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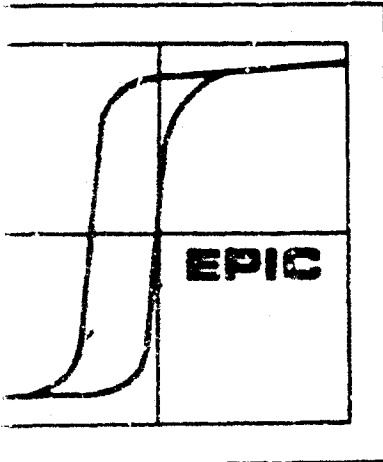
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THE  
BISMUTH TELLURIDE-  
BISMUTH SELENIDE  
SYSTEM

M. NEUBERGER

DATA SHEET DS-147  
JAN 1966

477558



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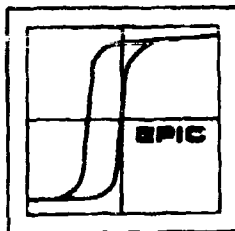
AIR FORCE MATERIALS LABORATORY  
RESEARCH AND TECHNOLOGY DIVISION  
AIR FORCE SYSTEMS COMMAND

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PROJECT 7801; TASK 780102

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## FOREWORD

The Electronic Properties Information Center (EPIC) was established in June 1961 at Hughes Aircraft Company, Culver City, California. It is operated under contract with the Air Force Materials Laboratory, Research and Technology Division, Wright-Patterson Air Force Base, Ohio. The Contract was initiated under Project No. 7381, Task No. 738103, with Mr. R. F. Klinger acting as Project Engineer.

The EPIC Information Analysis Center is a center for the collection, review and analysis of the scientific and technical literature on the electrical and electronic properties of materials. Its major function is to evaluate, compile and publish the experimental data from that literature. Through the medium of a series of publications such as Data Sheets, Special Reports, State-of-the-Art Reports, Computer Bibliographies, and services including special studies, answers to technical inquiries, research support is provided to the DoD community. EPIC input is primarily from the open literature. A large number of abstract journals, in addition to about 40 other journals, and the unclassified report literature are completely searched.

This report consists of the compiled data sheets on the Bismuth Telluride-Bismuth Selenide System. A full list of EPIC publications to date appears at the end of the report.

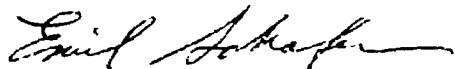
The author wishes to acknowledge the assistance afforded by Dr. J. J. Grossman in reviewing the experimental data, and the contribution of Mr. E. Schafer in the thorough pre-publication review of the compilation. The supporting assistance of other members of the EPIC staff, in particular, Mrs. D. Gough, Mr. Thomas Lyndon, and Mr. W.S. Hodge, is gratefully acknowledged.

## ABSTRACT

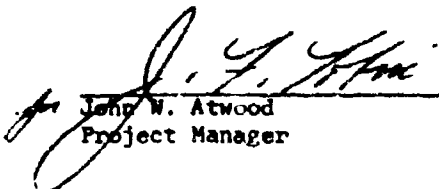
These data sheets present a compilation of a wide range of electronic properties for the bismuth telluride-bismuth selenide system. Electrical properties include conductivity, dielectric constant, Hall coefficient, and mobility. Emission data have been broken down into the varied electron and photon emissions which result from application of electromagnetic energy over a wide spectrum. Energy data include energy bands, energy gap, and energy levels, as well as effective mass tables, and work function. The optical properties include absorption, reflection, and the refractive index. Other magnetic data and irradiation effects are presented, as well as several related physical phenomena, such as piezoelectric properties, Debye temperature and electronic specific heat. Thermoelectric properties, thermal conductivity and figure of merit tables and graphs are especially presented. Each property is compiled over the widest possible range of parameters including bulk and film form, from references obtained in a thorough literature search.

A summary of crystal structure and phase transitions has been included.

This report has been reviewed and is approved for publication.



Emil Schafer, Assistant Head  
Electronic Properties Information Center



John W. Atwood  
Project Manager

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## INTRODUCTION

The initial step in the preparation of this data sheet was the retrieval, by means of modified coordinate index, of all bismuth telluride-bismuth selenide system literature in the EPIC file. Bibliographies were also reviewed to ensure the inclusion of all relevant literature. Those papers containing primary source data were selected unless only secondary references were available. If equally valid data were available from several sources, all were given. Data were rejected when considered questionable because of faulty or dubious measurements, unknown sample composition, or if more reliable and inclusive data were available from another source. Selection of data was based upon evaluation of that which was most representative, precise, reliable and inclusive over a wide range of parameters. The addition of new data to a material compilation requires a reappraisal of the reported values. Older data may be deleted in light of the new data.

Within every property section we have tried to include every available parameter and range of experimental condition in the literature. Information on test conditions and sample specification are extracted from the article. Some slight alterations in units and presentation may be made to facilitate comparison with other experimental data.

In the thermoelectric properties section, electric conductivity and thermal conductivity graphs, (where available for the same samples) are presented with thermal emf data in order to facilitate calculation of figure of merit values. Cross-referencing of germane information is also provided.

Within the individual properties, arrangement has generally been to show the pure sample data followed by the effects of dopants (in alphabetical



order). Doping, per se, however, is often not a qualifying factor, and graphs may be arranged or grouped according to experimental parameters.

In presenting tabular data, values are variously arranged. In some cases it is by dopant, in others by magnitude of numerical value. On occasion, however, the values from one reference may be grouped for comparison.

The references, from which the data are drawn, are shown by accession number below each graph, with the full bibliographic citation tabulated at the end of the data sheets. The bibliography is listed by accession number.

An introductory section on the crystallographic structure and phase diagrams of this system includes lattice arrangements and correlation with thermoelectric properties.

## CRYSTALLOGRAPHY

Bismuth telluride occurs naturally as tellurobismuthite in irregular plates or foliated masses. It is soft, with a metallic lustre; the (0001) cleavage is perfect, so that all measurements are made either normal or parallel to that plane. The hexagonal symmetry indicates that the electronic properties are anisotropic. This anisotropy is very marked in optical measurements [Ref. 3124]; dielectric constant [Ref. 10299]; electrical conductivity [Ref. 631], [electrical conductivity normal to the (0001) cleavage plane is .1 of that parallel to the (0001)]; magnetoelectric measurements [Ref. 19045]; reflectivity [Ref. 18221]; and thermoelectric emf [Ref. 19827].

Bismuth selenide occurs naturally as orthorhombic guanajuatite in acicular crystals or granular foliated or fibrous masses. The cleavage is distinct on (010) or (001). The mineral is soft with metallic lustre. The synthetic material is rhombohedral and apparently isostructural with the telluride.

Wyckoff states that both the bismuth telluride and the bismuth selenide are rhombohedral crystals with a one molecule unit. The corresponding hexagonal cell contains three molecules and the molecule is considered to have atom layers along the c-axis.

The ternary comprises a continuous series of isomorphic (rhombohedral) compounds [Ref. 19825]. As the selenium content increases, it becomes more difficult to obtain single crystal material in thin enough specimens to do optical work [Ref. 22468].

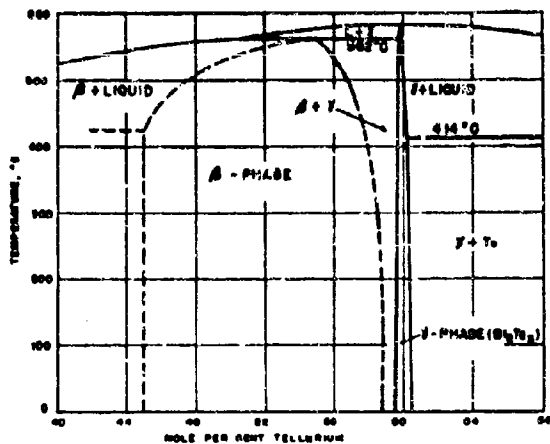
Composition	Symmetry	Lattice Constants			Remarks	Ref.	
		$\frac{a}{\text{\AA}}$	$\frac{c}{\text{\AA}}$	$\frac{c}{a}$			
$\text{Bi}_2\text{Te}_3$	hexagonal	$4.384 \pm 0.001\text{\AA}$	$30.495 \pm 0.006\text{\AA}$		300°K	21735	
$\text{Bi}_2\text{Te}_3$	hexagonal	$\frac{a}{\text{\AA}}$	$\frac{c}{\text{\AA}}$	$\frac{c}{a}$		Donnay	
		4.240	11.076	2.612			
		4.376	30.39	6.945			
		4.369	30.424	6.963			
		4.35	30.3	6.9655			
$\text{Bi}_2\text{Te}_3$	rhomboidal cell	10.473		$24^\circ 10'$		Wyckoff*	
	hexagonal cell	4.3835	30.487				
$\text{BiTe}$	cubic	6.47				Wyckoff**	
$\text{Bi}_2\text{Se}_3$	hexagonal	6.702	11.26	1.680		natural crystal isotypic with $\text{Bi}_2\text{Te}_3$	Donnay
		4.15	28.65	6.8836			
		4.125	28.56	6.9236			
		4.13 to	28.7 to	6.9492 to	variable		
		4.16	29.3	7.0096	composition		
$\text{Bi}_2\text{Se}_3$	rhombohedral cell	9.841		$24^\circ 16'$		Wyckoff*	
	hexagonal cell	4.138	28.64				
$\text{Bi}_3\text{Se}_4$	hexagonal	4.21 to	40.3 to	9.5724 to	variable composition	Donnay	
		4.28	41.1	9.6028			
$\text{Bi}_3\text{Se}_4$	rhombohedral cell	13.719		$17^\circ 44'$		Wyckoff*	
	hexagonal cell	4.23	40.5				

<u>Compo- sition</u>	<u>Symmetry</u>	<u>Lattice Constants</u>		<u>Remarks</u>	<u>Ref.</u>
BiSe	cubic	5.86			Donnay
BiSe	cubic	5.99			Wyckoff**
Bi <sub>2</sub> Te <sub>2</sub> Se	rhombo- hedral cell	10.255		24° 5'	Wyckoff*
	hexagonal cell	4.28	29.86		

Molecular %

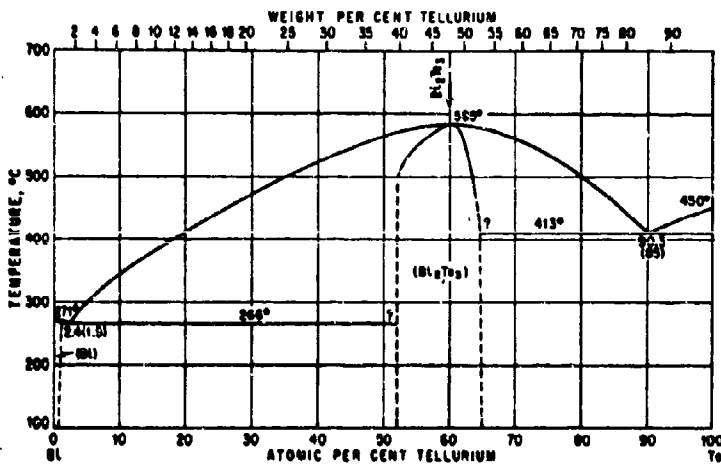
Bi <sub>2</sub> Te <sub>3</sub>	Bi <sub>2</sub> Se <sub>3</sub>	Formula
100	0	Bi <sub>2</sub> Te <sub>3</sub>
95	5	Bi <sub>2</sub> Te <sub>2.85</sub> Se <sub>0.15</sub>
90	10	Bi <sub>2</sub> Te <sub>2.7</sub> Se <sub>0.3</sub>
83.33	16.67	Bi <sub>2</sub> Te <sub>2.5</sub> Se <sub>0.5</sub>
80	20	Bi <sub>2</sub> Te <sub>2.4</sub> Se <sub>0.6</sub>
66.67	33.33	Bi <sub>2</sub> Te <sub>2</sub> Se
60	40	Bi <sub>2</sub> Te <sub>1.8</sub> Se <sub>1.2</sub>
50	50	Bi <sub>2</sub> Te <sub>1.5</sub> Se <sub>1.5</sub>
40	60	Bi <sub>2</sub> Te <sub>1.2</sub> Se <sub>1.8</sub>
33.33	66.67	Bi <sub>2</sub> TeSe <sub>2</sub>
22.22	77.78	Bi <sub>2</sub> Te <sub>0.77</sub> Se <sub>2.33</sub>
0	100	Bi <sub>2</sub> Se <sub>3</sub>

The atomic formulas and corresponding molecular percent compositions are given here for general reference purposes.



Phase diagram of the bismuth-tellurium system in the region near the congruent melting compound.

[Ref. 21735]



Bi-Bi<sub>2</sub>Te<sub>3</sub> eutectic, 1-1.5% wgt. Te, 263-267°C

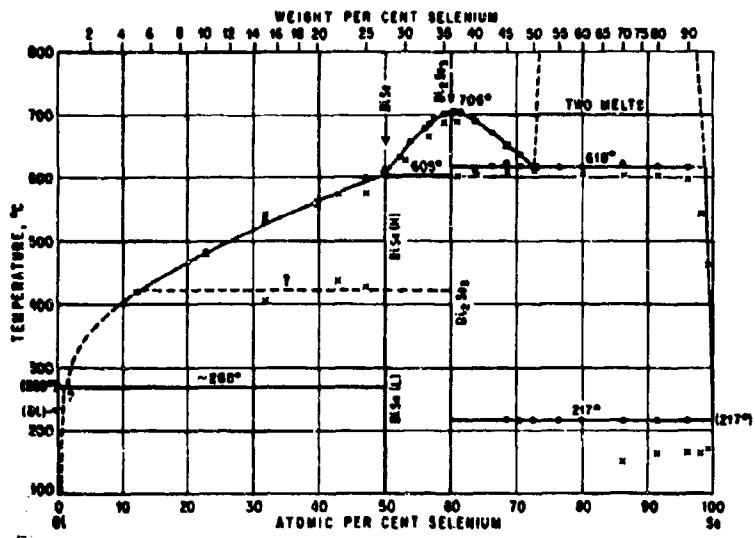
Bi<sub>2</sub>Te<sub>3</sub> mpt = 583-586°C

Bi<sub>2</sub>Te<sub>3</sub>-Te eutectic 85 wgt.%, 410-413°C

Bi mpt 269-271°C

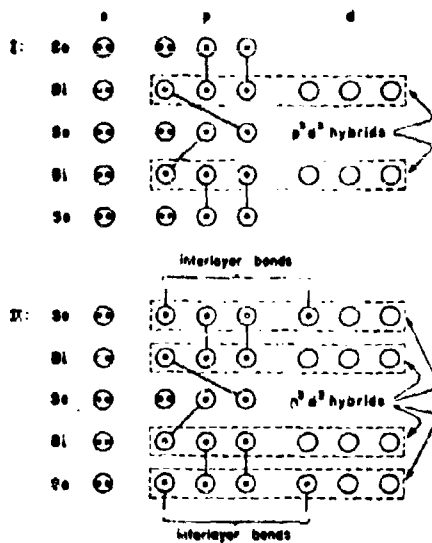
Te " 447-452°C

[Hansen]



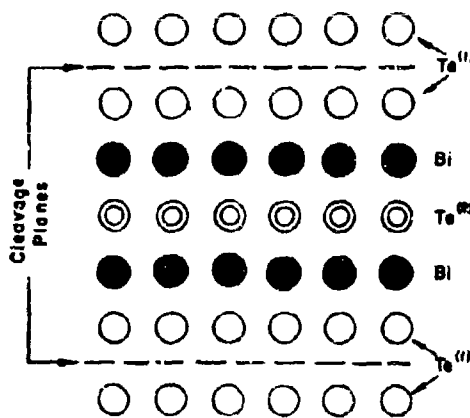
Phase diagram of bismuth-selenium system

[Hansen]



Arrangement of atoms in bismuth selenide as viewed parallel to the basal (cleavage) plane.

[Ref. 5564]



Arrangement of atoms in bismuth telluride as viewed parallel to basal plane, showing layer structure and two types of tellurium atoms.

[Ref. 19825]

"Considering the transition from  $\text{Bi}_2\text{Te}_3$  to  $\text{Bi}_2\text{Se}_3$  in light of the preferential-substitution hypothesis,  $\text{Bi}_2\text{Te}_3$  has the highest p-type conductivity in the system. Then, with initial substitution of selenium in  $\text{Te}^2$  sites,  $\text{Bi}-\text{Te}^2$  pair bonds would be replaced by more ionic  $\text{Bi}-\text{Se}^2$  bonds. Here decreasing electrical conductivity and increasing energy gap were noted. At  $x = 1$ , the  $\text{Bi}-\text{Te}^2$  pair bonds hypothetically would be replaced by  $\text{Bi}-\text{Se}^2$  bonds and the solid would consist of mutually-bonded  $\text{Te}^1-\text{Bi}-\text{Se}^2-\text{Bi}-\text{Te}^1$  chains. At  $\text{Bi}_2\text{Te}_2\text{Se}$  the Seebeck coefficient is observed to cross zero, electrical conductivity is minimum and energy gap is essentially maximum. With continued selenium substitution (now in  $\text{Te}^1$  sites) the observed property trends are reversed, i.e., the sign of the Seebeck coefficient becomes negative, electrical conductivity increases, and energy gap decreases slightly."

[Ref. 19825]

Stoichiometric bismuth telluride,  $\text{Bi}_2\text{Te}_3$ , is always p-type; excess tellurium or halogens yield n-type. Excess bismuth, lead or cadmium maintain the p-type. [Ref. 15291] Copper has a high diffusion rate in both the telluride and selenide and yields n-type material, so it should never be used for contacts. [Ref. 2595]

In the mixed crystals  $\text{Bi}_2\text{Te}_{3-x}\text{Se}_x$ , the carrier concentration decreases with increasing x-values, probably due to decrease in bismuth. Intrinsic conductivity occurs around  $\text{Bi}_2\text{Te}_2\text{Se}$ . At  $x > 1$ , the crystals are n-type, and the electron concentration then increases to a maximum of  $3 \times 10^{19}/\text{cc}$  for  $\text{Bi}_2\text{Se}_3$ . [Ref. 10984]

The thermoelectric properties of the bismuth telluride-bismuth selenide system are a function of the composition and the doping. Bismuth telluride-rich mixed crystals in this series are p-type if undoped. By means of donors such as silver, copper, chlorine, bromine and iodine, however, n-conduction can be achieved. This provides the optimum electron conductivity. Halogen donors are located in lattice vacancies, while copper and silver are held interstitially. Because of its high diffusion rate, under certain conditions, copper can cause ageing phenomena.

While normal electron scattering resulting from lattice vibrations is temperature dependent, the substitution of selenium for tellurium reduces the additional scattering due to lattice defects. At low temperatures, the scattering becomes evident on ionized centres. The highest figure of merit at room temperature, connected with the most favourable temperature range for the application of the Peltier method, is the 90-10 mixture prepared with optimum halogen doping.



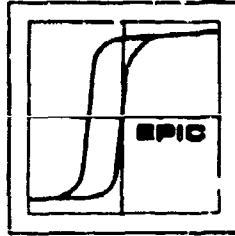
Decreased figure of merit values for the n-type at low temperatures is connected with lowered thermal emf, but increased electrical and thermal conductivity. Thermal lattice scattering and nondegeneracy aside, at 20°C, the lattice portion of the thermal conductivity is .0109 W/cm deg. This value closely approaches the minimum of the lattice thermal conductivity nominally at about 20 mole percent bismuth selenide. If it is wished to displace the figure of merit maximum towards a higher temperature, the selenide portion may be increased in order to increase the energy gap. Strong doping also allows intrinsic conduction to occur only at higher temperatures. Both methods, however, produce a decrease in the maximum figure of merit.

WYCKOFF, R.\* CRYSTAL STRUCTURES. 2nd. ed. N.Y., Interscience Publishers, 1963. V. 2, p. 29-30.

WYCKOFF, R.\*\* CRYSTAL STRUCTURES. 2nd. ed. N.Y., Interscience Publishers, 1963. V. 1, p. 86.

DONNAY, J.D.H. CRYSTAL DATA. DETERMINATIVE TABLES. 2nd. ed. American Crystallography Association, 1963.

HANSEN, M. CONSTITUTION OF BINARY ALLOYS. 2nd. ed., prepared with the cooperation of ANDERKO, K. N.Y., McGraw-Hill, 1958. p. 335 and 340.

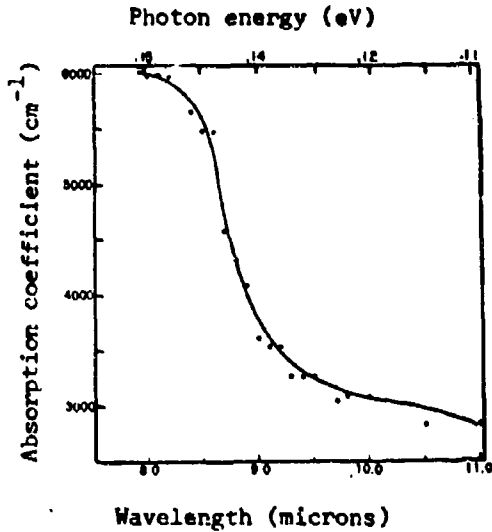


BISMUTH TELLURIDE

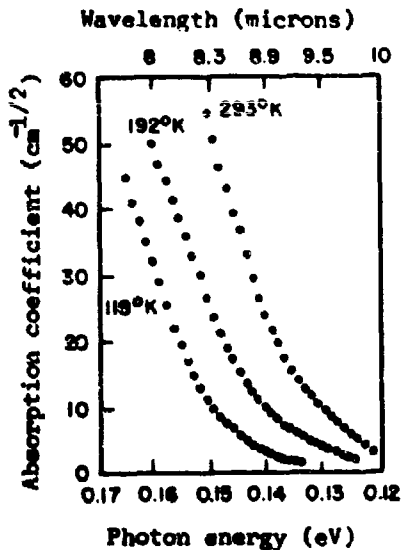
ABSORPTION ( $\alpha$ )

Absorption coefficient in single crystal  $\text{Bi}_2\text{Te}_3$  as a function of wavelength at 300°K. Measurements on (0001) cleavage plane.

$n = 5 \times 10^{17} / \text{cc}$  at 300°K.  
 $\rho = .055 \text{ ohm-cm.}$

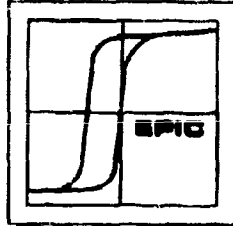


[Ref. 10535]



Absorption edge data for single crystal, n-type,  $\text{Bi}_2\text{Te}_3$ , shown by the square root of the absorption coefficient as a function of photon energy. Curves are calculated from transmission measurements made at three temperatures on a nearly intrinsic sample, iodine-compensated, on the (0001) cleavage plane.

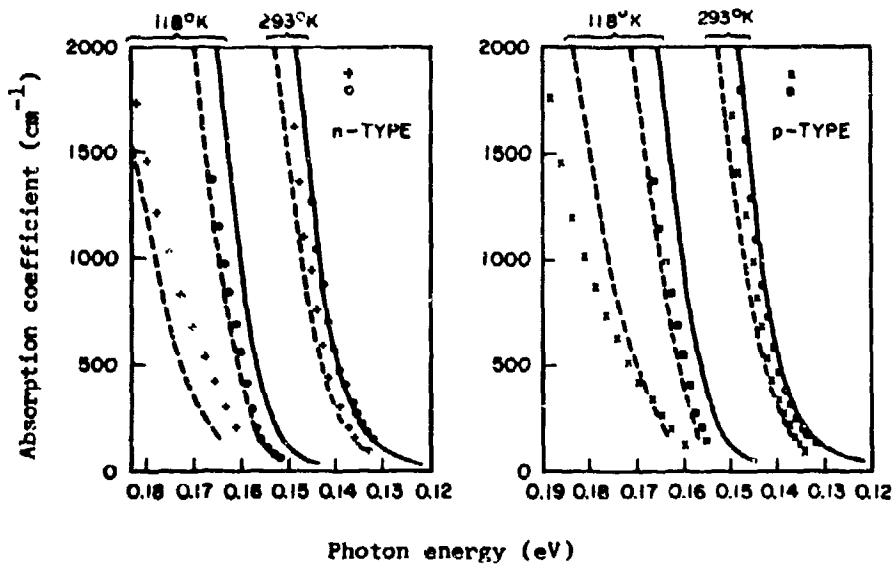
[Ref. 3124]



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**BISMUTH TELLURIDE**

**ABSORPTION**

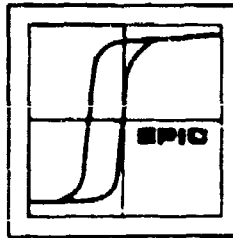


A comparison between the measured and calculated absorption edges in single crystal, n- and p-type,  $\text{Bi}_2\text{Te}_3$  samples, showing the effects of degeneracy at 2 temperatures.

- absorption edges, at two temperatures, for the single crystal, n-type, intrinsic sample shown on preceding page, given here for comparison.
- calculated edges showing effects of degeneracy at 118 and 292°K.

Points show experimental data

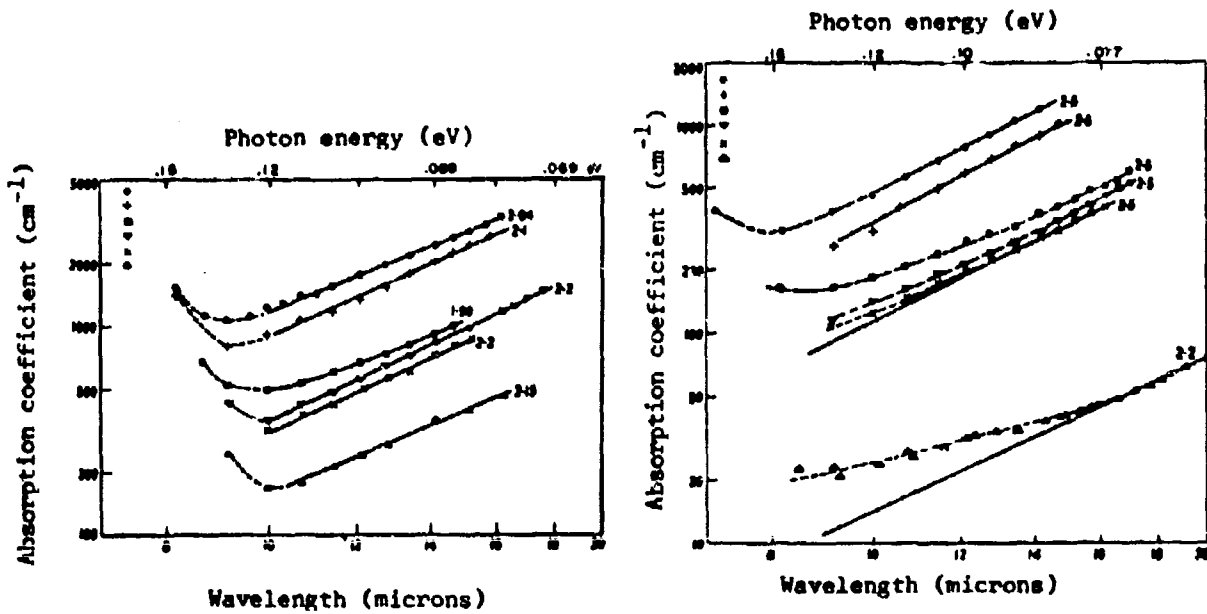
[Ref. 3124]



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BISMUTH TELLURIDE

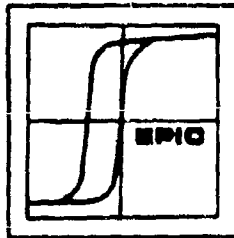
ABSORPTION



Free carrier absorption in single crystal  $\text{Bi}_2\text{Te}_3$  at  $300^\circ\text{K}$ . Values are calculated from transmission measurements on (0001) cleavage plane. Absorption coefficient,  $\alpha \sim \lambda^s$ . Values of  $s$  are shown on curves, by solid lines.

p-type		n-type	
carrier concentration n, at $4^\circ\text{K}$			
+	$3.5 \times 10^{18}/\text{cc}$	o	$1.3 \times 10^{19}/\text{cc}$
∇	$2.1 \times 10^{18}$	□	$3.8 \times 10^{18}$
x	$1.7 \times 10^{18}$		
△	$1.7 \times 10^{17}$ (intrinsic)		

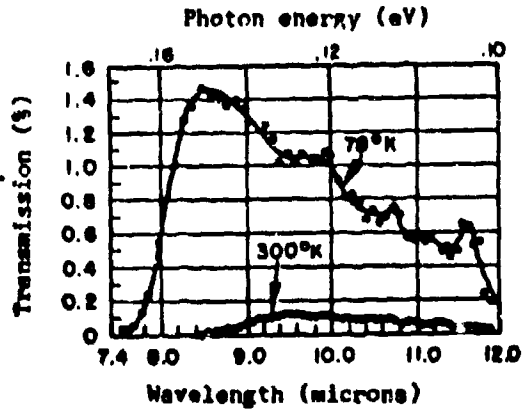
[Ref. 524]



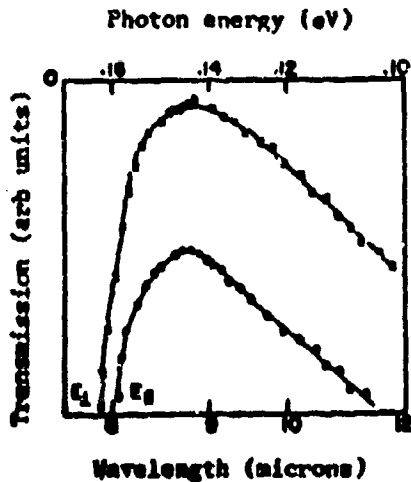
**BISMUTH TELLURIDE**

**ABSORPTION**

Infrared transmission as a function of wavelength for highly purified, p-type single crystal  $\text{Bi}_2\text{Te}_3$  at two temperatures. Thickness was 0.06 mm and illumination was normal to the cleavage plane (0001).



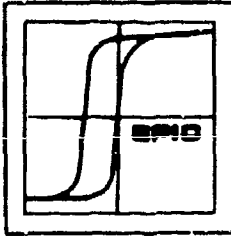
[Ref. 2866]



Transmission as a function of wavelength for single crystal, n-type  $\text{Bi}_2\text{Te}_3$  at 118°K, using light polarized in the two principal directions. The sample is iodine compensated-intrinsic.

$E_{\parallel}$ , polarized light parallel to cleavage planes;  
 $E_{\perp}$ , polarized light perpendicular to cleavage planes, (0001).

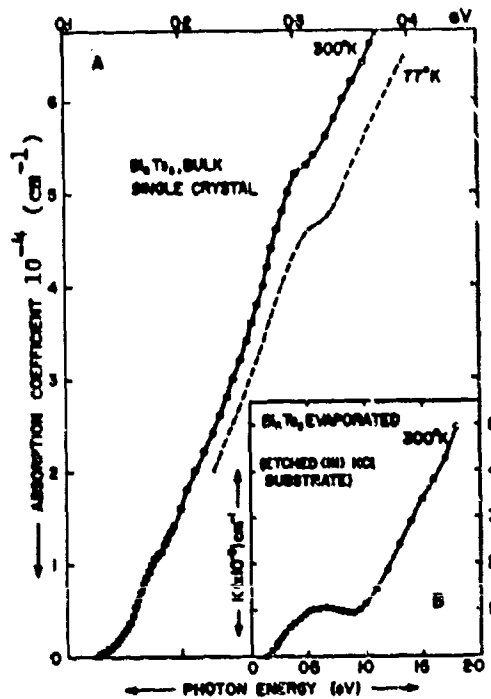
[Ref. 312\*]



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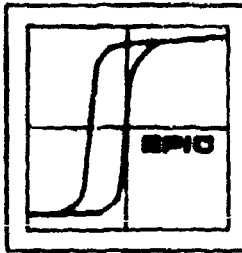
**ABSORPTION**



Absorption coefficient as a function of photon energy for single crystal, (A) and film (B)  $\text{Bi}_2\text{Te}_3$ , deposited on the (111) plane of a KCl substrate.

The single crystal shows a direct interband transition at 0.18 eV and a higher transition at 0.3 eV.

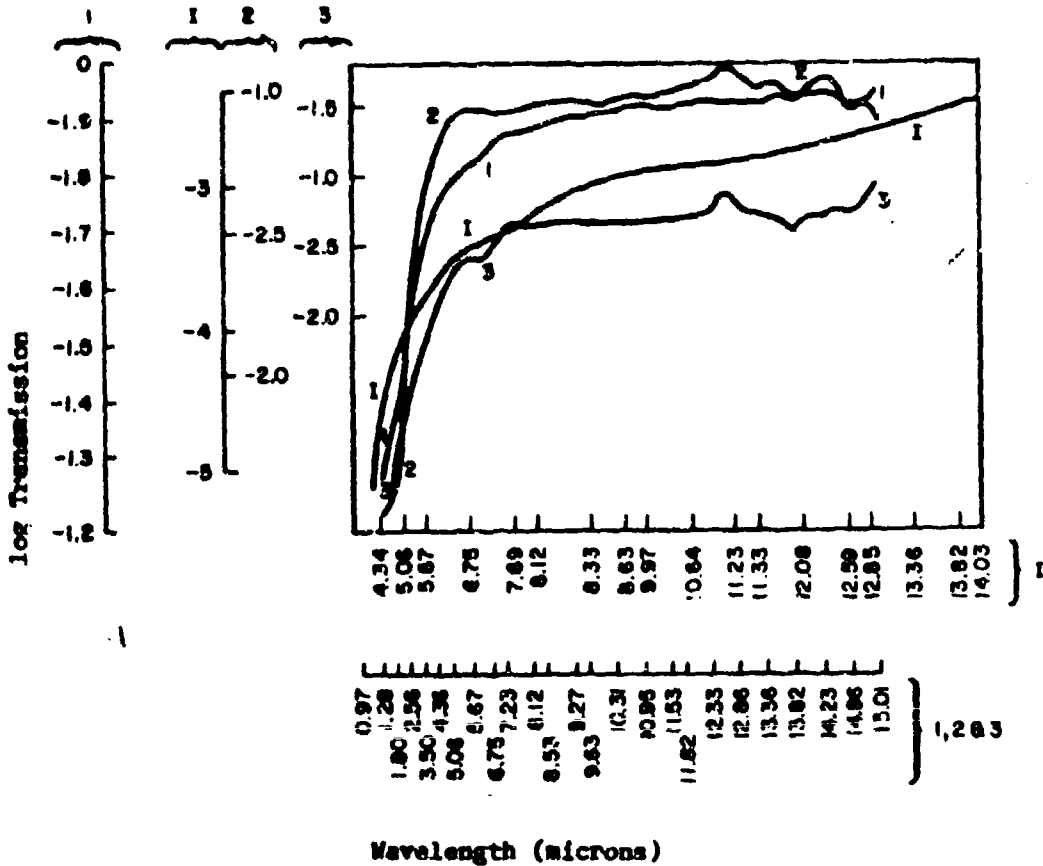
[Ref. 22468]



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BISMUTH TELLURIDE

ABSORPTION

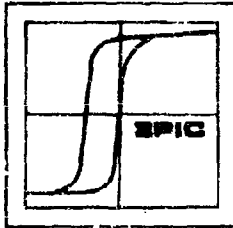


Transmission as a function of wavelength for:

1. Single crystal, thin section, p-type  $\text{Bi}_2\text{Te}_3$
- 1, 2, 3. Thin evaporated films of p-type  $\text{Bi}_2\text{Te}_3$

[Ref. 2711]

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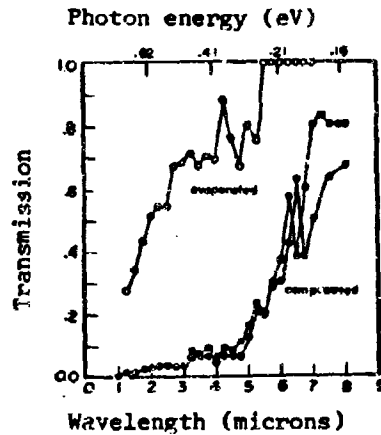
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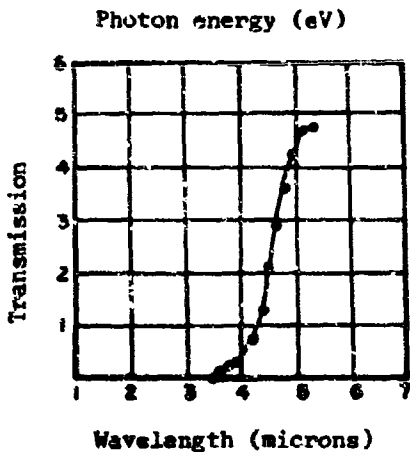
**BISMUTH SELENIDE**

**ABSORPTION**

Transmission as a function of wavelength for films and pressed powder disks of n-type  $\text{Bi}_2\text{Se}_3$  at  $300^\circ\text{K}$ .



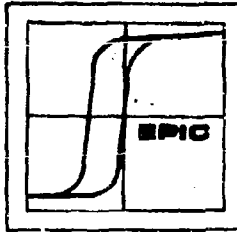
[Ref. 3097]



Transmission as a function of wavelength for purified single crystal, n-type  $\text{Bi}_2\text{Se}_3$  at  $300^\circ\text{K}$ . Illumination normal to the cleavage plane (0001), of a 0.03 mm thick sample. Carrier concentration is  $2 \times 10^{19}/\text{cc}$ .

[Ref. 2866]

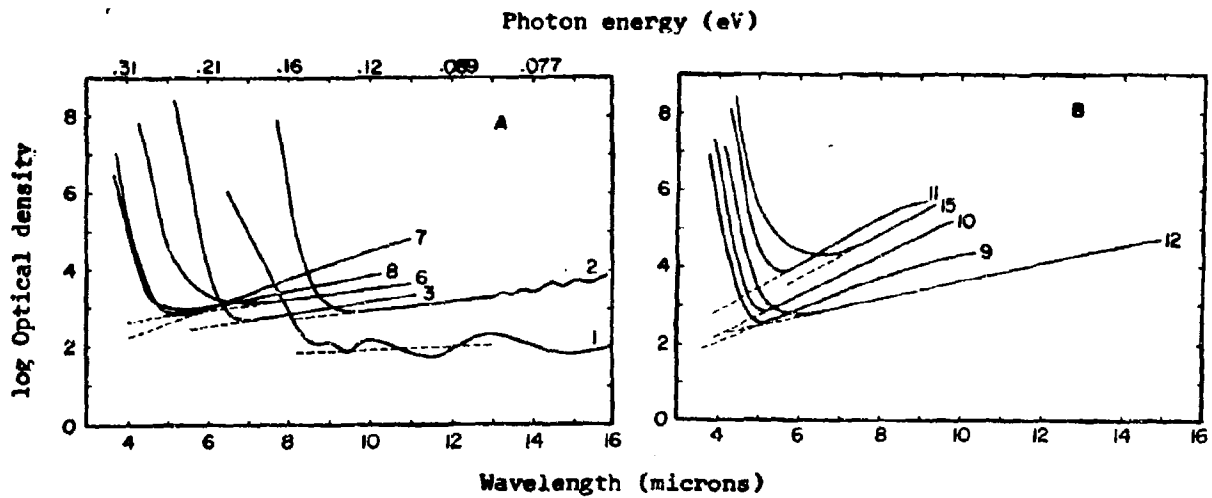




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BISMUTH TELLURIDE-BISMUTH SELENIDE ( $\text{Bi}_2\text{Te}_{3-x}\text{Se}_x$ )

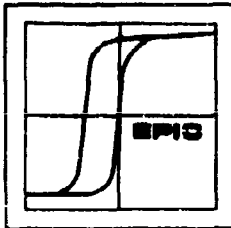
ABSORPTION



Optical density (normalized transmission) for  $\text{Bi}_2\text{Te}_3$ - $\text{Bi}_2\text{Se}_3$  polycrystalline, (plane parallel) samples at 300°K. Sample specifications given in table. Curves 1 and 2 for pure  $\text{Bi}_2\text{Te}_3$  show transmission interference fringes.

Sample (single crystal)	$\text{Bi}_2\text{Te}_3$	$\text{Bi}_2\text{Se}_3$	Type	Thickness (microns)
1	100	-	p	3
2	100	-	p	17
3	90	10	p	20
6	80	20	p	30
7	70	30	n	40
8	66.7	33.3		21
9	60	40		38
10	50	50		29
11	40	60		39
12	30	70		21
15	-	100		25

[Ref. 22468]



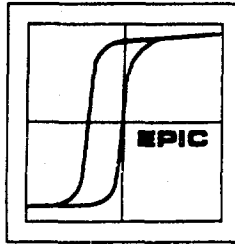
BISMUTH TELLURIDE-BISMUTH SELENIDE ( $\text{Bi}_2\text{Te}_{3-x}\text{Se}_x$ )

DEBYE TEMPERATURE ( $\theta_D$ )

$\theta_{s.h.}$	$\theta_{t.c.}$	$T^\circ\text{K}$	Sample $\text{Bi}_2\text{Te}_3$	Ref.
155.5 ± 3		0	macrocrystalline	7764
161		80	polycrystalline ↓	3030 ↓
158		90		
159		100		
161		120		
165		140		
171		160		
182		180		
190		200		
212		220		3030
117	71.6	10	single crystal, n-, and p-type ↓	3466 ↓ 3466
127.5	79.3	15		
142	88.5	20		
	95.3	25		
	98.2	30		
			$\text{Bi}_2\text{Se}_3$	
180		80	polycrystalline	3030

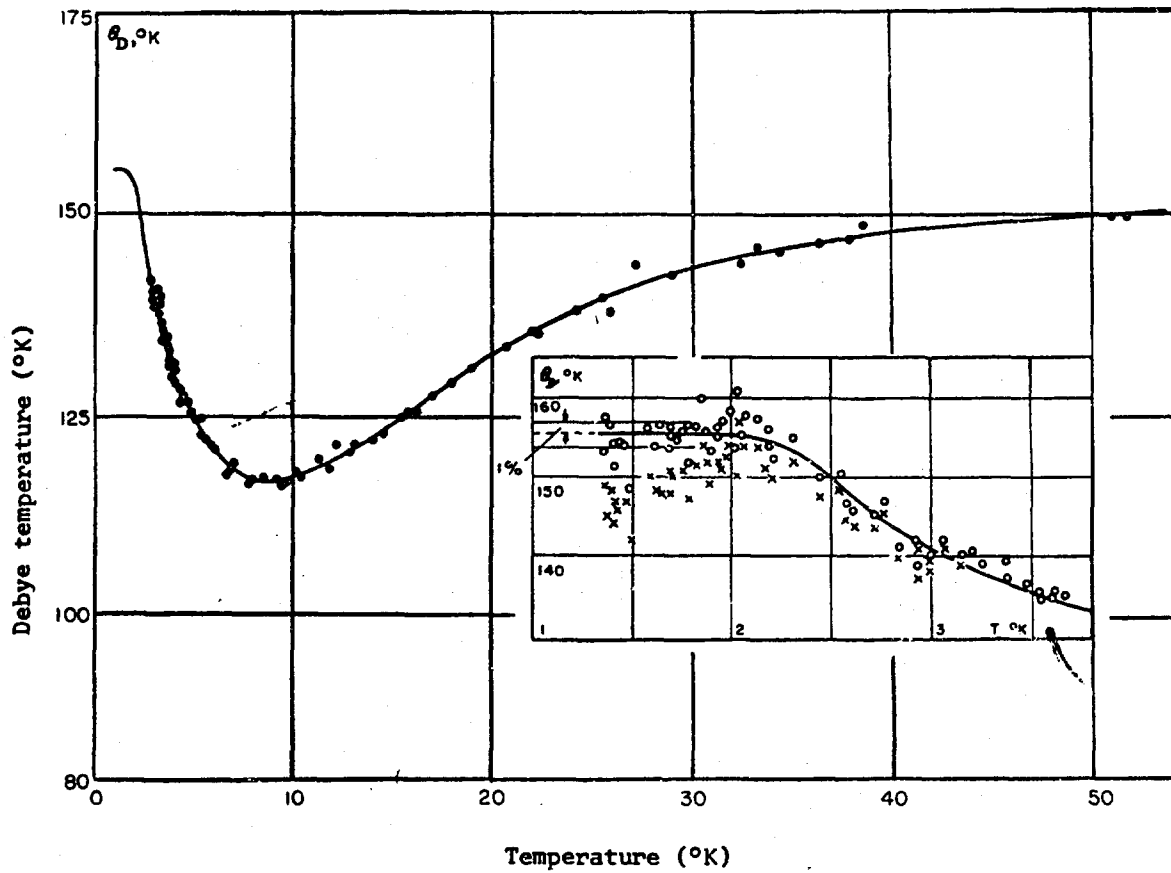
$\theta_{t.c.}$  is calculated from thermal conductivity data

$\theta_{s.h.}$  is calculated from specific heat data



BISMUTH TELLURIDE

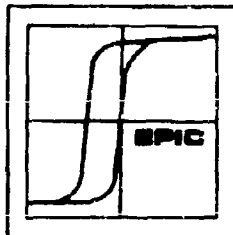
DEBYE TEMPERATURE



Characteristic Debye temperature for macrocrystalline, p-type  $\text{Bi}_2\text{Te}_3$  between 1.37 and 50°K, derived from the experimental heat capacity data. The region below 3.5°K is shown separately and corresponds to the portion of the main figure which has no points. The crosses indicate values calculated on the assumption that the entire measured heat capacity is due to the lattice.

[Ref. 7764]

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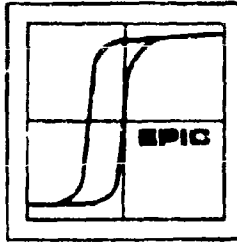
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**BISMUTH TELLURIDE**

**DIELECTRIC CONSTANT ( $\epsilon$ )**

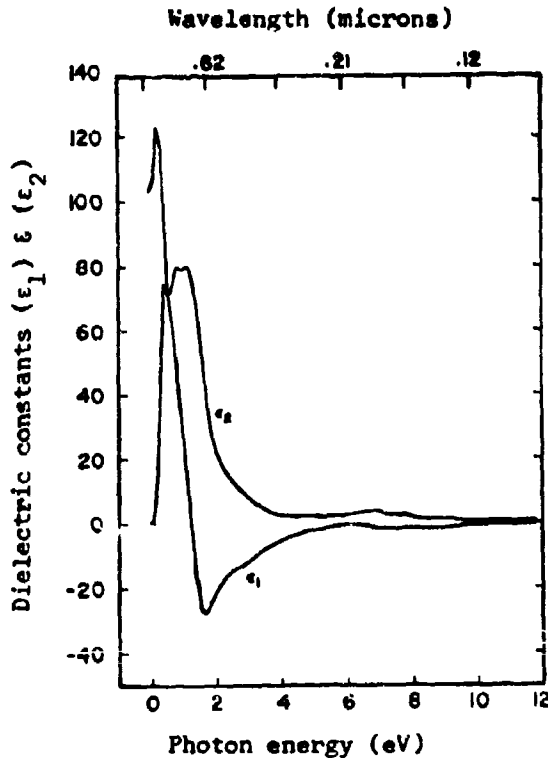
<u>Symbol</u>	<u>Value</u>	<u>Sample</u>	<u>Wavelength</u>	<u>Temperature</u>	<u>Ref.</u>
$\epsilon_0$	$\sim 100$ (est.)	single crystal, n-type $n = 3 \times 10^{17} - 6 \times 10^{19} / \text{cc}$			14854
$\epsilon_{\infty}$	84.6	single crystal, n-type nearly intrinsic, calc. from index of refraction $n = 9.2$	8 to $14\mu$	118°K	3124

Thorough search of the literature indicates no successful measurements have been made for dielectric constant or refractive index of bismuth selenide.

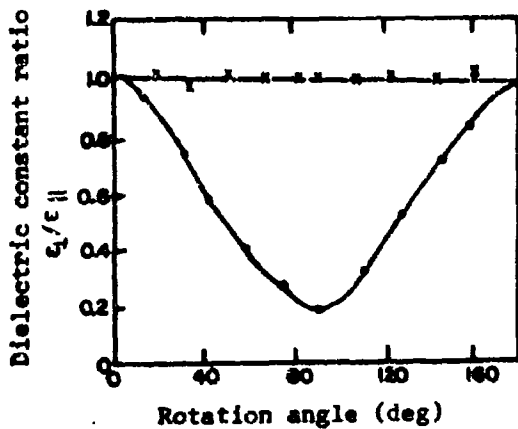


**BISMUTH TELLURIDE**  
**DIELECTRIC CONSTANT**

Real and imaginary part of the dielectric constant  $\epsilon_1$  and  $\epsilon_2$ , as a function of photon energy in single crystal, p-type  $\text{Bi}_2\text{Te}_3$ . Radiation normal to the cleavage plane (0001)  $E_{\perp c}$ . Values calculated from reflectivity measurements.



[Ref. 22468]



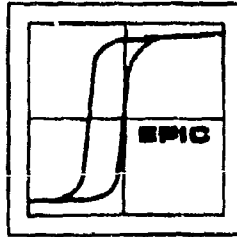
Anisotropy of dielectric constant in single crystal  $\text{Bi}_2\text{Te}_3$ .

x is  $\epsilon_{\parallel}/\epsilon_{\perp}$   
• is  $\epsilon_{\perp}/\epsilon_{\parallel}$

$\epsilon_{\parallel}$  is dielectric constant measured parallel to c-a is or (0001)

$\epsilon_{\perp}$  is dielectric constant measured normal to (0001)

[Ref. 10299]



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BISMUTH TELLURIDE

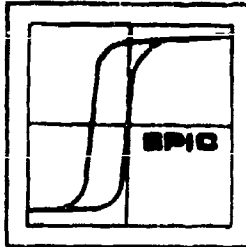
EFFECTIVE MASS ( $m^*$ )

Symbol	Value	Sample	Test Measurement	Temperature	Ref.
$m_1$	.0505	single crystal, p-type	magnetoelectric	300°K	18204
$m_2$	.209	↓	↓	↓	
$m_3$	.386	↓	↓	↓	18204
$m_{c1}^\dagger$	0.114	single crystal	magnetoelectric at 110 kOe	2, 4, and 77°K	9763
$m_{c2}$	0.145	↓	↓	↓	
$m_{c3}$	0.236	↓	↓	↓	9763
$m_c^\dagger$	0.13	single crystal, p-type $n \sim 10^{18}/\text{cc}$ , field parallel (0001)	deHaas-vanAlphen oscillations to 190 kG	1.4-4.2°K	11903

Faraday rotation at 17 kOe and $\lambda = 8-15\mu$ and 78°K	Optical absorption at $\lambda = 8-20\mu$ , made at 300°K	$n, \text{cm}^{-3}$	Single crystal type	
0.26	-	$1.5 \times 10^{19}$	p	524
-	0.35	$1.3 \times 10^{19}$	p	
0.25	0.28	$3.8 \times 10^{18}$	p	
0.15	0.15	$1.7 \times 10^{18}$	n, I-compensated	
-	0.16	$2.1 \times 10^{18}$	n	
0.14	0.13	$3.5 \times 10^{18}$	n	524

Field parallel (0001)  $\lambda$  normal (0001)

$\dagger m_c =$  cyclotron effective mass



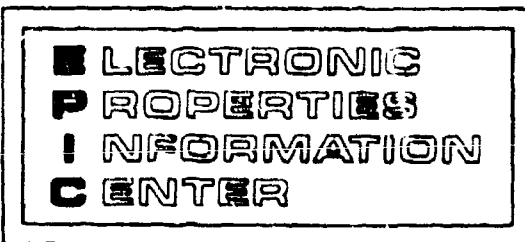
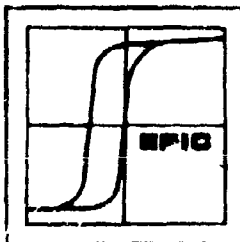
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**BISMUTH TELLURIDE**

**EFFECTIVE MASS**

<u>Symbol</u>	<u>Value</u>	<u>Sample</u>	<u>Test Measurement</u>	<u>Temperature</u>	<u>Ref.</u>
$m_n$	0.32	single crystal, n-type, iodine and tellurium-doped	thermal emf	300°K	2624
$m_p$	0.46	single crystal, p-type, bismuth and lead-doped			2624
$m_{DS}$	0.511	single crystal, $n_p = 6 \times 10^{18}/cc$	Hall	280°K	9763
$m_{DS}$	0.511	single crystal, p-type, $n = 3 \times 10^{18}/cc$	Hall	77°K	3207
$m_{DS}$	0.055 (lower conduction band)	single crystal, n-type Te-doped, $n = 2.4 \times 10^{17}/cc$	thermal emf	4.2°K	14854
$m_{DS}$ = density of states effective mass					
$m_n$	1.07	single crystal, p-type, normal to c-axis, $n = 1.4 \times 10^{19}/cc$	electrical & thermal emf	100-700°K	407
$m_p$	1.26		4 kG field		407
$m_p$	1.46	polycrystalline, p-type, $n = 4 \times 10^{19}/cc$	Hall coefficient and specific heat	2°K	7764

These excessively high effective mass values are due in part to channeling in a polycrystalline sample, but even more to neglect of the anisotropy factor in the electromagnetic measurements. The present interpretation of a six-valley band structure would reduce these high values by a factor of 3 with the introduction of the tensor components.



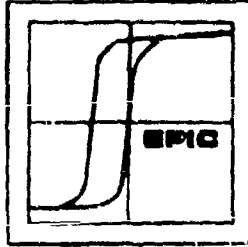
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BISMUTH SELENIDE

EFFECTIVE MASS

Symbol	Value	Sample	Test Measurement	Temperature	Ref.
$m_n$	0.18	polycrystalline	Hall	300°K	2473
$m_n$	0.18	polycrystalline, n-type, $n = 6.7 \times 10^{17}$ and $3 \times 10^{18}/cc$	thermal emf	100°K	21372
$m_n$	0.16	polycrystalline, n-type, $n = 4.2 \times 10^{18}$ and $5.4 \times 10^{18}/cc$	thermal emf	100°K	21372
$m$	$\sim 0.4$ (calc.)	macrocrystalline, n-type, $n = 10^{19}/cc$	electrical	300°K	2538
$m_2/m_1$	0.33	single crystal, n-type (0001) cleavage plane	magnetolectric	90°K	3350
$m_3/m_1$	4.2	↓	↓	↓	↓
$m_1:m_2:m_3$	(1.0:0.33:4.2)				3350
<u>Bi<sub>2</sub>Te<sub>3</sub></u>					
$m_1/m_2$	1.21	single crystal, n-type	magnetolectric	77°K	2360
$m_3/m_2$	0.093	↓	↓	↓	↓
$m_1:m_2:m_3$	(1.0:0.83:.077)				2360
<u>80% Bi<sub>2</sub>Te<sub>3</sub>-20% Bi<sub>2</sub>Se<sub>3</sub></u>					
$m_n$	1.1	polycrystalline, $n = 3 \times 10^{19}/cc$	thermal emf	77-630°K	14600
$m^*$	1.3	macrocrystalline, n-type, I-doped	thermal emf	300°K	2538

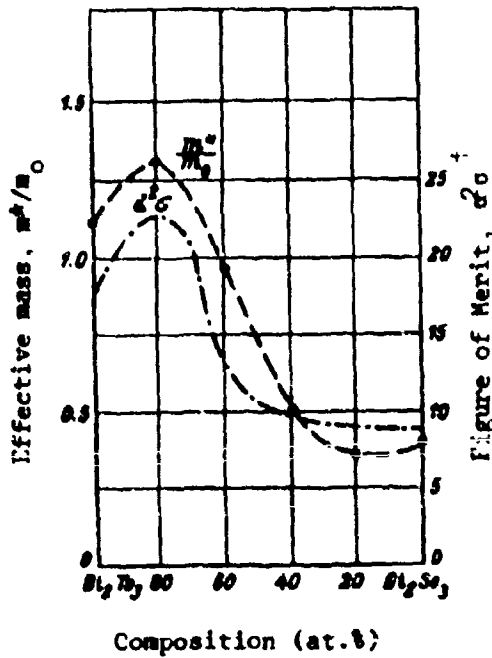




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BISMUTH TELLURIDE-BISMUTH SELENIDE ( $\text{Bi}_2\text{Te}_{3-x}\text{Se}_x$ )

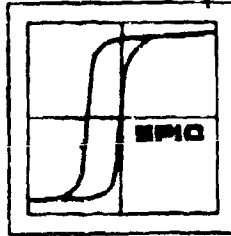
EFFECTIVE MASS



Effective mass as a function of composition for macrocrystalline, iodine-doped samples in the  $\text{Bi}_2\text{Te}_3$ - $\text{Bi}_2\text{Se}_3$  system at  $300^\circ\text{K}$ . Figure of merit measurements for same samples are shown.

† Usual figure of merit is defined as  $\frac{\alpha^2 \sigma}{k}$

[Ref. 2538]

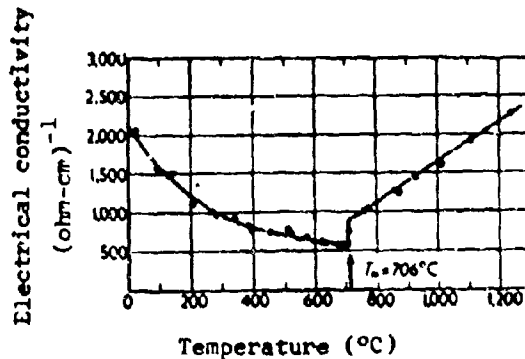


**BISMUTH TELLURIDE-BISMUTH SELENIDE**

**ELECTRICAL CONDUCTIVITY ( $\sigma$ )**

[Additional conductivity curves will be found in THERMOELECTRIC PROPERTIES Section]

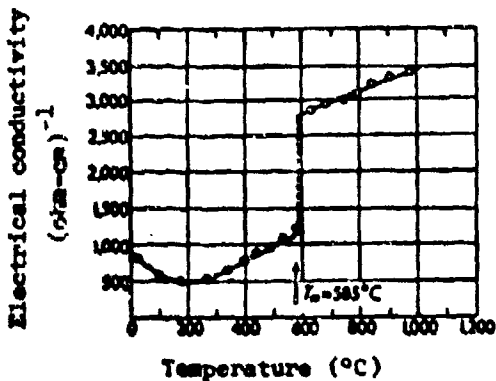
Temperature dependence of the electrical conductivity of stoichiometric  $\text{Bi}_2\text{Se}_3$  in the solid and liquid states.



[Ref. 3528]

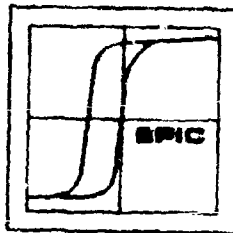
Both solid and liquid  $\text{Bi}_2\text{Te}_3$  and  $\text{Bi}_2\text{Se}_3$  are semiconductors, but on fusion they show metallic type conductivity.

$t_m$  = melting point



Temperature dependence of the electrical conductivity of stoichiometric  $\text{Bi}_2\text{Te}_3$  in the solid and liquid states.

[Ref. 3528]



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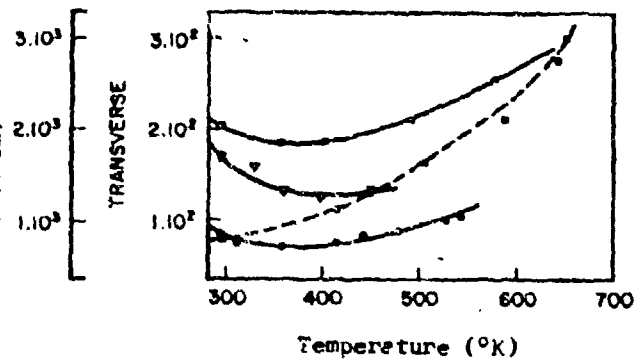
BISMUTH TELLURIDE

ELECTRICAL CONDUCTIVITY

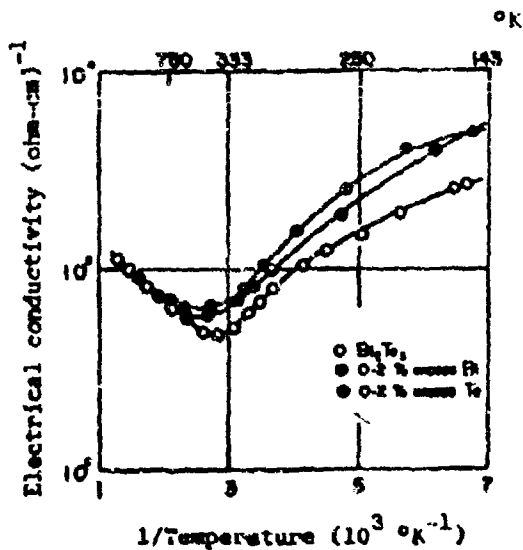
Temperature dependence of electrical conductivity as a function of temperature for single crystal, n-type  $\text{Bi}_2\text{Te}_3$ ,  $n \sim 10^{19}/\text{cc}$  for three similar samples. Conductivity normal to (0001) is about 0.1 of the parallel conductivity.

- parallel to cleavage plane (0001)
- - - normal to cleavage plane (0001)

Longitudinal electrical conductivity ( $\text{ohm-cm}^{-1}$ )



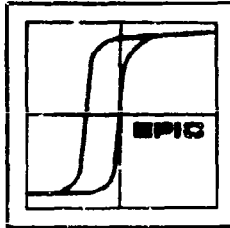
[Ref. 631]



Electrical conductivity as a function of reciprocal temperature for single crystal, p-type  $\text{Bi}_2\text{Te}_3$  cut on the (0001) cleavage plane.

o Stoichiometric  $\text{Bi}_2\text{Te}_3$ ,  $n = 1.4 \times 10^{19}/\text{cc}$ .  
Purified Bi and Te were used.

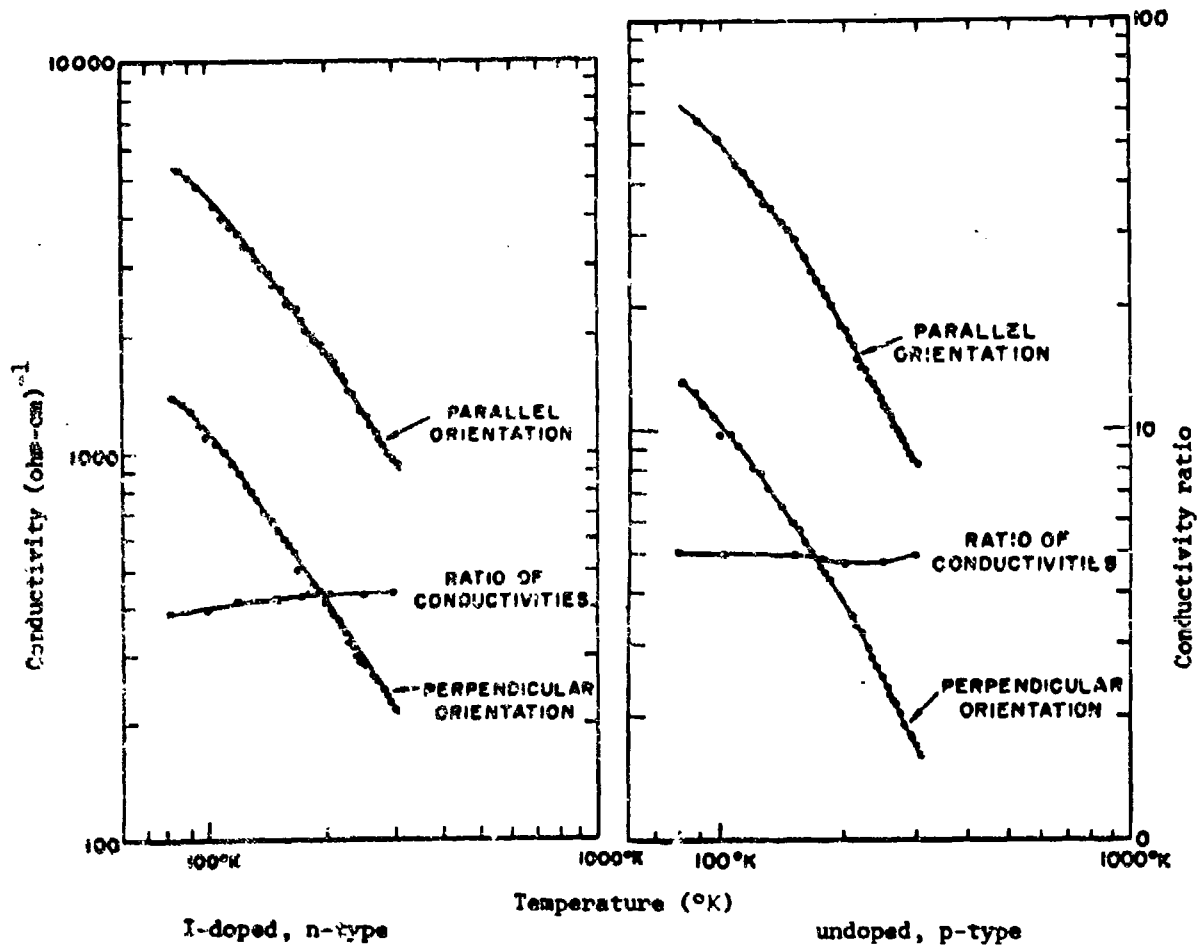
[Ref. 407]



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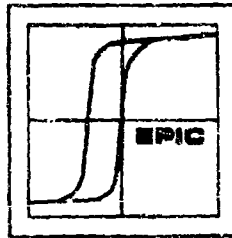
**BISMUTH TELLURIDE**

**ELECTRICAL CONDUCTIVITY**



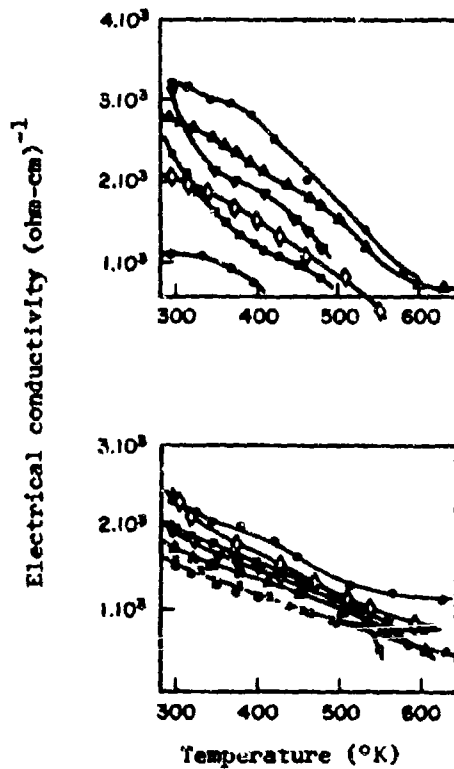
Conductivity and conductivity ratio of two types of single crystal  $\text{Bi}_2\text{Te}_3$  as a function of temperature. Measurements are taken parallel and normal to (0001). The zero slope of the conductivity ratio in the undoped sample indicates a multiple carrier and lattice scattering mechanism at 300-700°K, whereas, the 0.25 slope in the iodine-doped sample from 100-300°K indicates anisotropy due to a single carrier and multiple scattering mechanism.

[Ref. 19827]



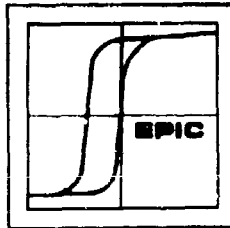
BISMUTH SELENIDE

ELECTRICAL CONDUCTIVITY



Electrical conductivity as a function of temperature for  $\text{Bi}_2\text{Se}_3$  n-type, single crystals parallel to their cleavage plane, (0001). Carrier concentrations are not specified for individual samples,  $n \sim 2 \times 10^{19}/\text{cc}$ . Conductivity normal to the cleavage plane is about  $60 (\text{ohm-cm})^{-1}$  at  $300^{\circ}\text{K}$  or approximately 3% of the parallel conductivity.

[Ref. 630]

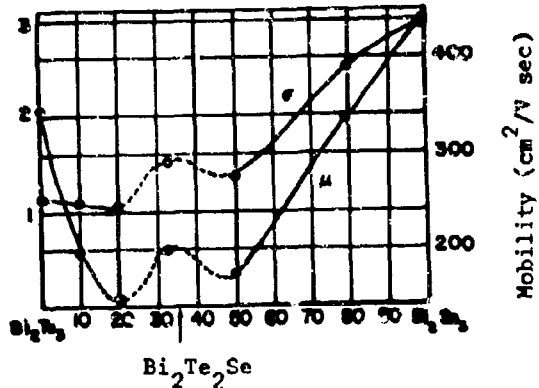


**BISMUTH TELLURIDE-BISMUTH SELENIDE ( $\text{Bi}_2\text{Te}_{3-x}\text{Se}_x$ )**

**ELECTRICAL CONDUCTIVITY**

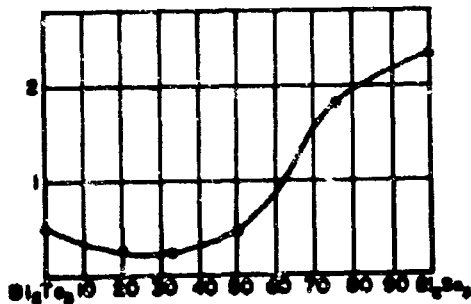
Electrical conductivity as a function of composition in silver iodide-doped, n-type, polycrystalline samples of the  $\text{Bi}_2\text{Te}_3$ - $\text{Bi}_2\text{Se}_3$  system at 300°K. The mixed crystals are homogeneous throughout, according to x-ray investigation, which shows a continuous decrease in the lattice constants with increase in selenium content.

Electrical conductivity  
 $\times 10^3 \text{ (ohm-cm)}^{-1}$



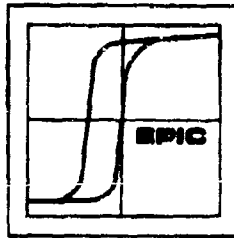
[Ref. 3867]

Electrical conductivity  
 $\times 10^3 \text{ (ohm-cm)}^{-1}$



Electrical conductivity as a function of composition for macrocrystalline samples of  $\text{Bi}_2\text{Te}_{3-x}\text{Se}_x$ , undoped, at 300°K.

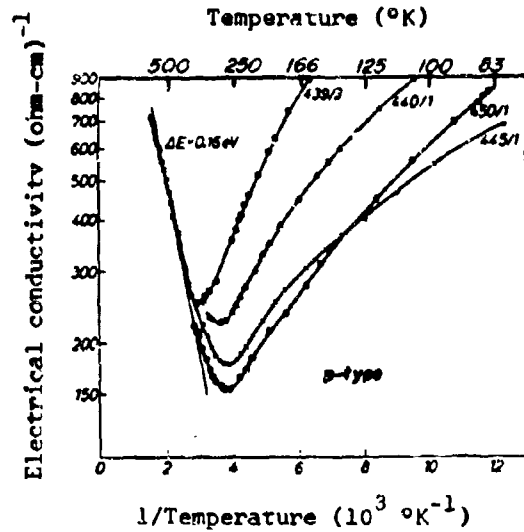
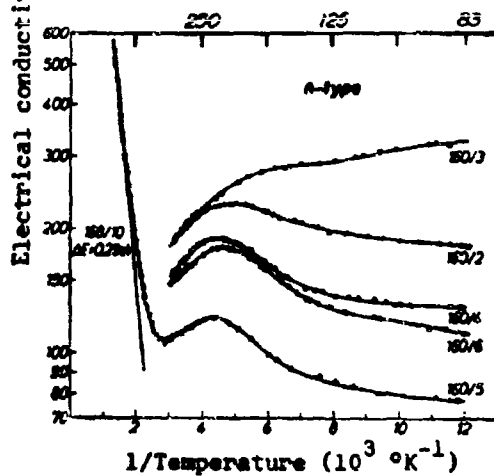
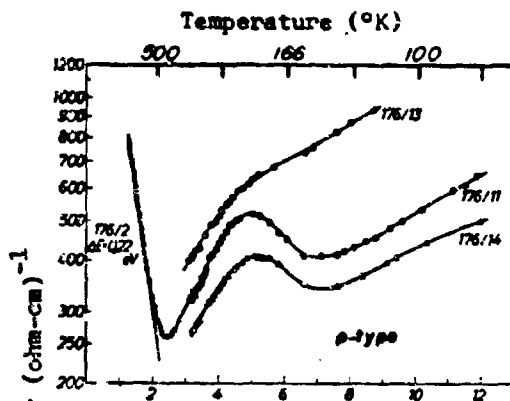
[Ref. 3867]



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BISMUTH TELLURIDE-BISMUTH SELENIDE ( $\text{Bi}_2\text{Te}_{3-x}\text{Se}_x$ )

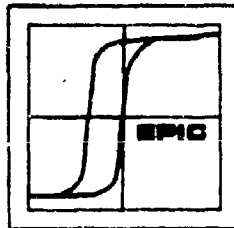
ELECTRICAL CONDUCTIVITY



Electrical conductivity as a function of reciprocal temperature for three compositions all with low carrier concentrations which are obtained by compensation. Samples are single crystal, n-, and p-type, A)  $\text{Bi}_2\text{Te}_3$ ; B) 90%  $\text{Bi}_2\text{Te}_3$ -10%  $\text{Bi}_2\text{Se}_3$ ; and C)  $\text{Bi}_2\text{Te}_3\text{Se}$ .

Curves are identified by sample numbers, however, no definite specifications are given.

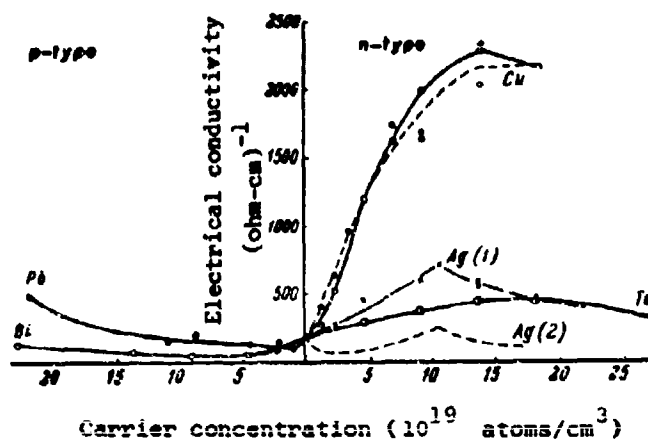
[Ref. 10984]



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BISMUTH TELLURIDE-BISMUTH SELENIDE ( $\text{Bi}_2\text{Te}_{3-x}\text{Se}_x$ )

ELECTRICAL CONDUCTIVITY

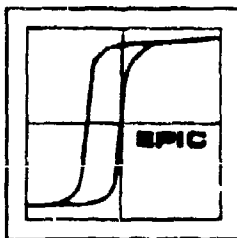


Electrical conductivity as a function of free element concentration for variously doped macrocrystalline samples of 80%  $\text{Bi}_2\text{Te}_3$ -20%  $\text{Bi}_2\text{Se}_3$ . Silver additions cause instability; Ag(2) was measured several months after Ag(1).

[Ref. 2538]



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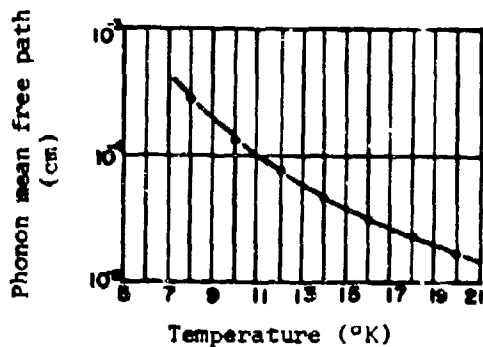
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BISMUTH TELLURIDE

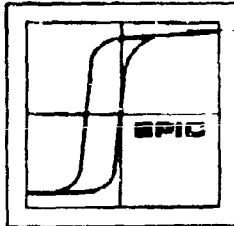
ELECTRICAL CONDUCTIVITY

Mean Free Path



Phonon mean free path as a function of temperature in single crystal n-, or p-type Bi<sub>2</sub>Te<sub>3</sub>, calculated from specific heat and thermal conductivity measurements.

[Ref. 3466]

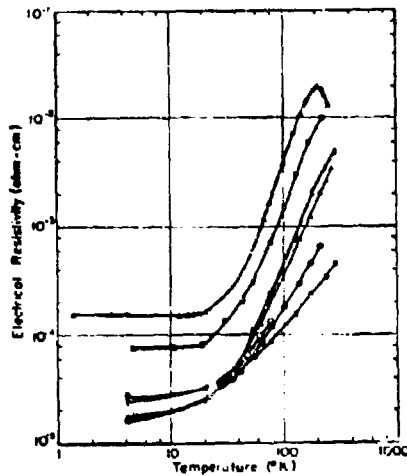


**BISMUTH TELLURIDE**

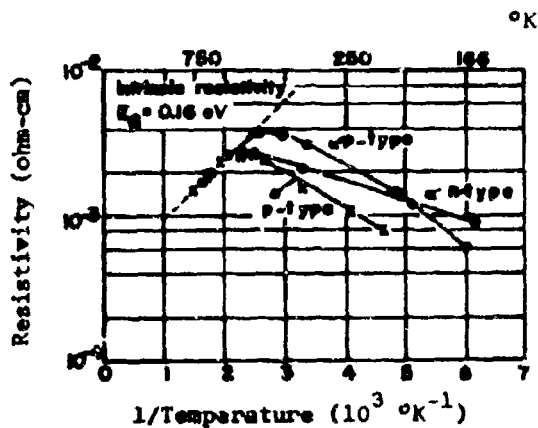
**ELECTRICAL RESISTIVITY ( $\rho$ )**

Electrical resistivity as a function of temperature for tellurium doped, n-type  $\text{Bi}_2\text{Te}_3$ , single crystal.

	$n, \text{cm}^{-3}$
$\Delta$	$2.4 \times 10^{17}$
$\square$	$5.3 \times 10^{17}$
$\blacktriangle$	$3.0 \times 10^{18}$
$\diamond$	$3.4 \times 10^{18}$
$\circ$	-
$\bullet$	$1.2 \times 10^{19}$
$\blacksquare$	$6.8 \times 10^{19}$



[Ref. 14854]



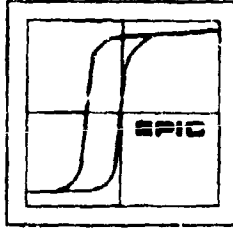
Resistivity as a function of reciprocal temperature for one n-type, and two p-type specimens of  $\text{Bi}_2\text{Te}_3$ . The samples are single crystal, n-type have excess tellurium or iodine.

$$n_p = 8 \times 10^{18} / \text{cc at } 300^\circ\text{K}$$

p-type are bismuth or lead-doped

$$n_n = 5 \times 10^{18} / \text{cc at } 300^\circ\text{K}$$

[Ref. 2624]

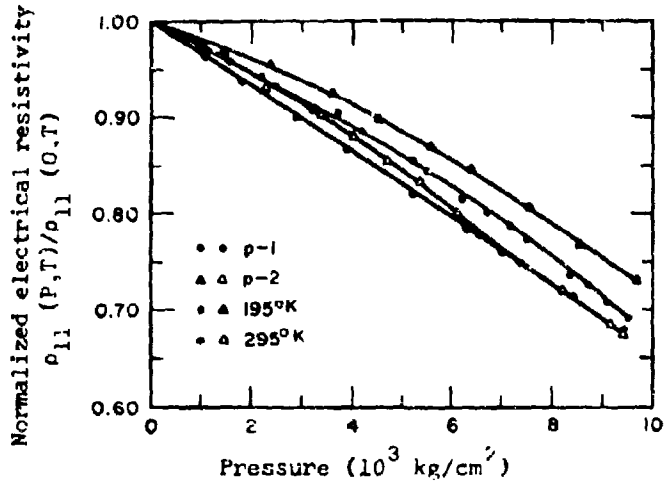


BISMUTH TELLURIDE

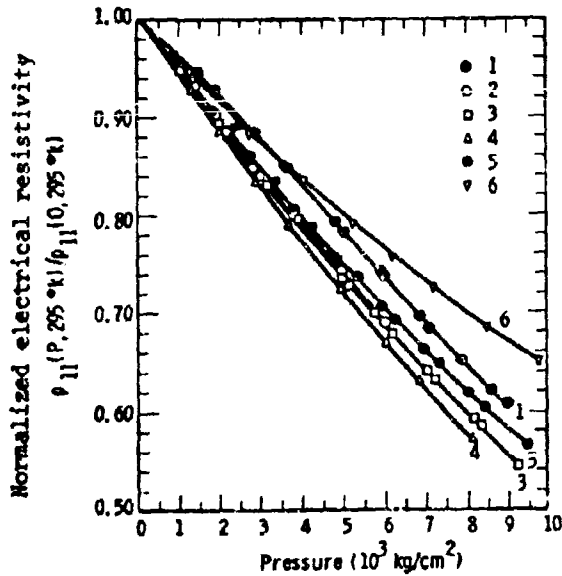
ELECTRICAL RESISTIVITY

Normalized electrical resistivity as a function of pressure for two single crystal, p-type, Te-doped  $\text{Bi}_2\text{Te}_3$  samples at two temperatures. Current normal to the rotation axis and parallel to (0001).

T is given temperature  
P is pressure  
O is zero pressure

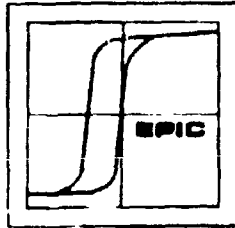


[Ref. 18361]



Normalized electrical resistivity as a function of pressure for single crystal, n-type, Te-doped  $\text{Bi}_2\text{Te}_3$  at 295°K. Current normal to rotation axis, parallel to (0001). Carrier concentration is lowest for sample #1, and highest for #6.

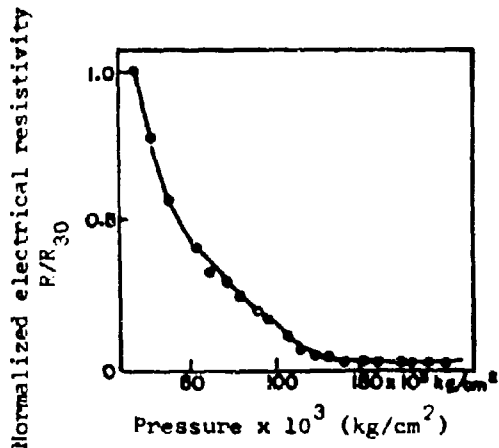
[Ref. 18361]



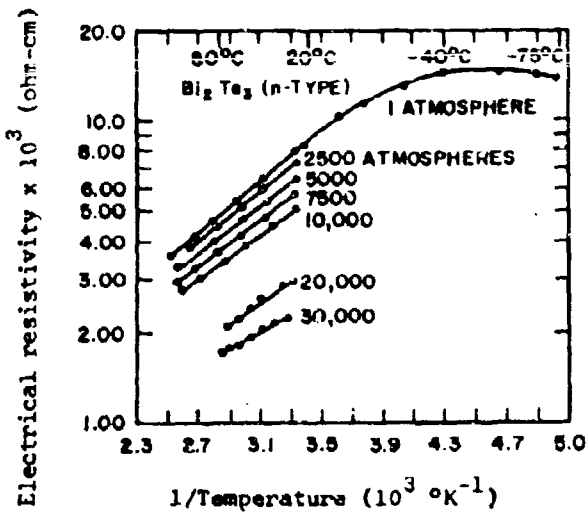
BISMUTH TELLURIDE

ELECTRICAL RESISTIVITY

Variation of a normalized electrical resistance of  $\text{Bi}_2\text{Te}_3$  with pressure up to 200 000 atm at 300°K.  $R_{30}$  is electrical resistance at 25 500  $\text{kg}/\text{cm}^2$  and is taken as the initial resistance.

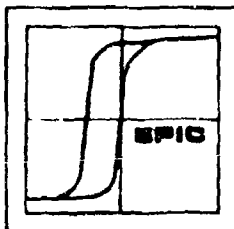


[Ref. 16009]



Resistivity as a function of reciprocal temperature for  $\text{Bi}_2\text{Te}_3$  single crystal, from 1 to 30 000 atmospheres.

[Ref. 21112]



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**BISMUTH TELLURIDE**

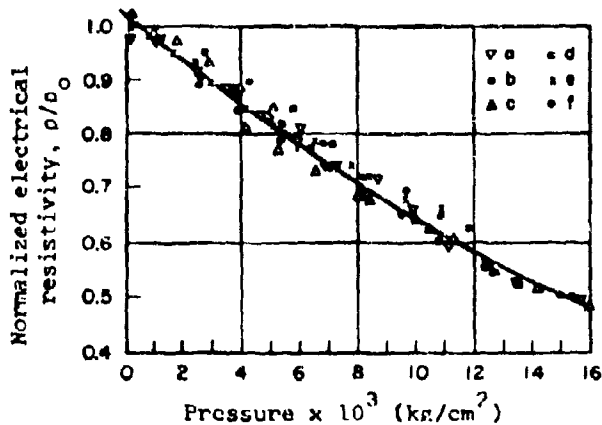
**ELECTRICAL RESISTIVITY**

Effect of hydrostatic pressure on the normalized electrical resistivity of  $\text{Bi}_2\text{Te}_3$  at 300°K.

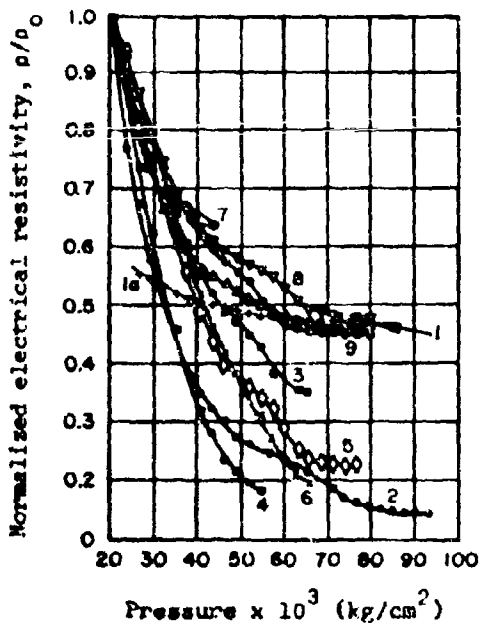
- a, b: sample I, p-type
- c, d: sample II, p-type
- e, f: 2 samples, n-type
- a, c, e, at increasing pressure
- c, d, f, at decreasing pressure

Piezocoefficient of resistivity for 1 to  $15 \times 10^3$  kg/cm<sup>2</sup>.

$[1/R : \Delta R / \Delta P = 3.5 \times 10^{-5} / \text{kg cm}^{-2}]$ .



[Ref. 16204]

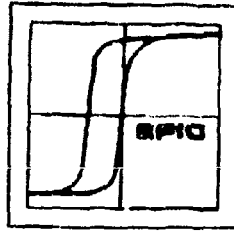


Normalized electrical resistivity of single crystal  $\text{Bi}_2\text{Te}_3$  as a function of hydrostatic pressures of 20-95 kg/cm<sup>2</sup> at 300°K.

- 1, 2: sample I, p-type
- 3, 4, 5, 6, 7: sample II, p-type
- 8, 9: 2 samples, n-type

All curves at increasing pressure, except 1a, at decreasing pressure.

[Ref. 16204]



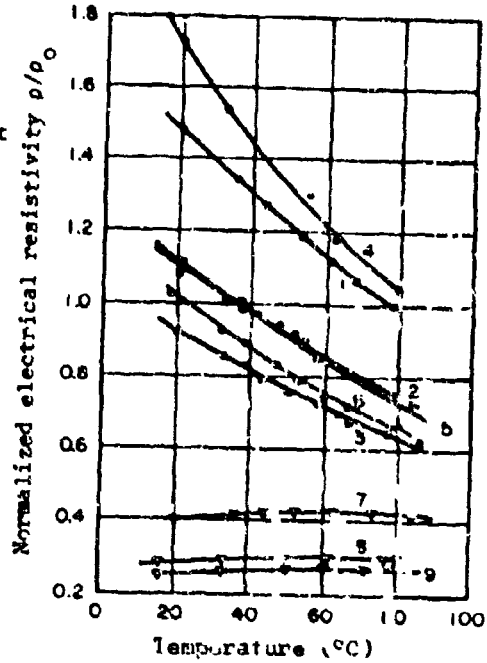
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BISMUTH TELLURIDE

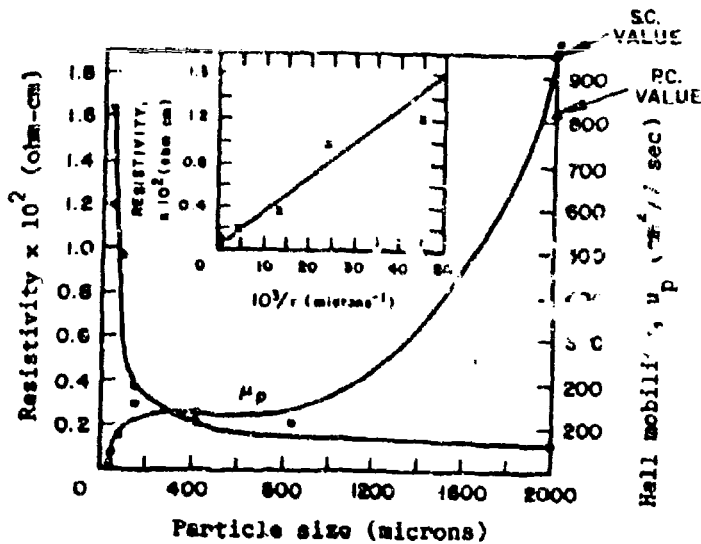
ELECTRICAL RESISTIVITY

Electrical resistivity of single crystal  $\text{Bi}_2\text{Te}_3$  as a function of temperature at several constant hydrostatic pressures.

Sample	Type	Pressure (kg/cm <sup>2</sup> )
1	p	atmospheric
2	p	5 870
3	p	10 365
4	p	atmospheric
5	pp	8 340
6	p	11 150
7	n	atmospheric
8	n	8 290
9	n	11 650



[Ref. 16204]

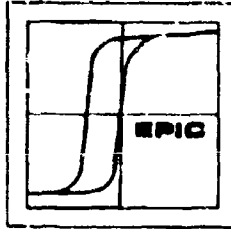


Resistivity and Hall mobility of pressed  $\text{Bi}_2\text{Te}_3$  powders as a function of grain size at 77°K. The powders are p-type,  $n \sim 2 \times 10^{19}/\text{cc}$ .

S.C. is single crystal  
P.C. is polycrystalline

$r$  is  $\frac{\text{grain boundary area}}{\text{grain boundary volume}}$

[Ref. 8758]



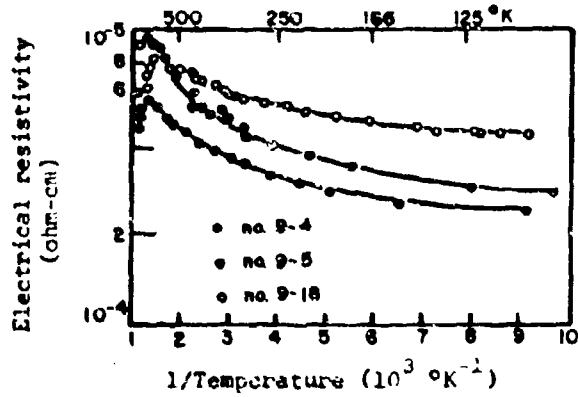
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BISMUTH SELENIDE

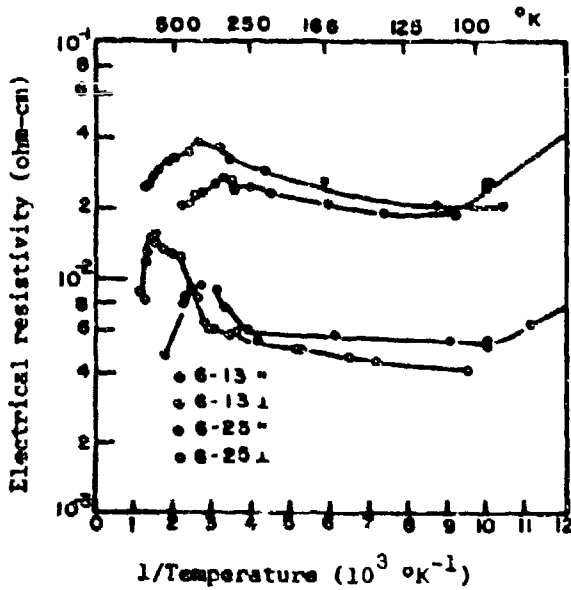
ELECTRICAL RESISTIVITY

Electrical resistivity as a function of reciprocal temperature for polycrystalline BiSe.

Sample	$n, \text{cm}^{-3}$
9-4	$2.0 \times 10^{20}$
9-5	$2.5 \times 10^{20}$
9-18	$2.2 \times 10^{20}$



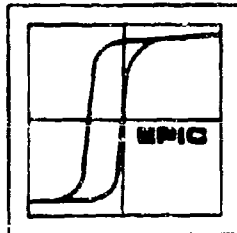
[Ref. 3097]



Electrical resistivity as a function of reciprocal temperature for single crystal  $\text{Bi}_2\text{Se}_3$ , (0001) cleavage plane.

Sample	$n, \text{cm}^{-3}$
6-13, parallel	$3.3 \times 10^{18}$
6-13, normal	$2.5 \times 10^{18}$
6-25, parallel	$2.30 \times 10^{18}$
6-25, normal	$1.82 \times 10^{18}$

[Ref. 3097]

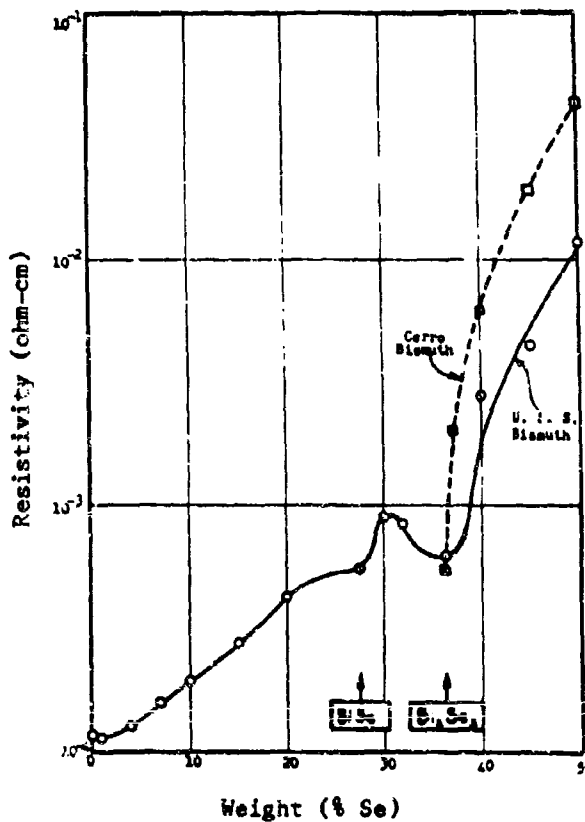


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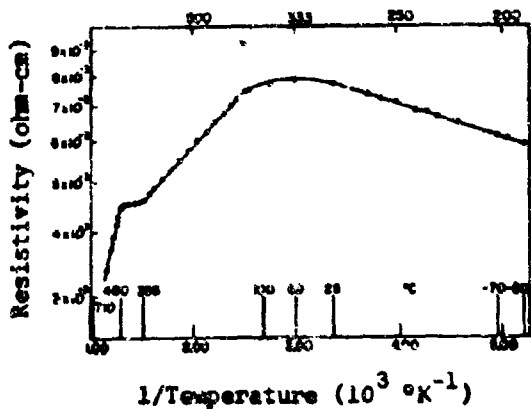
**BISMUTH SELENIDE**

**ELECTRICAL RESISTIVITY**

Electrical resistivity of BiSe alloys as a function of Se content at 300°K. The alloys were macrocrystalline. A high purity grade of selenium was used with two commercial grades of bismuth. The Cerro bismuth was purer than the U.S.S. brand, although the latter was purified before use.



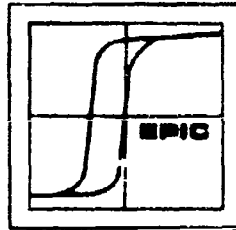
[Ref. 12851]



Electrical resistivity as a function of reciprocal temperature for single crystal, n-type Bi<sub>2</sub>Se<sub>3</sub>, parallel (0001). Temperature in °C is also given.

[Ref. 7839]





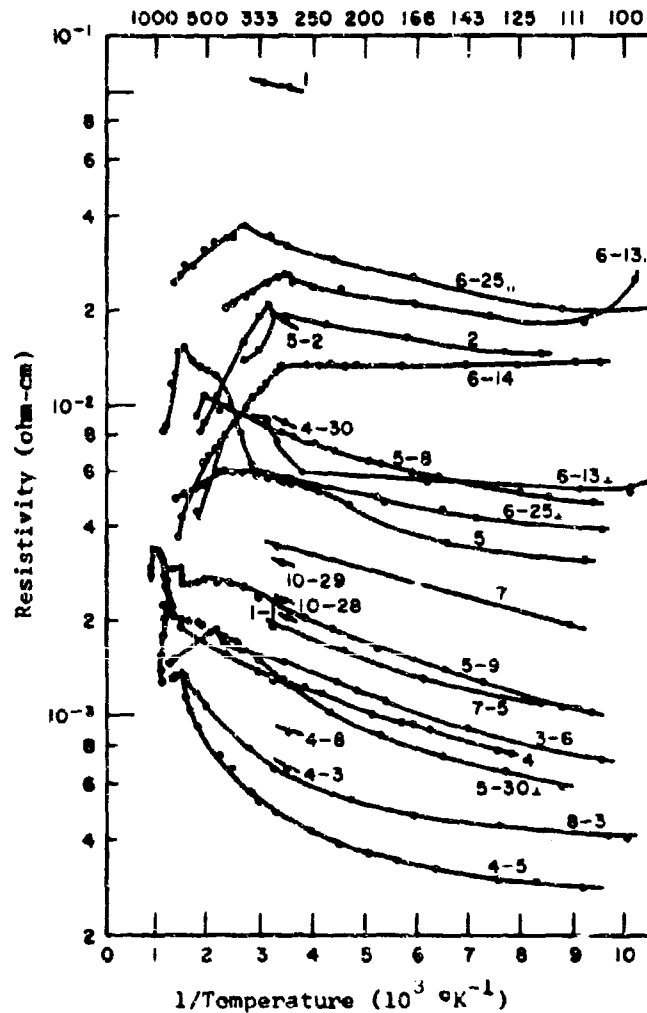
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BISMUTH SELENIDE

ELECTRICAL RESISTIVITY

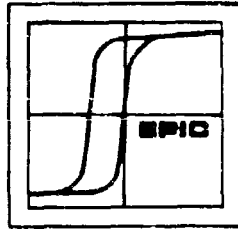
°K

Sample	$n, \text{cm}^{-3}$	remarks
1	0.08	
1-1	0.25	
2	1.0	
3-6	2.1	zone melt
4	22.0	
4-3	52	
4-5	16	
4-8	1200	
4-30		
5	2.44	
5-2		
5-8	9.0	
5-9	3.0	
5-30	3.20	single crystal
6		single crystal
6-13	3.3	parallel
	2.5	normal
6-14	0.598	
6-14-1	0.74	
6-25	2.30	parallel,
	1.82	single crystal
	1.5	normal
7	1.5	0.077% In-doped
7-5	6.6	1.2% In-doped
8-3	6.28	
10-28		0.01% Cu-doped
10-29		0.1% Cu-doped



Electrical resistivity as a function of reciprocal temperature in single and polycrystalline  $\text{Bi}_2\text{Se}_3$ .

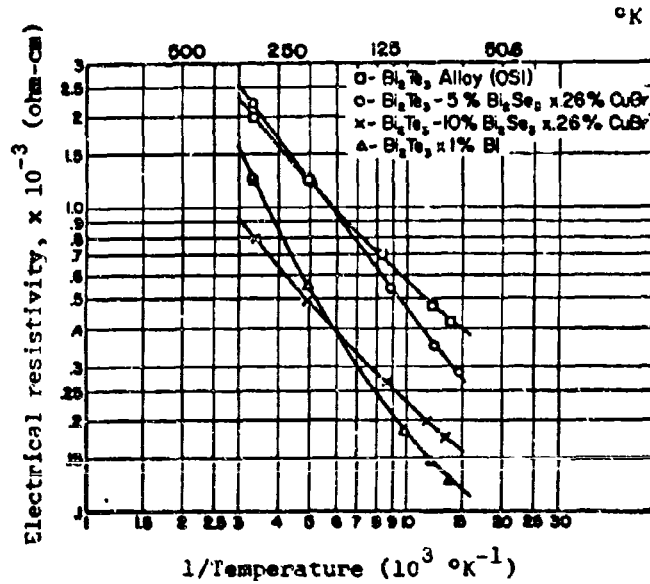
[Ref. 3097]



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BISMUTH TELLURIDE-BISMUTH SELLENIDE ( $\text{Bi}_2\text{Te}_3\text{-xSe}_x$ )

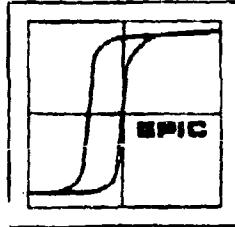
ELECTRICAL RESISTIVITY



Electrical resistivity as a function of temperature for two  $\text{Bi}_2\text{Te}_3\text{-Bi}_2\text{Se}_3$  alloys, also two  $\text{Bi}_2\text{Te}_3$  samples, one is n-type, the other is p-type.

[Ref. 15503]

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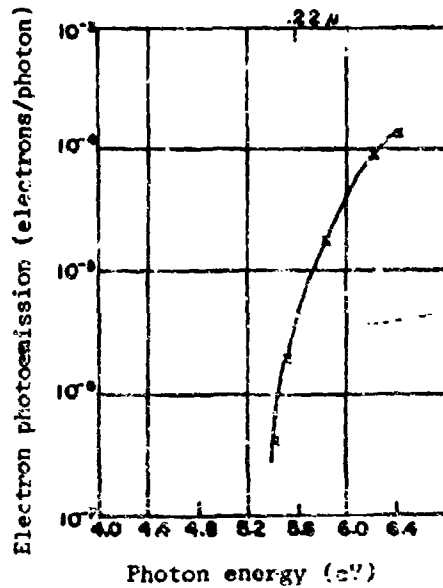


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BISMUTH TELLURIDE

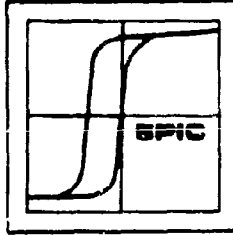
ELECTRON PHOTOEMISSION



Electron photoemission yield as a function of photon energy for freshly cleaved single crystal Bi<sub>2</sub>Te<sub>3</sub>, (001), at 300°K and fields up to ~ 5 volts.

[Ref. 493]

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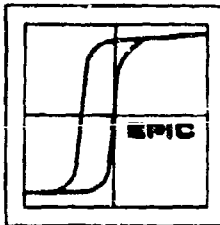
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BISMUTH TELLURIDE

ELECTRONIC SPECIFIC HEAT ( $\gamma$ )

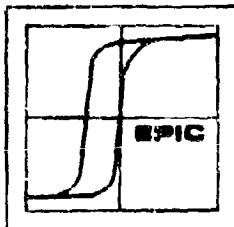
<u>Symbol</u>	<u>Value</u>	<u>Sample</u>	<u>Test Method</u>	<u>Temperature</u>	<u>Ref.</u>
$\gamma$	$17 \pm 8 \times 10^{-5}$ joul/deg <sup>2</sup> /g-atom	macrocrystalline p-type	specific heat	1.37-65°K	7764



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BISMUTH TELLURIDE, BISMUTH SELENIDE, and the BISMUTH TELLURIDE-BISMUTH SELENIDE SYSTEM

ENERGY BANDS	Symbol	Value	Bi <sub>2</sub> Te <sub>3</sub>	Sample (single crystal)	Measurement Method	Temperature	Ref.
$\Delta E_g/\Delta T$		$-0.95 \times 10^{-4}$ eV/°K		p-type, cleavage parallel to (0001), nearly intrinsic	optical absorption	118, 152 & 293°K	3124
$\Delta E_g/\Delta T$		$-0.9 \times 10^{-4}$ eV/°K		p-type, $n_{300K} = 10^{19}$ /cc	IR transmission	77 & 300°K	2866
$\Delta E_g/\Delta P$		$\sim -2 \times 10^{-6}$ eV/atm		n-type, $n \sim 10^{17}$ /cc .18 mm section	resistivity meas. 1 to 30 000 atm	200-400°K	21112
$\Delta E_g/\Delta P$		$-6 \times 10^{-5}$ eV/atm (above 25 000 atm)		p-type, (0001) oriented 0.1-0.3mm thick section	electrical resistivity	300°K	16204
$\Delta E_g/\Delta P \rightarrow 0$		above 40-45 kbar.		$E_g \rightarrow 0$ (metallic state)			16204
<u>Bi<sub>2</sub>Se<sub>3</sub></u>							
$\Delta E_g/\Delta T$		$-2 \times 10^{-4}$ eV/°K		n-type, $n_{300K} = 2 \times 10^{19}$ /cc	IR transmission	77 & 300°K	2866
$\Delta E_g/\Delta T$		-5. to $-1. \times 10^{-4}$ eV/°K		n-type	reflectivity	77-300°K	22468
<u>60% Bi<sub>2</sub>Se<sub>3</sub>-40% Bi<sub>2</sub>Te<sub>3</sub></u>							
$\Delta E_g/\Delta T$		$-5 \times 10^{-4}$ eV/°K		n-type	reflectivity	77-300°K	22468

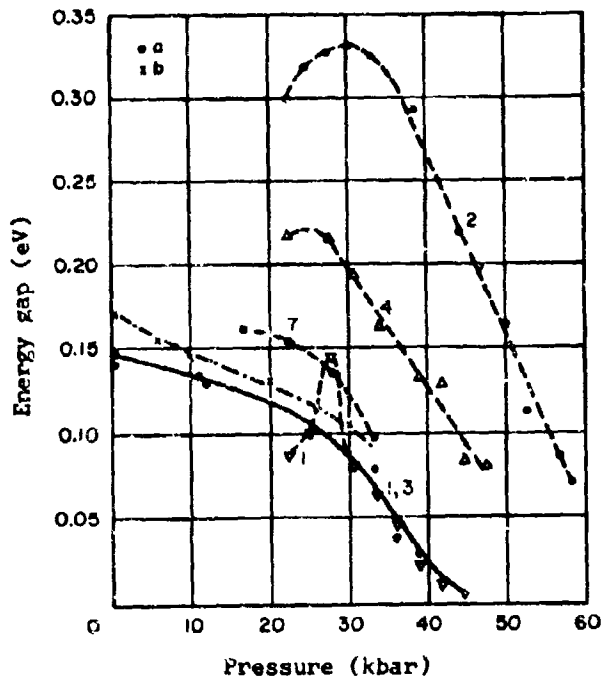


**BISMUTH TELLURIDE**

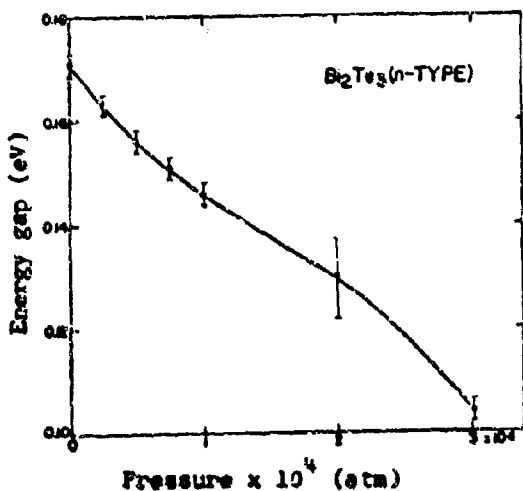
**ENERGY BANDS**

Effect of pressure on energy gap for p-type, single crystal  $\text{Bi}_2\text{Te}_3$ , (0001).  
a) Measured by the hydrostatic method;  
b) data from [Ref. 21112]. Although the slope remains fairly constant the absolute values vary, due possibly, to deformation during experiment.

Sample 1 and 2 are cut from one single crystal, 3, 4, and 7 from another single crystal.

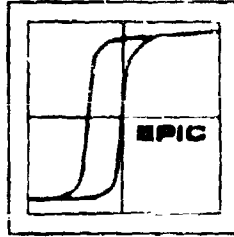


[Ref. 16204]



Shift in energy gap with pressure in n-type, single crystal  $\text{Bi}_2\text{Te}_3$ ,  $n \sim 10^{17}/\text{cc}$ . At 1 atm. measurements were made from 199-393°K. At higher pressures, 300°K was the lower temperature limit.

[Ref. 21112]



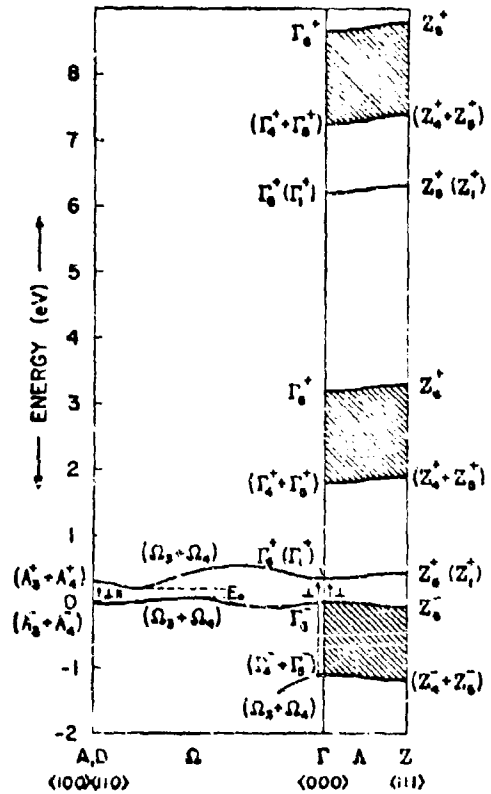
BISMUTH TELLURIDE-BISMUTH SELENIDE ( $\text{Bi}_2\text{Te}_{3-x}\text{Se}_x$ )

ENERGY BANDS

$\Gamma_A$  and  $\Gamma_D$  are degenerate. Five bands nearly horizontal across the  $\Gamma Z$  direction are assumed. They show small energy differences at  $\Gamma$  and  $Z$ .  $\Gamma_6(\Gamma_1)$  characterizes the  $\Gamma_5$  states arising from nondegenerate states of the single group.

The scheme explains the occurrence of the satellite peaks in the reflectivity spectra of the alloys as the energy distance of a certain gap at  $\Gamma$  and  $Z$  increases and resolution in the spectra becomes possible.

Derived from reflectivity data at 77-300°K on single crystal  $\text{Bi}_2\text{Te}_3$ ,  $\text{Bi}_2\text{Se}_3$  and polycrystalline alloys of these two compounds in varying proportions.



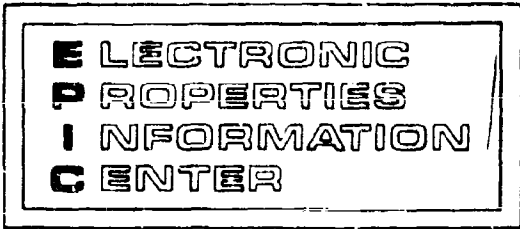
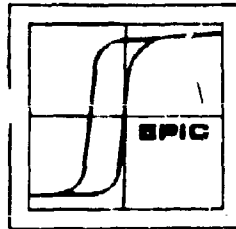
[Ref. 22468]

"In  $\text{Bi}_2\text{Te}_3$  the surfaces of constant energy are almost spheroidal and are highly compressed in a direction nearly parallel to the three-fold axis of rotation of the crystal."

[Ref. 2360]

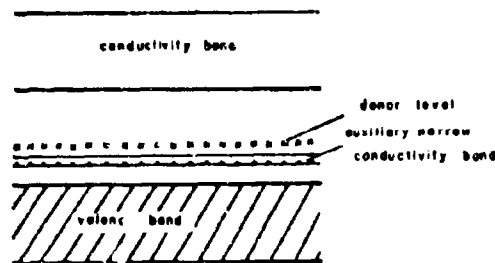
"In  $\text{Bi}_2\text{Se}_3$  the surfaces of constant energy are ellipsoidal and are compressed in the x-direction and extended nearly parallel to the three-fold axis of rotation."

[Ref. 3350]



BISMUTH TELLURIDE-BISMUTH SELENIDE ( $\text{Bi}_2\text{Te}_{3-x}\text{Se}_x$ )

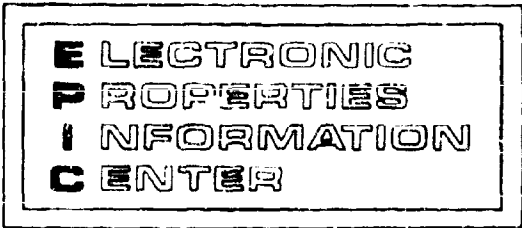
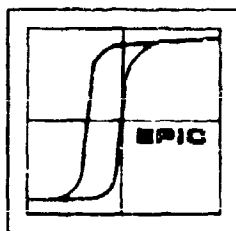
ENERGY BANDS



If a few donors are present over the narrow conductivity band, then weak n-type conductivity occurs at low temperatures. As the temperature rises, transitions take place from the valence to the narrow conduction band. As the narrow band is filled, the conductivity increases. As a consequence of the temperature dependence of the mobility, there is a conductivity decrease until intrinsic conductivity begins, i.e., until there is a transition of electrons into the main conductivity band. Because of the higher mobility in this band, there ensues the second sign change in the Hall field and the thermal emf. Since the energy gap is smaller for the telluride than the mixed telluride-selenide, the narrow band for the bismuth telluride possibly lies nearer the conductivity band, with the result that the saturation effect in the electrical conductivity is covered by the intrinsic conductivity.

[Ref. 10384]





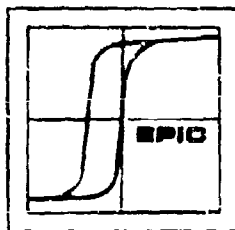
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BISMUTH TELLURIDE

ENERGY GAP ( $E_g$ )

<u>Value(eV)</u>	<u>Sample</u>	<u>Test Measurement</u>	<u>Temperature</u>	<u>Ref.</u>
0.16	single and macrocrystalline, intrinsic (iodine compensated)	electrical conductivity	0°K	2595
0.171	single crystal, n-type, $n \sim 10^{17}/cc$	electrical resistivity, 1-30 000 atm., 199-393°K	0°K	21112
0.21	single crystal, p-type, cleavage normal to c-axis (0001) $n_p = 1.4 \times 10^{19}/cc$	electrical	0°K	407
0.16*	single crystal, highly purified	optical	77°K	2866
0.18	single crystal, less pure	"	"	2866
0.20	single crystal, cleavage plane (0001) n-type, $n = 3$ and $9 \times 10^{17}/cc$ , p-type, $n = 3$ and $4 \times 10^{18}$ zone refined, p-type, $n = 2 \times 10^{19}$	electrical	77-375°K	801
0.13	single crystal, p-type, intrinsic, parallel (0001)	optical, $\lambda = 8-14\mu$	300°K	3124
0.14	single crystal, p-type, (0001) $n = 5 \times 10^{17}/cc$	electrical conductivity	300°K	10535
0.15*	single crystal, highly purified	optical	300°K	2866

\* value for purest material



BISMUTH SELENIDE

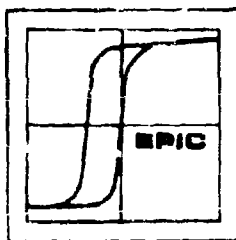
ENERGY GAP (E<sub>g</sub>)

Value (eV)	Sample	Test Measurement	Temperature	Ref.
0.275	polycrystalline	IR transmission	300°K	2785
0.35	single crystal	IR optical and transition	300°K	2866
0.40	"	"	77°K	2866
0.36	single crystal, n-type, parallel (0001), n <sub>300K</sub> = 5x10 <sup>17</sup> /cc	electrical	> 750°K	7839
0.23	polycrystalline, n-type	elec. resist.	0°K	3097
0.2	"	optical abn. at 1-8μ		
0.4	"	elec. resist.		3097

BISMUTH TELLURIDE-BISMUTH SELENIDE (Bi<sub>2</sub>Te<sub>3-x</sub>Se<sub>x</sub>)

ENERGY GAP (E<sub>g</sub>)

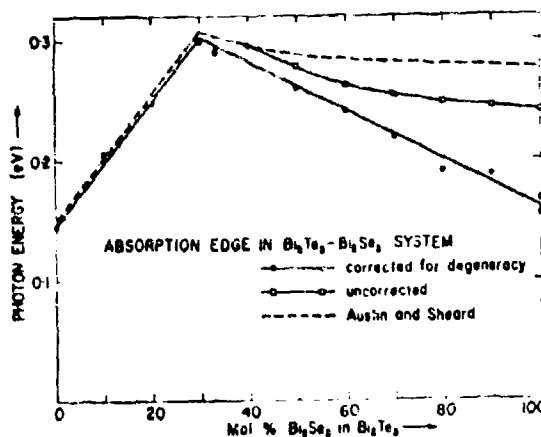
Thermal (eV)	Optical (eV)	single crystal, doped or compensated, 0 ≤ x ≤ 1, (low conductivity)	Test Measurement	Temperature	Ref.
0.16	0.15	Bi <sub>2</sub> Te <sub>3</sub>	electrical	300°K	10984
0.22	0.20	Bi <sub>2</sub> Te <sub>2.7</sub> Se <sub>0.3</sub>			
0.29	0.30	Bi <sub>2</sub> Te <sub>2</sub> Se			10984



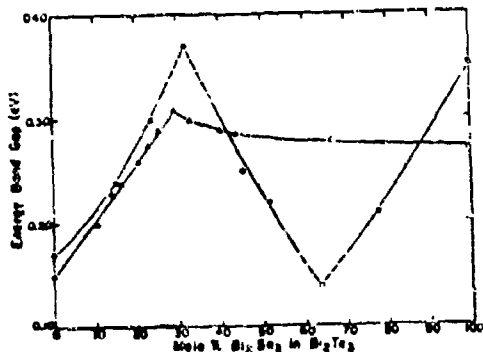
BISMUTH TELLURIDE-BISMUTH SELENIDE SYSTEM

ENERGY GAP

Absorption edge as a function of composition in single crystal samples in the bismuth telluride-bismuth selenide system. Incident illumination normal to (0001) cleavage plane.



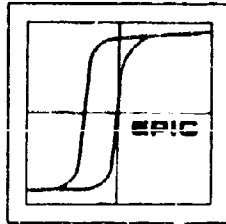
[Ref. 22468]



Energy gap as a function of composition for single crystal sample. Data taken by electrical resistivity measurements, parallel to (0001).

- Miller et al. (thermal) [Ref. 15551]
- Smith et al. (thermal) [Ref. 7839]
- Black et al. (optical) [Ref. 2866]
- ▲ Austin and Sheard (optical) [Ref. 2785]

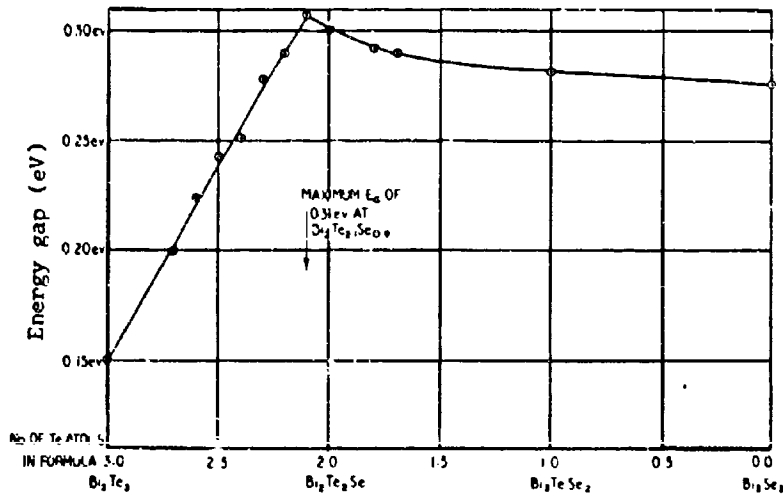
[Ref. 15551]



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BISMUTH TELLURIDE-BISMUTH SELENIDE ( $\text{Bi}_2\text{Te}_{3-x}\text{Se}_x$ )

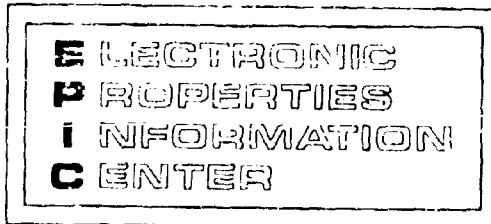
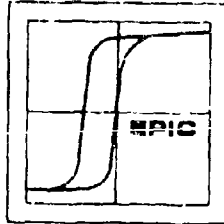
ENERGY GAP



Energy gap as a function of composition for  $\text{Bi}_2\text{Te}_3\text{-Bi}_2\text{Se}_3$ .

Samples were polycrystalline and purified. A single hexagonal phase was shown with slight point-to-point inhomogeneity in samples with over 16 at.% of selenium.

[Ref. 2785]



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BISMUTH TELLURIDE

ENERGY LEVELS

<u>Symbol</u>	<u>Value (eV)</u>	<u>Dopant</u>	<u>Sample</u>	<u>Test Method</u>	<u>Temperature</u>	<u>Ref.</u>
$E_m$	0.5-0.7	deformation for Bi vacancies and	single crystal, p-type	elec. resist.	300°K	5890
$E_m$	1.09-1.1	Te vacancies	"	"	"	5890

$E_m$  is an activation energy for vacancy motion arising from plastic deformation which introduces defects that change p-type material to n-type.

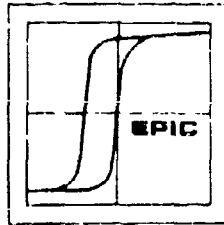
Oxygen and copper act as donors.

$E_A$	~ 0.4	Ge	macrocrystalline, normal (0001), $n = 2 \times 10^{19}/cc$	electrical conductivity	300°K	15813
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Stoichiometric  $Bi_2Te_3$  is always p-type, but excess Te or halogens change it to n-type. The very high diffusion rate of copper in  $Bi_2Te_3$  produces an n-type material. 2595

Iodine acts as a donor in  $Bi_2Te_3$ . Tin apparently is associated with a trapping level at 0.01 eV as is seen from Hall measurements between 77° and 200°K. 8730

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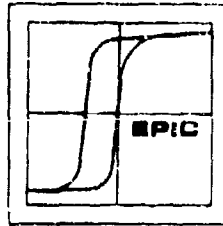
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BISMUTH SLENIDE

ENERGY LEVELS

<u>Symbol</u>	<u>Value (eV)</u>	<u>Sample</u>	<u>Test Method</u>	<u>Temperature</u>	<u>Ref.</u>
$E_D$	0.09 <sub>CB</sub>	single crystal, n-type, parallel (0001), $n_{300K} = 5 \times 10^{17}/cc$	resistivity and Hall	125-350°K	7839

0.01%  $Bi_2O_3$  added to  $Bi_{2.4}Te_{2.4}Se_{0.6}$  polycrystalline, n-type,  $n \sim 10^{19}/cc$ , causes a 40% decrease in conductivity, but no change in thermal emf. Further addition has no effect on conduction. 4382



BISMUTH TELLURIDE-BISMUTH SELENIDE ( $\text{Bi}_2\text{Te}_{3-x}\text{Se}_x$ )

ENERGY LEVELS

Composition mol %		Thickness ( $\mu$ )	$\alpha$ ( $\mu\text{V}/\text{deg}$ )	Type	$\zeta^*$	$\{-E_{co}$ at 300°K (eV)	$\lambda_g$ ( $\mu$ )	$\Gamma_x$ (eV)	$E_{g,corr}$ (eV)
$\text{Bi}_2\text{Te}_3$	$\text{Bi}_2\text{Se}_3$								
100	—	3	253	p					
100	—	17	253	p	-1.2		8.53	0.145	0.145
90	10	20	217	p	-0.7		5.98	0.203	0.203
90	10	31	217	p	-0.7		6.10	0.207	0.207
80	20	8	229	p	-0.9		4.95	0.246	0.246
80	20	30	224	p	-0.85		5.05	0.250	0.250
70	30	40	-246	n	-0.9		4.15	0.299	0.299
66.7	33.3	21	-240	n	-0.75		4.30	0.287	0.259
60	40	38	-218	n	-0.5		4.20	0.295	0.295
50	50	29	-153	n	0.7	0.018	4.45	0.278	0.260
40	60	39	-148	n	0.75	0.02	4.75	0.262	0.242
30	70	21	-120	n	1.3	0.04	4.90	0.253	0.219
20	80	15	-90	n	2.2	0.057	5.00	0.248	0.191
10	90	31	-91	n	2.2	0.057	5.08	0.244	0.187
0	100	25	-66	n	3.3	0.066	5.15	0.241	0.155
0	100	18	-55.5	n	~4.0		5.38	0.230	
0	100	25	-73	n	3.0	0.078	5.06	0.245	0.167

The Fermi level and energy gap values in this table, are derived from reflectivity data for a series of single crystal members of the bismuth telluride-bismuth selenide system. Measurements are made at 0.1 to 12 eV and 300°K. Incident light is both normal and parallel to the (0001) cleavage plane.

$\alpha$  is the thermoelectric emf

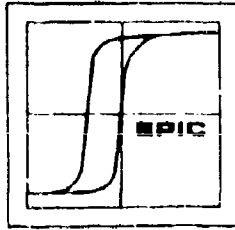
$\zeta^*$  is the reduced Fermi level and is determined from thermoelectric data

$E_g$  is the energy gap determined at the wavelength corresponding to an interband contribution of  $K_{int} = 600 \text{ cm}^{-1}$

$\lambda_g$  is the incident wavelength in microns

The energy gap values are also corrected for degeneracy.

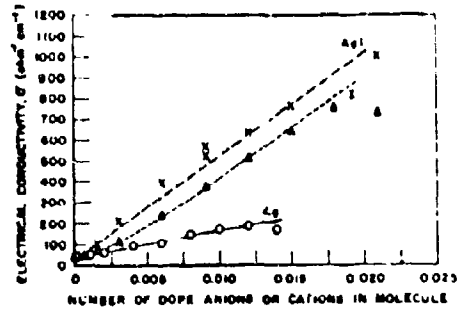
[Ref. 22468]



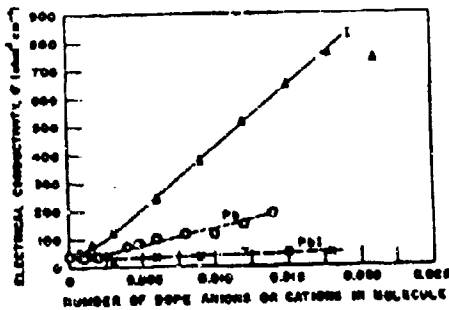
BISMUTH TELLURIDE-BISMUTH SELENIDE ( $\text{Bi}_2\text{Te}_{3-x}\text{Se}_x$ )

ENERGY LEVELS

Electrical conductivity as a function of dopant concentration in polycrystalline  $\text{Bi}_2\text{Te}_{2.1}\text{Se}_{0.9}$ . The dopant is added as either silver, iodine or the silver iodide; the increase in conductivity is cumulative. In the case of the lead, lead iodide or iodine additions, the iodine produces n-type material, whereas the lead yields p-type, resulting in a compensating action for the lead iodide.



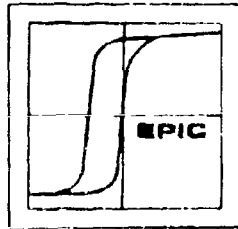
[Ref. 316]



Electrical conductivity as a function of dopant concentration in polycrystalline  $\text{Bi}_2\text{Te}_{2.1}\text{Se}_{0.9}$ .

[Ref. 316]



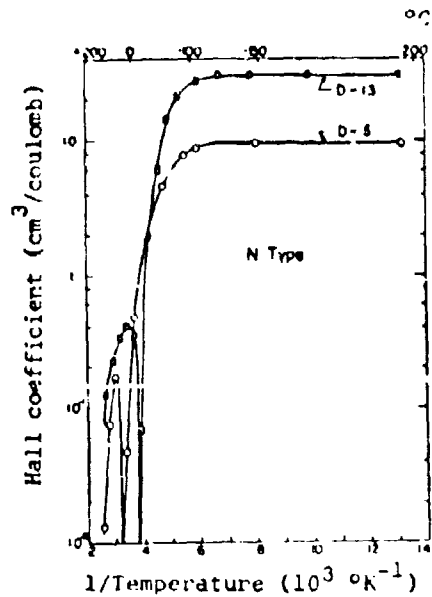


BISMUTH TELLURIDE

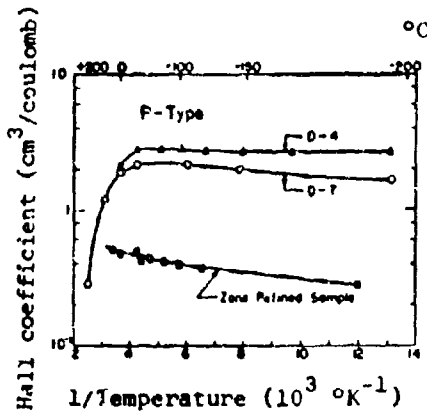
HALL COEFFICIENT ( $R_H$ )

Hall coefficient as a function of reciprocal temperature in single crystal, n-type bismuth telluride. The current and Hall voltage were parallel to the cleavage plane, and the magnetic field was perpendicular to the cleavage plane.

Sample	$n, \text{cm}^{-3}$
D-13	$3 \times 10^{17}$
D-5	$9 \times 10^{17}$



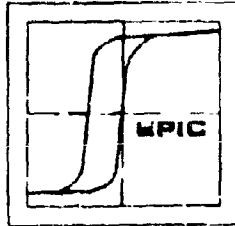
[Ref. 801]



Hall coefficient as a function of reciprocal temperature in single crystal, p-type bismuth telluride. The current and Hall voltage were parallel to the cleavage plane and the magnetic field was perpendicular to the cleavage plane.

Sample	$n, \text{cm}^{-3}$
D-4	$3 \times 10^{18}$
D-7	$4 \times 10^{18}$
Zone refined sample	$2 \times 10^{19}$

[Ref. 801]



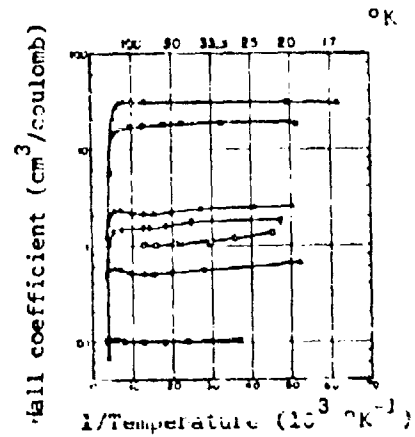
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BISMUTH TELLURIDE

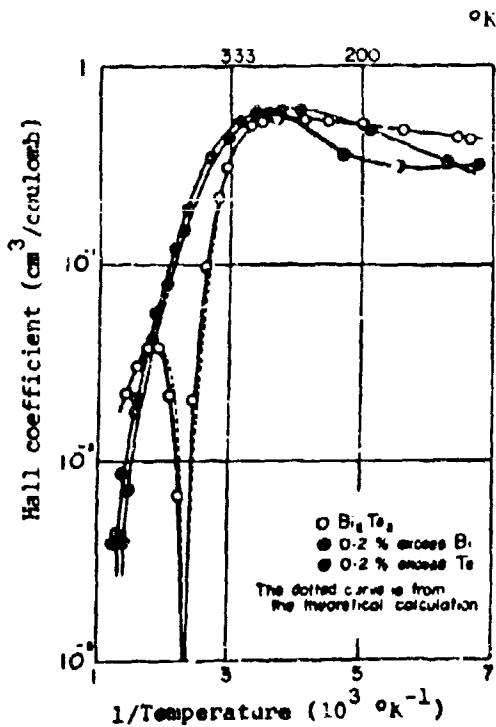
HALL COEFFICIENT

Hall coefficient as a function of reciprocal temperature for single crystal, n-type  $\text{Bi}_2\text{Te}_3$ , Te-doped.

Symbol	$n, \text{cm}^{-3}$
△	$2.4 \times 10^{17}$
□	$5.3 \times 10^{17}$
▲	$3.0 \times 10^{18}$
◇	$3.4 \times 10^{18}$
●	$1.2 \times 10^{19}$
■	$6.8 \times 10^{19}$
○	no data given

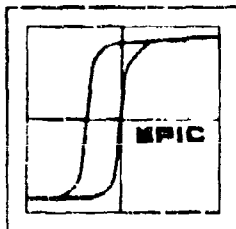


[Ref. 14854]



Hall coefficient in stoichiometric and 0.2% excess samples as a function of reciprocal temperature for p-type, single crystals, cut parallel to (0001) cleavage plane. Measurements were made at 4 kG,  $n = 1.4 \times 10^{19}/\text{cc}$ .

[Ref. 407]

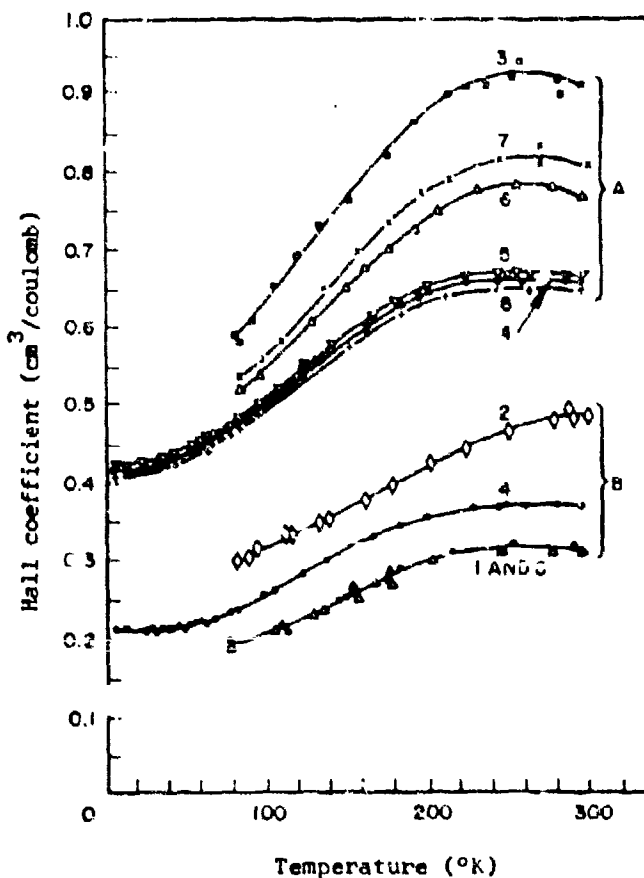


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BISMUTH TELLURIDE

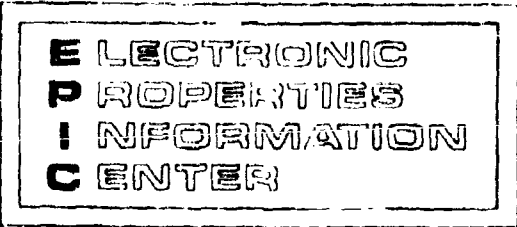
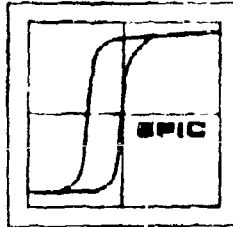
HALL COEFFICIENT

Sample		$n, \text{cm}^{-3}$ at 290°K
o	1	-
◇	2	-
○	3	-
*	4	normal $8.2 \times 10^{18}$
v	5	parallel $8.2 \times 10^{18}$
△	6	-
x	7	$2.9 \times 10^{18}$
+	8	-



The Hall coefficient as a function of temperature for zone purified, p-type, single crystal  $\text{Bi}_2\text{Te}_3$ . A) indicates the  $\rho_{231}$  tensor component: B) indicates the  $\rho_{123}$  tensor component, except 4 which is the transverse component. All samples cut parallel to the (0001) cleavage plane.

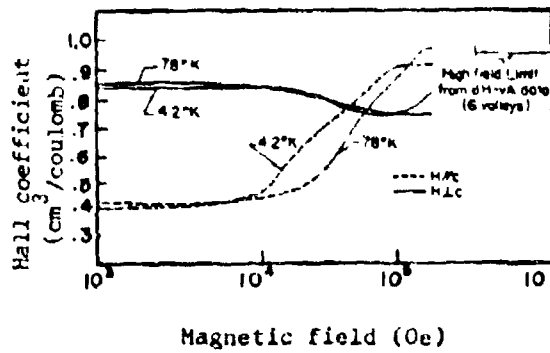
[Ref. 2984]



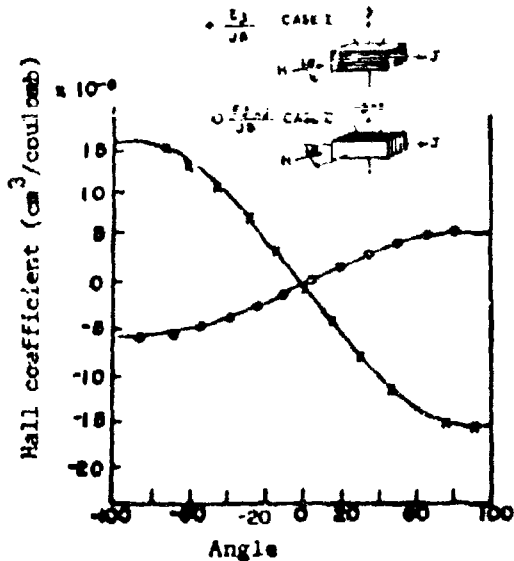
BISMUTH TELLURIDE

HALL COEFFICIENT

Hall coefficient as a function of field for single crystal, p-type  $\text{Bi}_2\text{Te}_3$  at 160 kG and 2 temperatures. Field is parallel or normal to (0001) cleavage plane.



[Ref. 11903]

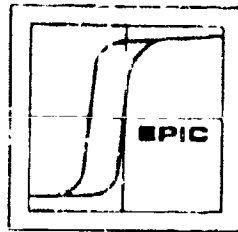


Hall coefficient as a function of angle between field and current at 77°K, in single crystal, n-type  $\text{Bi}_2\text{Te}_3$  with high iodine doping, cut parallel to (0001) cleavage plane.

- + data for field normal to (0001)
- o data for field parallel to (0001).

[Ref. 19045]

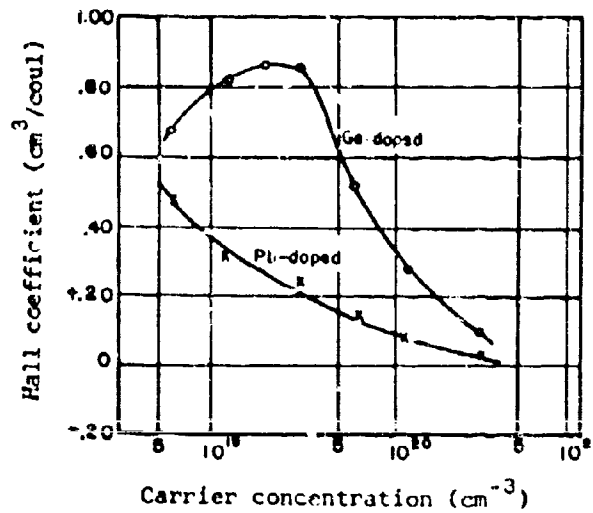
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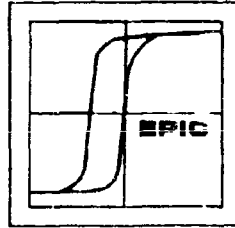
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BISMUTH TELLURIDE  
HALL COEFFICIENT



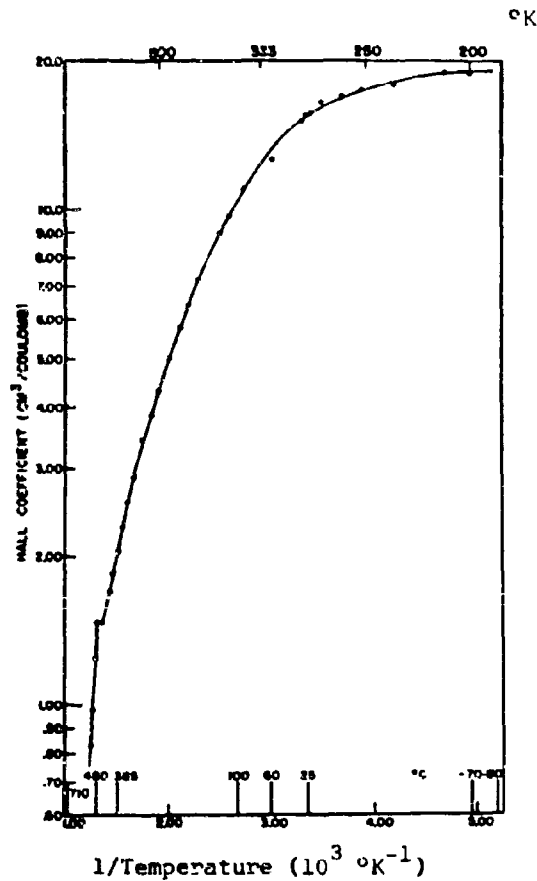
Hall coefficient as a function of carrier concentration at 300°K for macrocrystalline Bi<sub>2</sub>Te<sub>3</sub>. Lead-doped samples show steady decrease, whereas Ge-doped material has a maximum at 2x10<sup>19</sup>/cc.

[Ref. 15813]



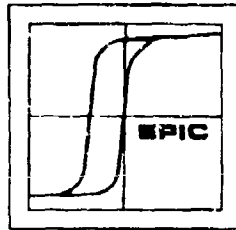
BISMUTH SELENIDE

HALL COEFFICIENT



Hall coefficient as a function of reciprocal temperature for Bi<sub>2</sub>Se<sub>3</sub> n-type, single crystal, parallel to cleavage plane, (0001).

[Ref. 7839]

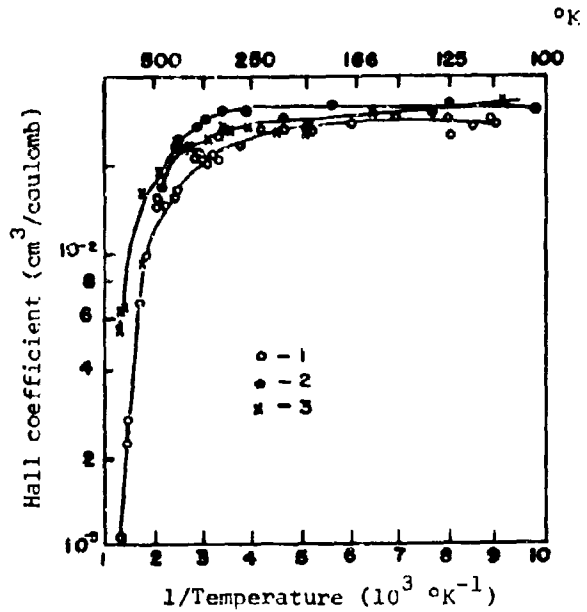


BISMUTH SELENIDE

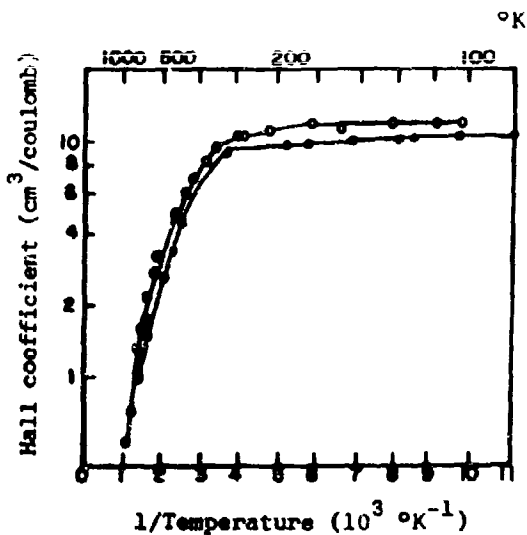
HALL COEFFICIENT

Hall coefficient as a function of reciprocal temperature for single crystal BiSe.

Sample	$n, \text{cm}^{-3}$
1	$2 \times 10^{20}$
2	$2.5 \times 10^{20}$
3	$2.2 \times 10^{20}$



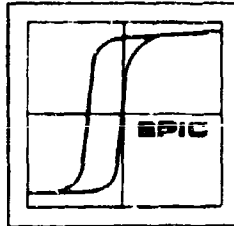
[Ref. 3097]



Hall coefficient as a function of reciprocal temperature in single crystal, n-type  $\text{Bi}_2\text{Se}_3$ .

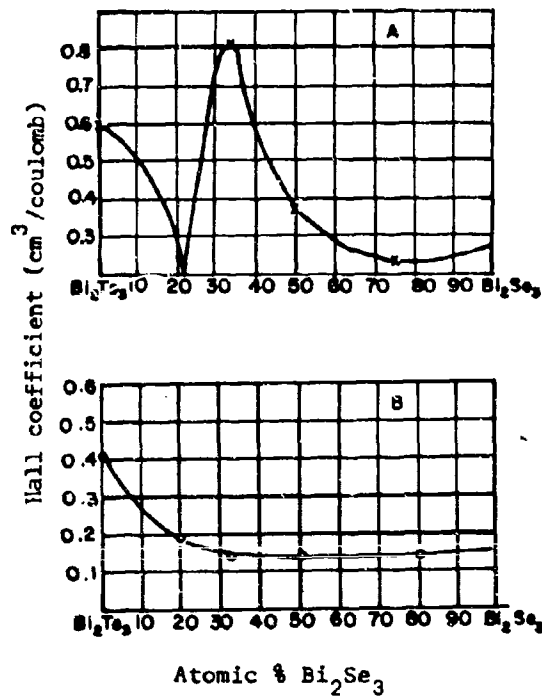
Sample	$n, \text{cm}^{-3}$
○	$6 \times 10^{17}$
●	$7 \times 10^{17}$

[Ref. 3097]



BISMUTH TELLURIDE-BISMUTH SELENIDE ( $\text{Bi}_2\text{Te}_{3-x}\text{Se}_x$ )

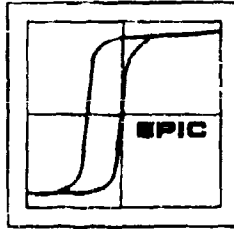
HALL COEFFICIENT



Hall coefficient as a function of composition at 300°K, in single crystal  $\text{Bi}_2\text{Te}_3$ - $\text{Bi}_2\text{Se}_3$  mixed crystals. A) is undoped, B) is silver iodide doped.

[Ref. 3867]





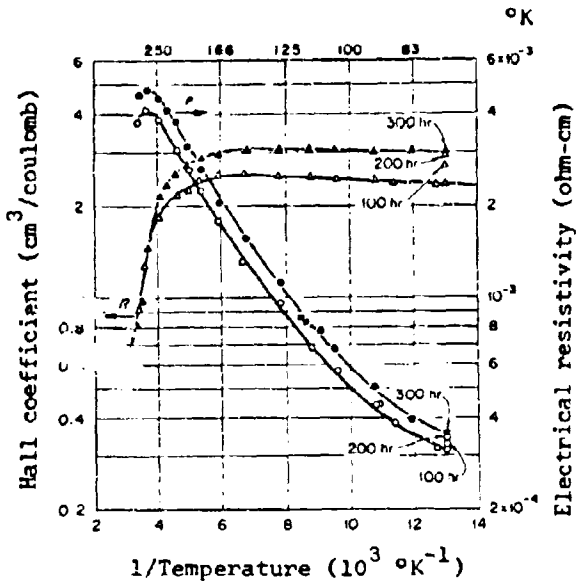
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**BISMUTH TELLURIDE**

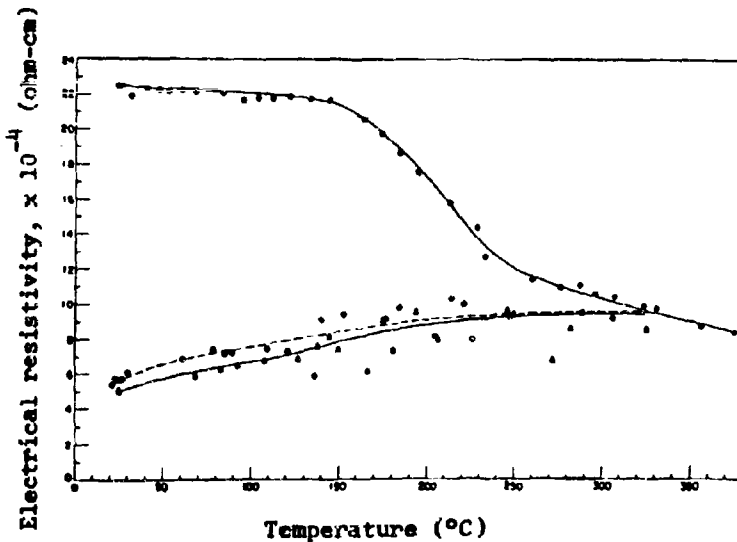
**IRRADIATION PROPERTIES**

Hall coefficient and electrical resistivity before and after 300-hr  $\text{Co}^{60}$ -gamma radiation as a function of reciprocal temperature for single crystal, n-type  $\text{Bi}_2\text{Te}_3$ ,  $n \sim 10^{18}/\text{cc}$ . In n-type samples the mobility reaches  $8500 \text{ cm}^2/\text{V sec}$  at  $77^\circ\text{K}$  after prolonged irradiation; in p-type, the mobility reaches  $7500$ .

- $\Delta, \circ$  before irradiation and up to 200 hours irradiation
- $\blacktriangle, \bullet$  after 300 hours irradiation.



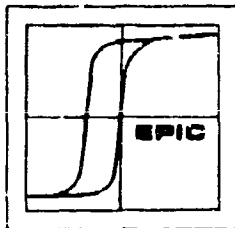
[Ref. 16462]



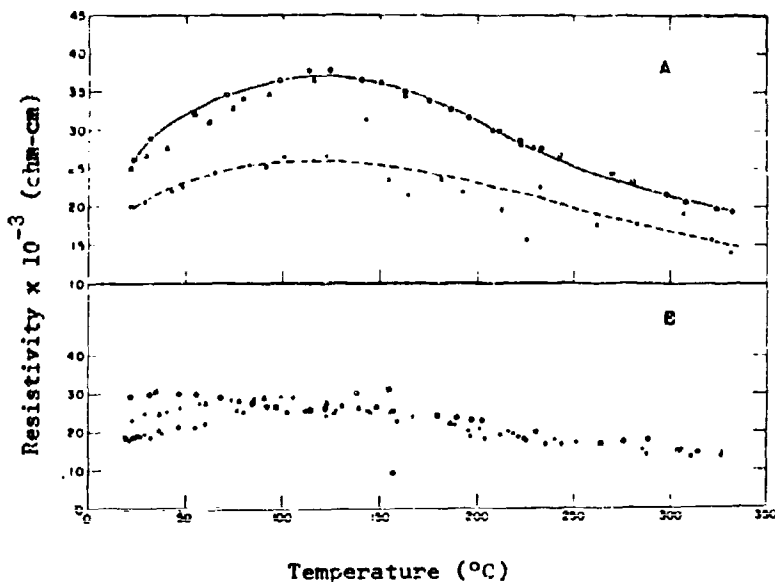
Electrical resistivity as a function of temperature in n-type polycrystalline  $\text{Bi}_2\text{Te}_3$ , irradiated by both thermal and fast neutrons to an integrated thermal flux of  $1.5 \times 10^{20}$  neutrons/cm<sup>2</sup> and  $1.6 \times 10^{19}$ /cm<sup>2</sup> flux of fast ( $> 1 \text{ meV}$ ) neutrons.

- $\circ$   $\text{Bi}_2\text{Te}_3$  irradiated without cadmium shield
- $\blacktriangle$  sample after annealing
- $\circ$  unirradiated sample

[Ref. 2737]



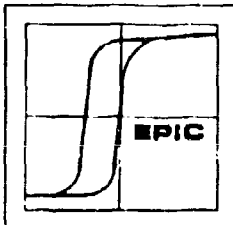
BISMUTH TELLURIDE  
IRRADIATION PROPERTIES



Electrical resistivity as a function of temperature for p-type polycrystalline bismuth telluride, irradiated at about 33°K by both thermal and fast (> 1 meV) neutrons. Total flux  $1.5 \times 10^{20}$  thermal neutrons/cm<sup>2</sup> and  $1.6 \times 10^{19}$  fast (> 1 meV) neutrons/cm<sup>2</sup>.

- unirradiated
- A ○ run 1, cadmium shielded
- △ run 2, cadmium shielded
- p-type, unirradiated
- B ○ p-type, irradiated without cadmium shield
- + , △ p-type, irradiated after annealing

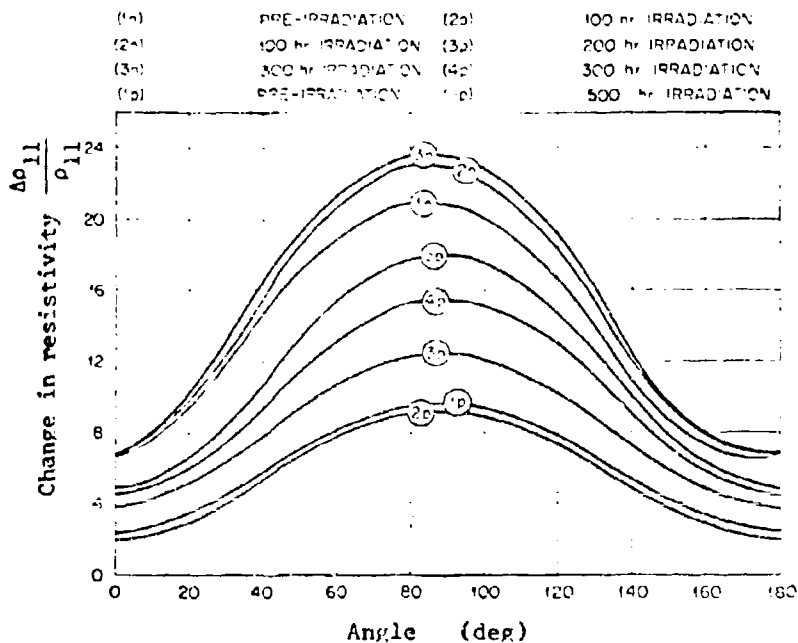
[Ref. 2737]



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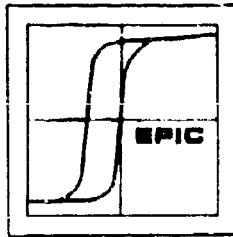
BISMUTH TELLURIDE

IRRADIATION PROPERTIES

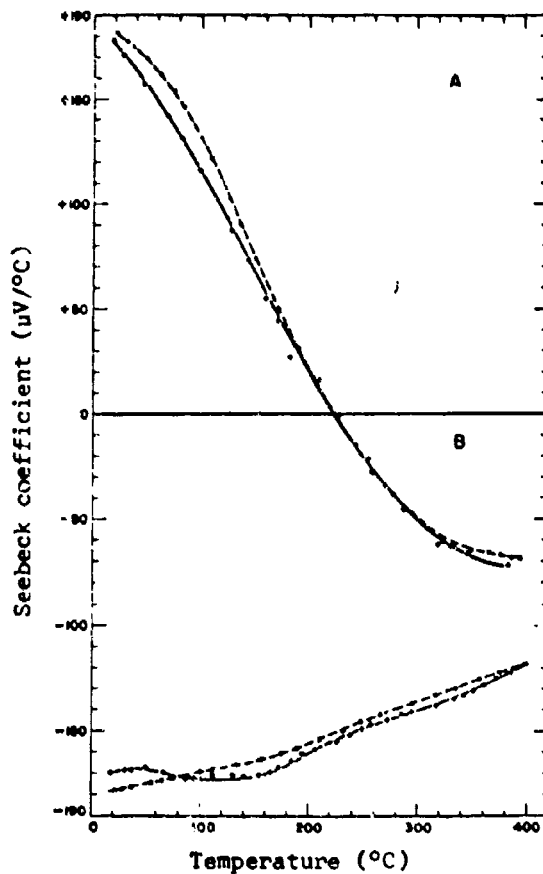


Magnetoresistance as a function of angle between current and magnetic field for single crystal, n-, and p-type  $\text{Bi}_2\text{Te}_3$ . Irradiation was with  $\text{Co}^{60}$ -gamma rays. Initial carrier concentration was  $10^{18}$  to  $10^{19}/\text{cm}^3$

[Ref. 16462]



**BISMUTH TELLURIDE  
IRRADIATION PROPERTIES**

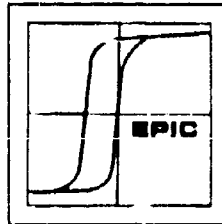


Comparison of Seebeck coefficients as a function of temperature in p-, and n-type, polycrystalline bismuth telluride samples unirradiated and irradiated without the cadmium shield, but subsequently annealed by slow step-wise heating to  $\sim 400^{\circ}\text{C}$ .

- (A) ● p-type unirradiated sample  
+ p-type irradiated unshielded sample after annealing
- (B) ● n-type sample unirradiated  
+ n-type irradiated unshielded sample after annealing

[Ref. 2737]

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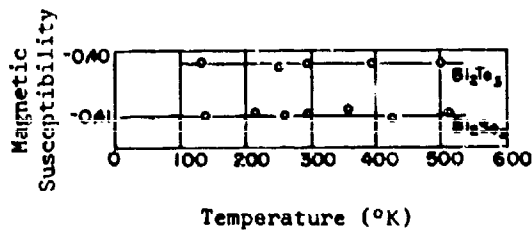
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BISMUTH TELLURIDE and BISMUTH SELENIDE

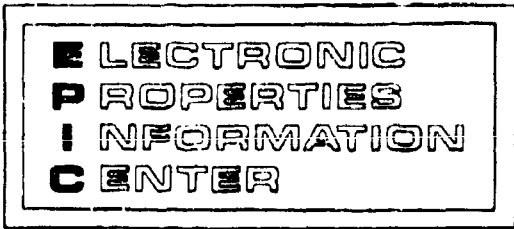
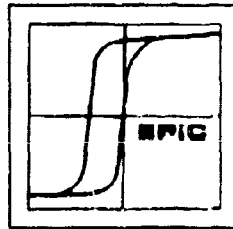
MAGNETIC SUSCEPTIBILITY ( $\chi$ )

Symbol	Value ( $\text{cm}^3/\text{g}$ )	Material	Sample	Temperature	Ref.
$\chi$	$-0.402 \times 10^{-6}$	$\text{Bi}_2\text{Te}_3$	polycrystalline, p-type	130-500°K	5184
	$-0.410 \times 10^{-6}$	"	"	"	5184



Magnetic susceptibility as a function of temperature for polycrystalline, n-type  $\text{Bi}_2\text{Se}_3$  and p-type  $\text{Bi}_2\text{Te}_3$ .

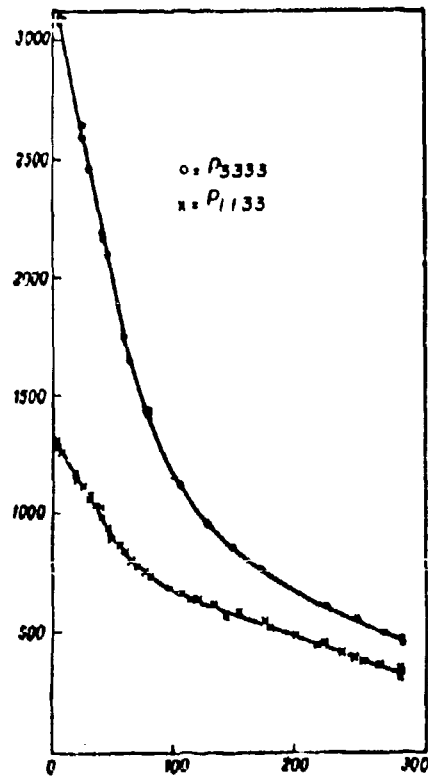
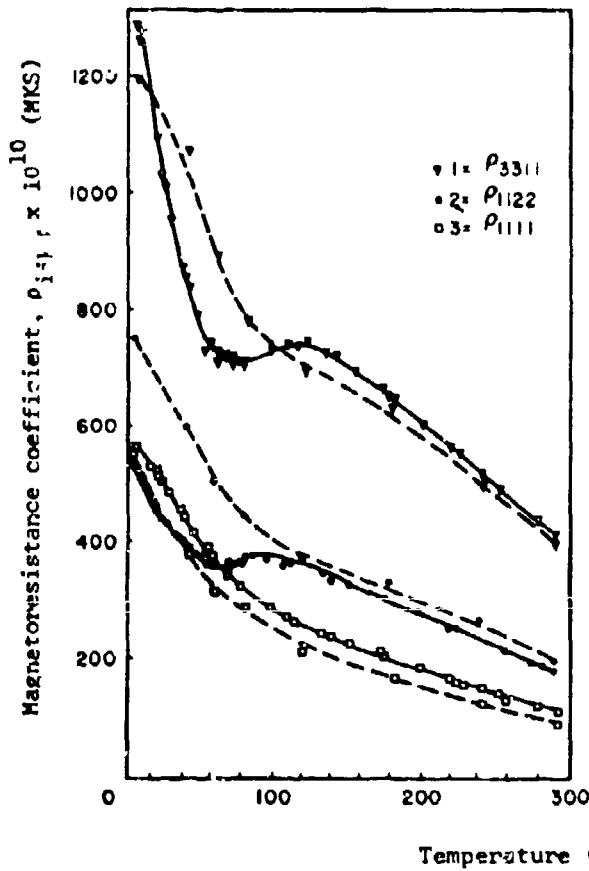
[Ref. 5184]



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BISMUTH TELLURIDE

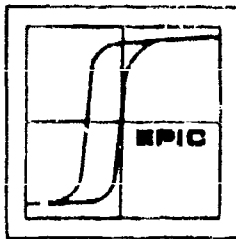
MAGNETOELECTRIC PROPERTIES ( $\Delta\rho/\rho_0$ )



The five strong magnetoresistance coefficients are shown as a function of temperature for single crystal, p-type  $\text{Bi}_2\text{Te}_3$ , parallel to (0001) cleavage plane.

$$n = 8 \times 10^{18} / \text{cc}$$

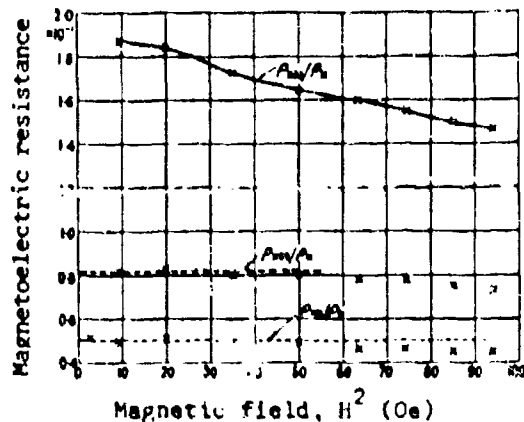
[Ref. 2984]



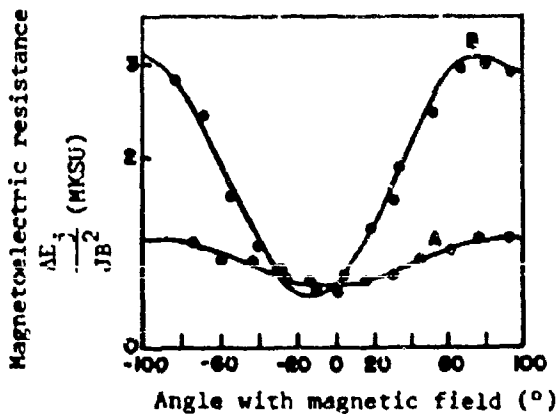
BISMUTH TELLURIDE

MAGNETOELECTRIC PROPERTIES

Magnetolectric resistance coefficients as a function of magnetic field at 77°K for single crystal, n-type  $\text{Bi}_2\text{Te}_3$ , in (0001) cleavage plane.



[Ref. 2360]



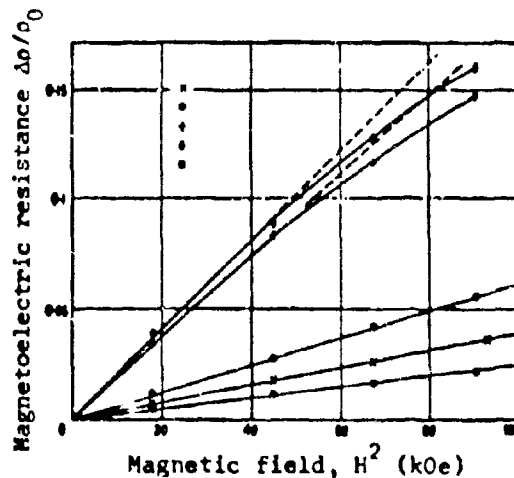
— Magnetolectric resistance as a function of angle at 77°K for single crystal, n-type, highly I-doped  $\text{Bi}_2\text{Te}_3$ .

- (A) ● field normal to (0001)
- (B) ○ field is parallel to (0001)

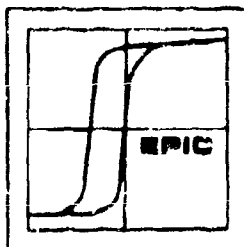
[Ref. 19045]

Magnetolectric resistance as a function of field at 77°K for single crystal, n-, and p-type  $\text{Bi}_2\text{Te}_3$ , cut parallel to (0001) cleavage plane. Slightly iodine-doped samples deviate from linearity.

- x } p-type, undoped
  - } p-type, undoped
  - + } n-type, iodine-doped
  - ◆ } n-type, iodine-doped
  - } n-type, iodine-doped
- ↓ increasing I content

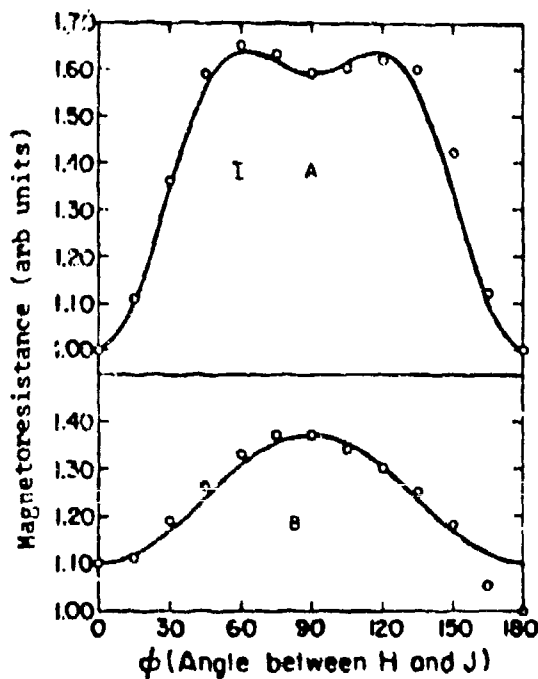
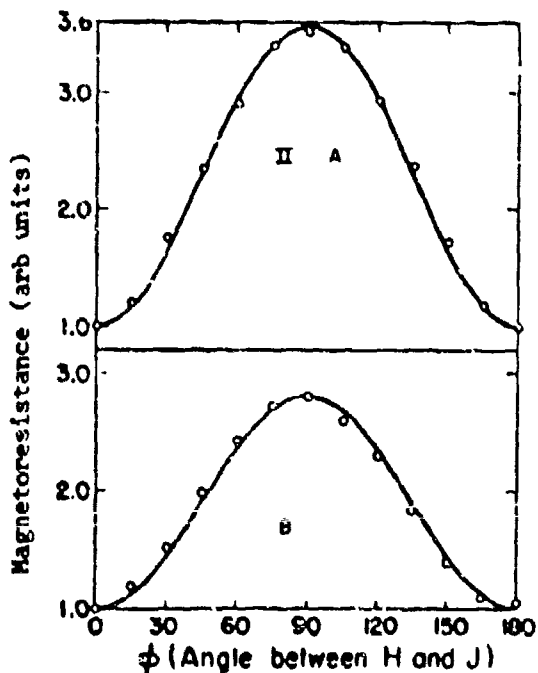


[Ref. 3215]



BISMUTH TELLURIDE

MAGNETOELECTRIC PROPERTIES



Magnetoresistance as a function of angle between current and field at 77°K. The two samples (A and B) of  $\text{Bi}_2\text{Te}_3$  are single crystal, n-type, cut on (0001) cleavage plane,  $n = 3 \times 10^{18}/\text{cc}$ .

For sample A, field is 6000 G; for sample B, it is 975 G.

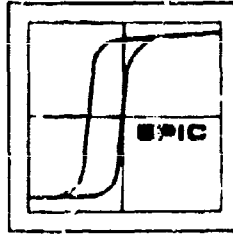
I Field is parallel (0001)

II Field is normal (0001)

[Ref. 17748]



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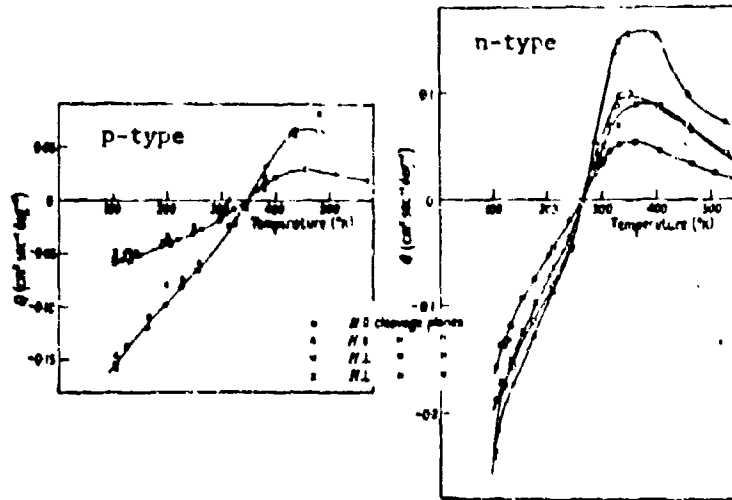


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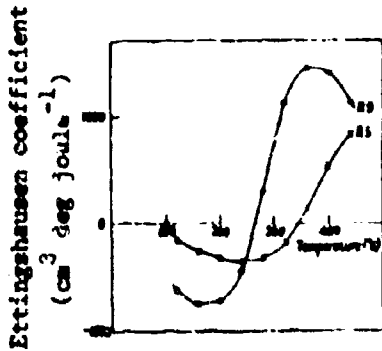
BISMUTH TELLURIDE

MAGNETOELECTRIC PROPERTIES



Nernst coefficient as a function of temperature for single crystal, n-, and p-type  $\text{Bi}_2\text{Te}_3$  for fields parallel and normal to cleavage plane, (0001).

- Δ x,  $Q_{\parallel}$  is the isothermal coefficient
- o,  $Q_{\perp}$  is the quasi-adiabatic coefficient

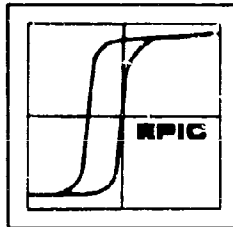


Ettingshausen coefficient as a function of temperature in single crystal, n- or p-type  $\text{Bi}_2\text{Te}_3$ . Magnetic field is normal to (0001) cleavage plane.

- $R_5$  is p-type
- $R_9$  is n-type

[Ref. 3360]

[Ref. 3360]

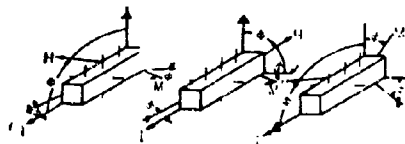


BISMUTH SELENIDE

MAGNETOELECTRIC PROPERTIES

Units

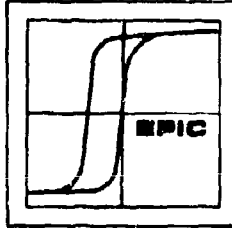
Sample	A	B		
Temp. (°K)	4.2	90		
	Obs.	Obs.	Calc.	
$\sigma_{11}$ $\sigma_{33}$	+ 3.5 + 0.59	$2.10 \times 10^8$ (ohm <sup>-1</sup> )(cm) <sup>-1</sup>		$\sigma$ in (ohm-cm) <sup>-1</sup>
$\sigma_{12}$ $\sigma_{22}$	- 0.40 - 2.50	$0.26 \times 10^8$ (ohm) <sup>-1</sup> (cm)(coul) <sup>-1</sup>		$R_H \sigma^2$ (cm/ohm <sup>2</sup> coul)
$\sigma_{111}$ $\sigma_{112}$ $\sigma_{122}$ $\sigma_{211}$ $\sigma_{222}$	- 0.7 - 4.8 - 24.4 - 0.1 - 0.8 - 1.4 - 0.53 + 1.6	$0.12 \times 10^8$ (ohm) <sup>-1</sup> (cm)(coul) <sup>-2</sup>		$R_H^2 \sigma^3$ (cm <sup>3</sup> /ohm <sup>3</sup> coul <sup>2</sup> )
$e_{11}/\sigma_{11}$	+ 5.9	4.7	5.36	
$e_{12}/\sigma_{12}$	+ 5.2	4.9	5.36	
$\sigma_{1111}/\sigma_{1122}$ $\sigma_{1122}/\sigma_{1122}$ $\sigma_{1122}/\sigma_{1122}$ $\sigma_{2211}/\sigma_{1122}$ $\sigma_{2222}/\sigma_{1122}$ $\sigma_{2211}/\sigma_{1122}$ $\sigma_{2222}/\sigma_{1122}$	+ 0.029 + 0.70 + 0.004 + 0.003 + 0.058 + 0.022 - 0.065	0.012 0.17 0.020 0.047 0.06 0.012 0.17	0.045 0.202 0.0486 0.0344 0.0590 0.0091 0.0930	



Experimental arrangements. *H* the magnetic field, *I* the electric current,  $\Delta$  the three-fold axis,  $\odot$  the two-fold axis, *M* the axis along the mirror plane and  $\theta$  the rotatory angle of magnetic field.

Experimental and calculated magneto-electric coefficients of single crystal, n-type Bi<sub>2</sub>Se<sub>3</sub> at 4.2°K. Sample B data from [3350]. Calculated data is derived from an ellipsoidal six valley model for conduction band minima.

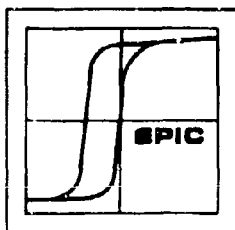
[Ref. 12046]



**BISMUTH TELLURIDE**

**MOBILITY ( $\mu$ )**

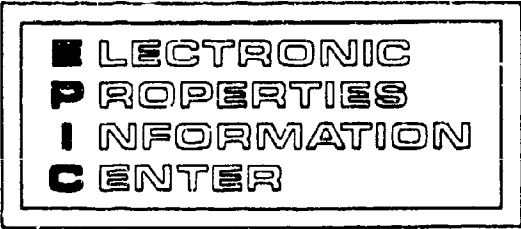
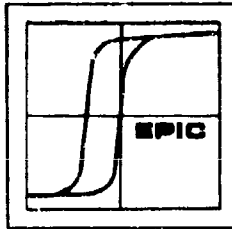
Symbol	Value ( $\text{cm}^2/\text{V sec}$ )	Temp. coeff.	Sample (single crystal)	Temperature	Ref.
$\mu_n$	4600		n-type, I-doped, $n = 2.07 \times 10^{19}/\text{cc}$ $\rho_{77\text{K}} = 6.57 \times 10^{-5} \text{ ohm-cm}$	77°K	4487
$\mu_n$	200-1000	$T^{-2.3}$	p-type, $n = 1.4 \times 10^{19}/\text{cc}$	300-140°K	407
$\mu_n$	1250	$1.67 \times 10^7 T^{-1.68}$	n-type	286°K	2360
$\mu_n$	330			150-300°K	2360
$\mu_p$				300°K	
$\mu_n$	800		p-type, $n = 10^{19}/\text{cc}$ , $\rho = 1.6 \times 10^{-3} \text{ ohm-cm}$	300°K	2866
$\mu_p$	400		"	"	2866
$\mu_n$	540		n-type, excess Te & I $n_n = 5 \times 10^{18}/\text{cc}$	300°K	2624
$\mu_p$	400		p-type, excess Bi & Pb $n_p = 8 \times 10^{18}/\text{cc}$	300°K	2624
$\mu_n$	310	$n, \text{ cm}^{-3}$ $3 \times 10^{17}$	n-type	300°K	801
$\mu_p$	440				
$\mu_n$	240	$9 \times 10^{17}$			
$\mu_p$	330				
$\mu_p$	410	$2 \times 10^{19}$	p-type		
$\mu_p$	430	$3 \times 10^{18}$			
$\mu_p$	680	$4 \times 10^{18}$			801



BISMUTH TELLURIDE

MOBILITY

Symbol	Value (cm <sup>2</sup> /V sec)	Temp. coeff.	Sample	Temperature	Ref.
$\mu_n$	400		single or polycrystalline, n-type, parallel (0001)	300°K	631
	10		normal (0001)	300°K	
$\mu_n$		$T^{-3}$	parallel (0001)	273-560°K	631
$\mu_n$	350		macrocrystalline, p-type (undoped)	300°K	3867
$\mu_p$	265			↓	
$\mu_p$	350		AgI-doped, $n = 2-18 \times 10^{19}/cc$		
$\mu_p$	149-18*		Sn-doped, $n = 3-33 \times 10^{19}/cc$		3867
* Hole mobility decreases with increase in Sn-doping					
$\mu_p$	280		single crystal, p-type, $\rho = .055$ ohm-cm	300°K	10535
$\mu_p$		$T^{-1.3}$ to $-1.6$	$n = 5 \times 10^{17}/cc$	4-250°K	10535
$\mu_p$	515		single crystal, p-type	290°K	3207
$\mu_p$		$T^{-1.98}$	" "	77-290°K	3207
$\mu_p$	$1.2 \times 10^8$	$T^{-2.3}$	single crystal, p-type $n = 1.4 \times 10^{19}/cc$	140-300°K	407
			single or polycrystalline (0001)	150-300°K	2595
$\mu_n$		$\sim T^{-1.72}$	n-type		
$\mu_p$		$\sim T^{-1.94}$	p-type		2595



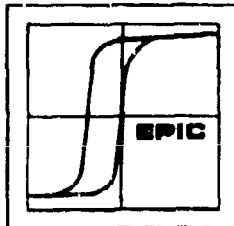
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**BISMUTH TELLURIDE**

**MOBILITY**

Symbol	Value cm <sup>2</sup> /V sec	Temp. coeff.	Sample	Temperature	Ref.
$\mu_n$		$\sim T^{-1.78}$	polycrystalline, CuBr doping yields n-type, $n = 2-20 \times 10^{19}/cc$	80-600°K	14525
$\mu_p$		$\sim T^{-2.12}$	Pb-doped yields p-type, $n = 2-10 \times 10^{19}/cc$	"	14525
$\mu$	$1.8 \times 10^5$ (max)		single crystal, Te-doped, $n = 9 \times 10^{17}/cc$	4.2°K	14854
$\mu_n$		$T^{-2.8}$	$n = 2.4 \times 10^{17}$	4.2-250°K ↑ ↓	14854 ↓
		$T^{-2.7}$	$5.3 \times 10^{17}$		
		$T^{-2.2}$	$3.0 \times 10^{18}$		
		$T^{-2.4}$	$3.4 \times 10^{18}$		
		$T^{-1.70}$	$1.2 \times 10^{19}$		
		$T^{-1.31}$	$6.8 \times 10^{19}$		

$\mu_n$  is electron mobility  
 $\mu_p$  is hole mobility



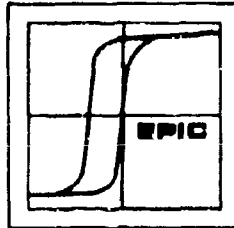
**BISMUTH SELENIDE**

**MOBILITY**

Symbol	Value cm <sup>2</sup> /V sec	Temp. coeff.	Sample	Temperature	Ref.
$\mu_n$	700		macrocrystalline, n-type, $n \sim 10^{19}/\text{cc}$	300°K	2538
$\mu_n$	600		single crystal, n-type, $\rho = 5 \times 10^{-4}$ ohm-cm, $n = 2 \times 10^{19}/\text{cc}$	300°K	2866
$\mu$	300-500		single crystal, n-type, parallel (0001), $n = 2-4 \times 10^{19}/\text{cc}$ , $\rho = .001$ ohm-cm	300°K	630
$\mu$	10-20		normal (0001), $n = 2-4 \times 10^{19}/\text{cc}$ $\rho = .02$ ohm-cm	300°K	630
		$T^{-.5}$	parallel (0001)	130-300°K	630
		$T^{-1.5}$	"	300-500°K	
		$T^{-3}$	"	> 500°K	630
$\mu$	442		macrocrystalline, n-type, AgI-doped	300°K	3867

**BISMUTH TELLURIDE-BISMUTH SELENIDE**

$\mu$	22.		75% Bi <sub>2</sub> Te <sub>3</sub> -25% Bi <sub>2</sub> Se <sub>3</sub> AgI-doped film annealed, $n = 1.5 \times 10^{19}/\text{cc}$ $\rho \sim 10^{-4}$ ohm-cm	300°K	21023
	0.5		film not annealed, $n = 2.9 \times 10^{20}$ $\rho \sim .01$ to $.3$ ohm-cm		
	150		bulk, $n = 10^{19}/\text{cc}$ , $\rho = .005$ ohm-cm	300°K	21023

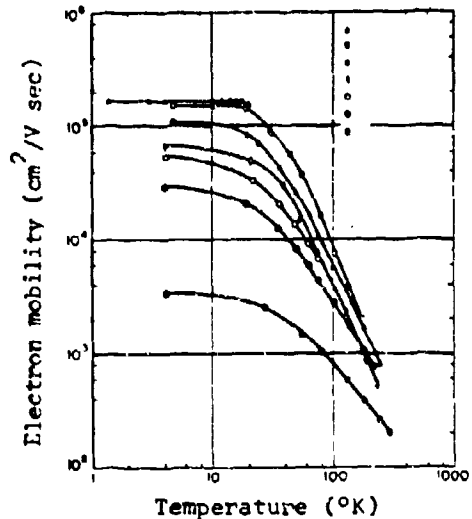


BISMUTH TELLURIDE

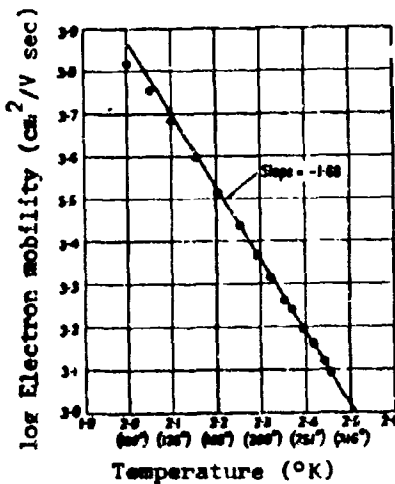
MOBILITY

Electron Hall mobility as a function of temperature in tellurium-doped, single crystal, n-type bismuth telluride. Samples designated by solid symbols are more homogeneous.

	$n, \text{cm}^{-3}$
$\Delta$	$2/4 \times 10^{17}$
$\square$	$5.3 \times 10^{17}$
$\blacktriangle$	$3.0 \times 10^{18}$
$\diamond$	$3.4 \times 10^{18}$
$\circ$	-
$\bullet$	$1.2 \times 10^{19}$
$\blacksquare$	$6.8 \times 10^{19}$



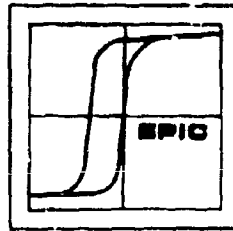
[Ref. 14854]



Electron mobility as a function of temperature in single crystal, n-type  $\text{Bi}_2\text{Te}_3$ , cut parallel to (0001) cleavage plane.  $n_{77\text{K}} = 4.8 \times 10^{18}/\text{cc}$ .

$$\mu_n = 1.67 \times 10^7 T^{-1.68} \text{ (from 150-300°K)}$$

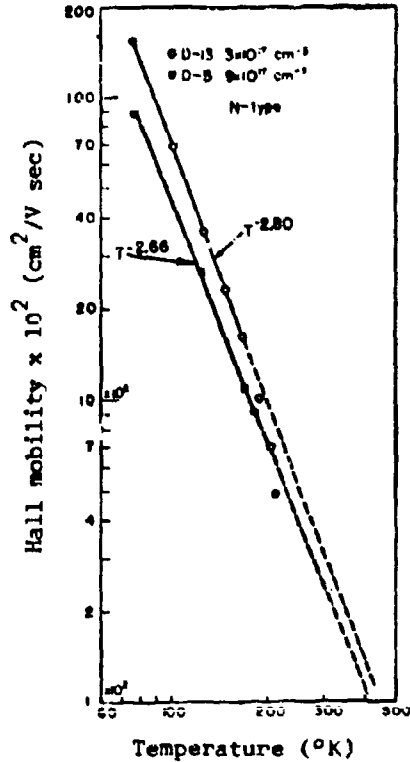
[Ref. 2360]



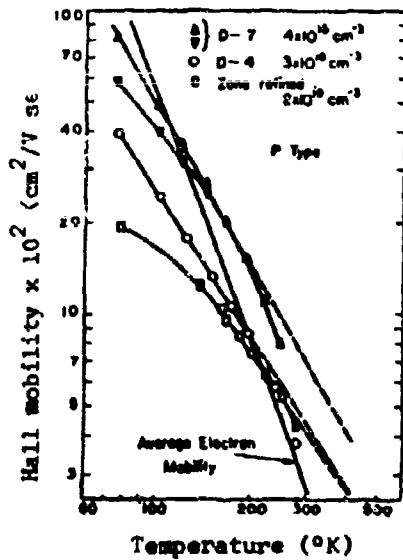
BISMUTH TELLURIDE

MOBILITY

Hall mobility as a function of temperature in n-type, single crystal bismuth telluride. The Hall coefficient was measured with the current parallel to cleavage plane and magnetic field perpendicular to cleavage plane. The resistivity was measured parallel to the cleavage plane.



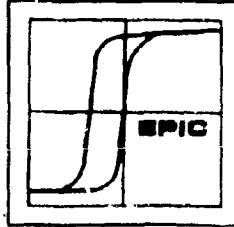
[Ref. 801]



Hall mobility as a function of temperature for p-type, single crystal bismuth telluride. The Hall coefficient was measured with the current parallel to the cleavage plane and the magnetic field perpendicular to the cleavage plane. The resistivity was measured parallel to the cleavage plane (0001). D-7 was very inhomogeneous.

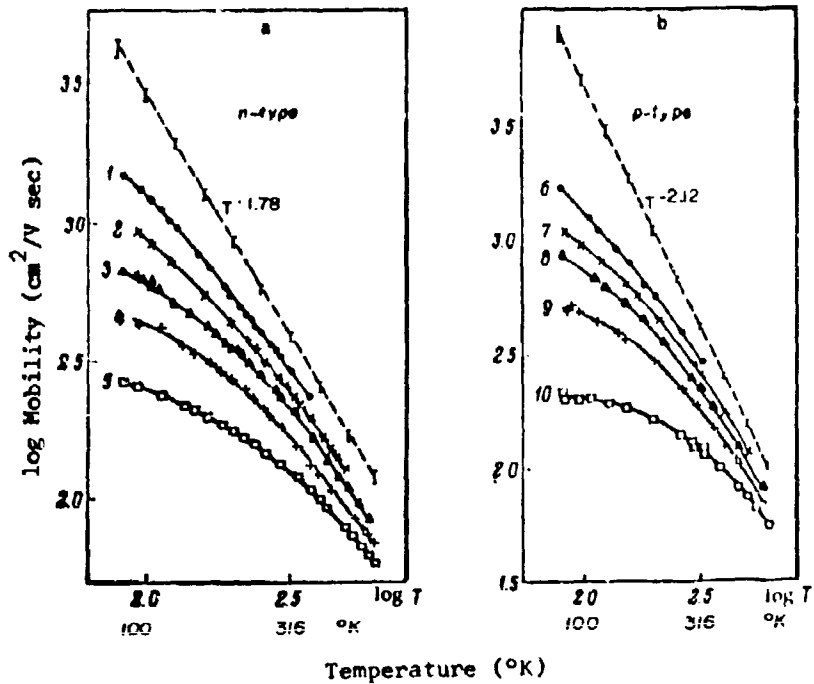
[Ref. 801]





BISMUTH SELENIDE

MOBILITY



Mobility as a function of log temperature in polycrystalline  $\text{Bi}_2\text{Te}_3$ . n-Type is CuBr-doped, p-type is Pb-doped.

———— experimental  
----- calculated to include impurity scattering

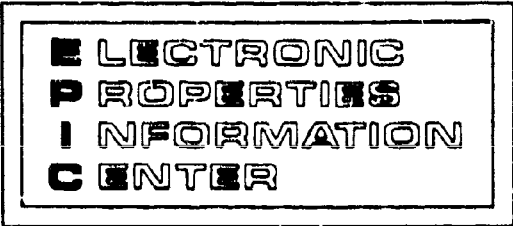
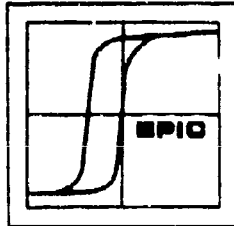
n-type,  $n, \text{cm}^{-3}$

- 1)  $2.5 \times 10^{19}$
- 2)  $5.2 \times 10^{19}$
- 3)  $7.8 \times 10^{19}$
- 4)  $12.3 \times 10^{19}$
- 5)  $20.4 \times 10^{19}$

p-type,  $n, \text{cm}^{-3}$

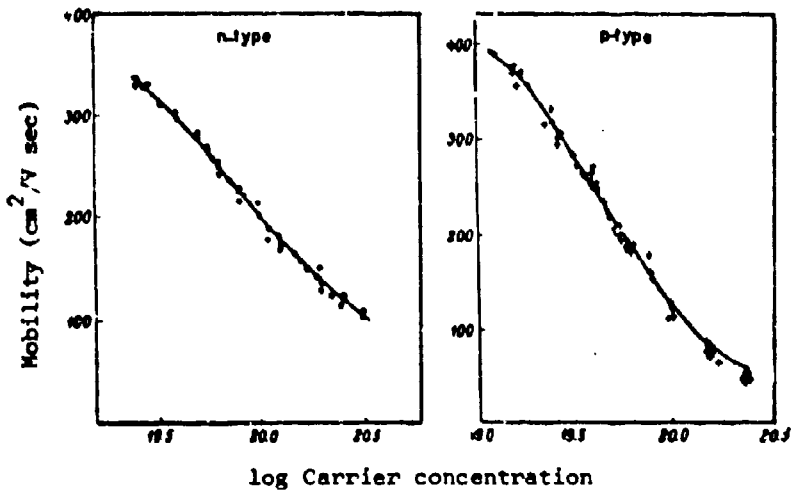
- 6)  $7.2 \times 10^{19}$
- 7)  $3.4 \times 10^{19}$
- 8)  $4.4 \times 10^{19}$
- 9)  $6.0 \times 10^{19}$
- 10)  $10.0 \times 10^{19}$

[Ref. 14525]



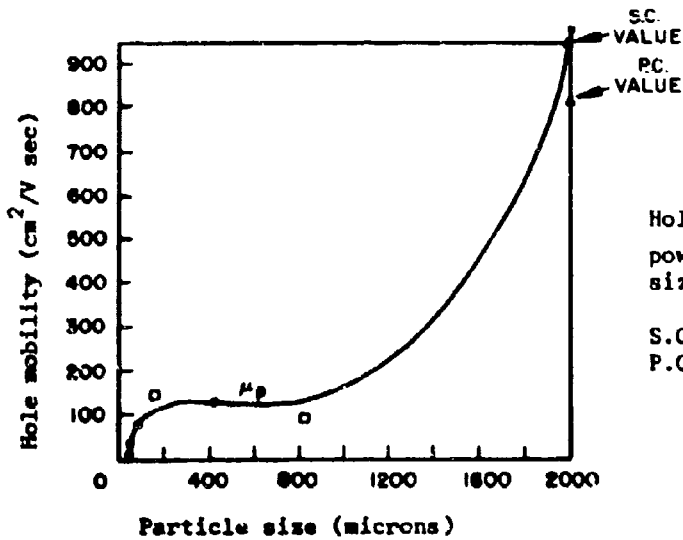
**BISMUTH TELLURIDE**

**MOBILITY**



Mobility as a function of carrier concentration at 300°K for polycrystalline  $\text{Bi}_2\text{Te}_3$ ,  $n > 10^{19}/\text{cc}$ . Calculated curve includes impurity scattering; measured values of mobility are points on curve.

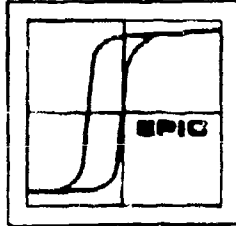
[Ref. 14525]



Hole mobility of pressed  $\text{Bi}_2\text{Te}_3$  powders as a function of particle size at 77°K.

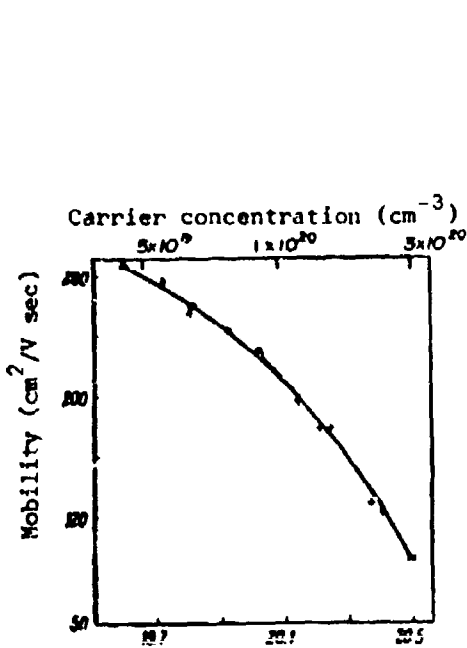
S.C. is single crystal value  
 P.C. is polycrystalline value.

[Ref. 8758]

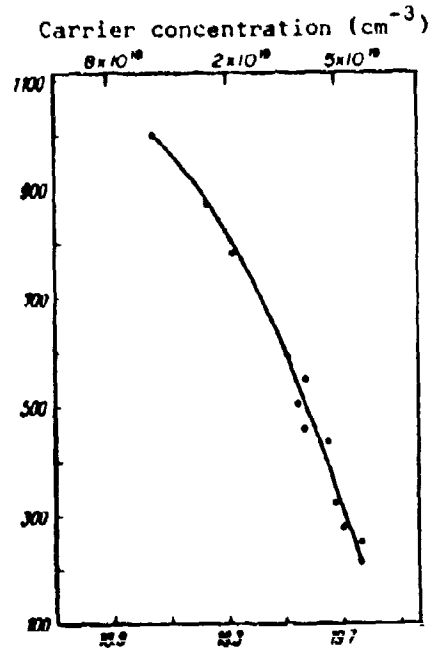


BISMUTH TELLURIDE and BISMUTH SELENIDE

MOBILITY



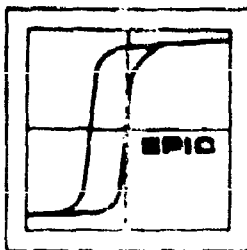
log Carrier concentration ( $\text{cm}^{-3}$ )  
 Bismuth Telluride



log Carrier concentration ( $\text{cm}^{-3}$ )  
 Bismuth Selenide

Mobility as a function of carrier concentration in polycrystalline, hot-pressed bismuth telluride and bismuth selenide, both n-type, at 300°K.

[Ref. 14675]



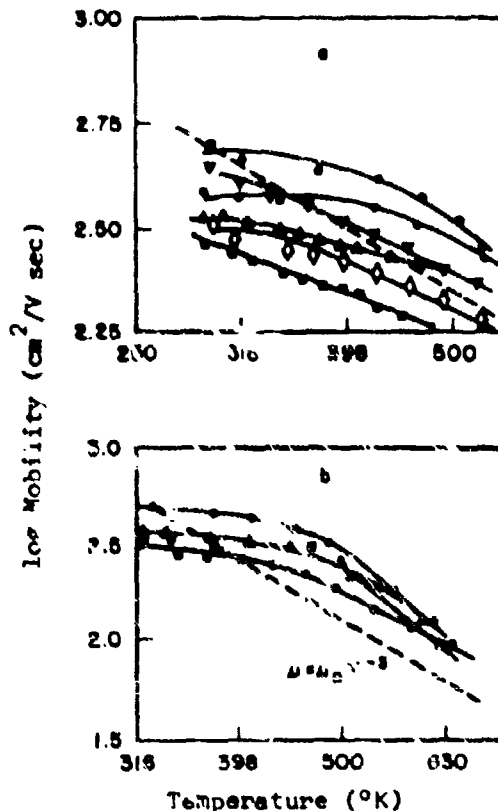
BISMUTH SELENIDE

MOBILITY

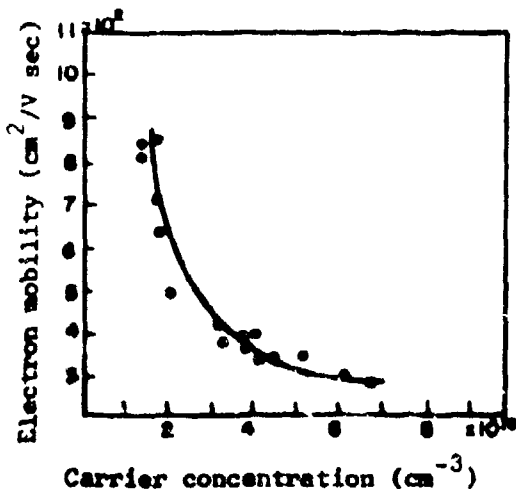
Electron mobility as a function of temperature in single crystal, n-type  $\text{Bi}_2\text{Se}_3$ , measured parallel (0001) cleavage plane. Individual sample specifications are not given, only a range of all samples at 300°K.

$$n = 2-4 \times 10^{19} / \text{cc.}$$

- a) Electrical conductivity at 300°K ranges from 2000-3000  $(\text{ohm-cm})^{-1}$ .
- This sample has conductivity of 1000  $(\text{ohm-cm})^{-1}$ .
- b) Electrical conductivity at 300°K is  $\sim 2000 \text{ ohm-cm}$ .
- $\mu = \mu_0 T^{-3}$ .



[Ref. 630]

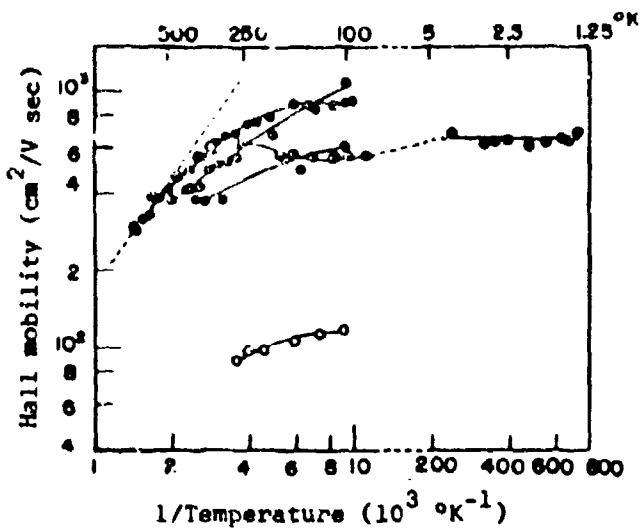


Electron mobility as a function of carrier concentration in single crystal, n-type  $\text{Bi}_2\text{Se}_3$  at 300°K.

[Ref. 630]

BISMUTH SELENIDE

MOBILITY

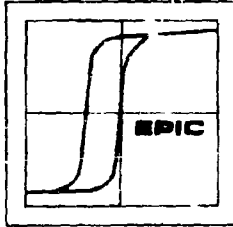


Hall mobility as a function of reciprocal temperature for single crystal, n-type  $\text{Bi}_2\text{Se}_3$ .

Sample No.	$\rho$ (ohm-cm)	$n, \text{cm}^{-3}$
● 5	$5.66 \times 10^{-3}$	$2.44 \times 10^{18}$
● 6-13 normal	5.98	2.5
○ 6-13 parallel	25.5	3.3
● 6-14	13.55	0.598
● 6-14-1	14.2	0.74

$$\text{---} \mu = \mu_0 T^{-1.5}$$

[Ref. 3097]

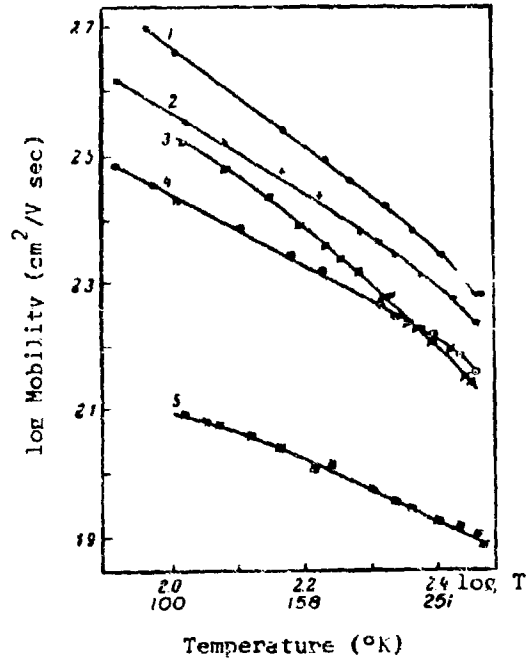


BISMUTH TELLURIDE-BISMUTH SELENIDE

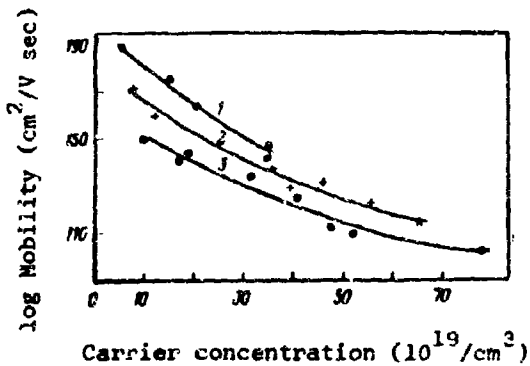
MOBILITY

Mobility as a function of temperature for hot-pressed polycrystalline, n-type  $\text{Bi}_2\text{Te}_3$  (80%) -  $\text{Bi}_2\text{Se}_3$  (20%). The solid solution is highly homogeneous. Samples are copper and lead doped.

	$n, \text{cm}^{-3}$
1)	$4.6 \times 10^{19}$
2)	$5.0 \times 10^{19}$
3)	$8.0 \times 10^{19}$
4)	$3.6 \times 10^{20}$
5)	$5.5 \times 10^{20}$



[Ref. 14675]

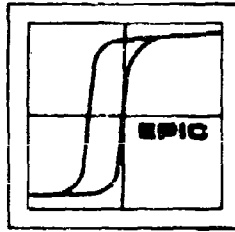


Mobility as a function of carrier concentration for hot-pressed polycrystalline, n-type, 80%  $\text{Bi}_2\text{Te}_3$  + 20%  $\text{Bi}_2\text{Se}_3$ , with Cu and Pb doping.

	$n, \text{cm}^{-3}$
1)	$5 \times 10^{19}$
2)	$8 \times 10^{19}$
3)	$1.1 \times 10^{20}$

[Ref. 14675]

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 AIR FORCE SYSTEMS COMMAND

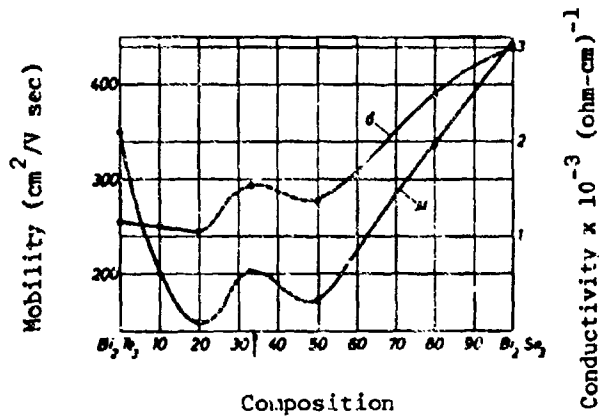


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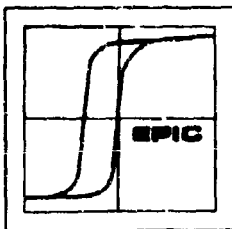
**BISMUTH TELLURIDE-BISMUTH SELENIDE**

**MOBILITY**



Mobility as a function of composition in polycrystalline  $\text{Bi}_2\text{Te}_3\text{-Bi}_2\text{Se}_3$ , silver iodide-doped. Carrier concentration for the  $\text{Bi}_2\text{Te}_3 = 2 \times 10^{19}/\text{cc}$ , increases to 4, then  $5 \times 10^{19}$  for the 5 compounds, and returns to  $4.7 \times 10^{19}$  for the  $\text{Bi}_2\text{Se}_3$ .

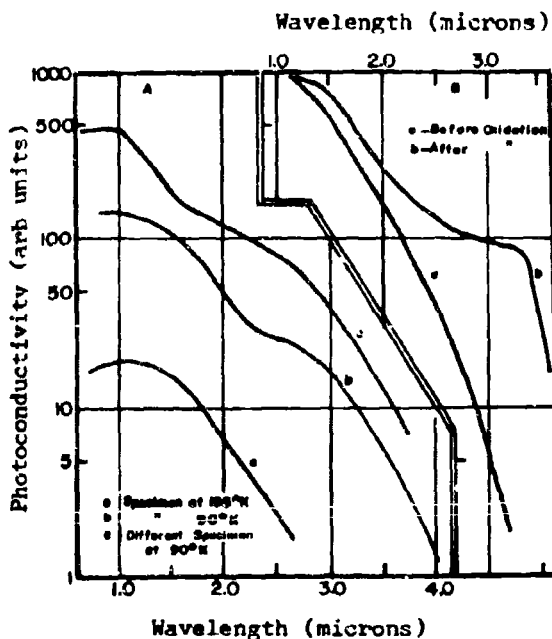
[Ref. 3867]



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BISMUTH TELLURIDE

PHOTOELECTRONIC PROPERTIES



Photoconductivity as a function of wavelength in  $\text{Bi}_2\text{Te}_3$ , p-type films.

$\rho = 1 \text{ ohm-cm}$

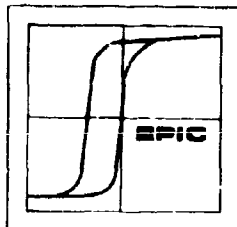
A) shows data taken at two temperatures

B) shows data taken before and after oxidation

Oxygen impurity centers introduce a photoconductive absorption band at about 0.44 eV, (2.8 $\mu$ ).

[Ref. 21299]





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BISMUTH TELLURIDE and BISMUTH SELENIDE

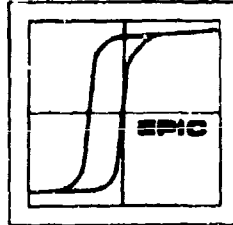
PIEZOELECTRIC PROPERTIES ( $\pi$ )

Symbol	Value ( $\text{cm}^2/\text{Vne}$ )	$\text{Bi}_2\text{Te}_3$	Sample (single crystal)	Temperature	Ref.
$\pi_{11}$	$+ 87 \times 10^{-12}$		p-type, $n = 5 \times 10^{19}/\text{cc}$ $p = 10^{13}/\text{cc}$	300°K	16428
$\pi_{33} + \pi_{31}$	$-40 \times 10^{-12}$		"	"	16428
$\pi_{33}$	$+ 118 \times 10^{-12}$ $+ 115$ $+ 90$		n-type ↓	300°K	5842
$\pi_{11}$	$-2$ to $-5 \times 10^{-12}$	$\text{Bi}_2\text{Se}_3$	n-type, $\sigma = 3300 (\text{ohm-cm})^{-1}$	78-300°K	5842

$\pi_{11}$  is measured parallel to (0001)

$\pi_{33}$  and  $\pi_{31}$  are measured normal to (0001)

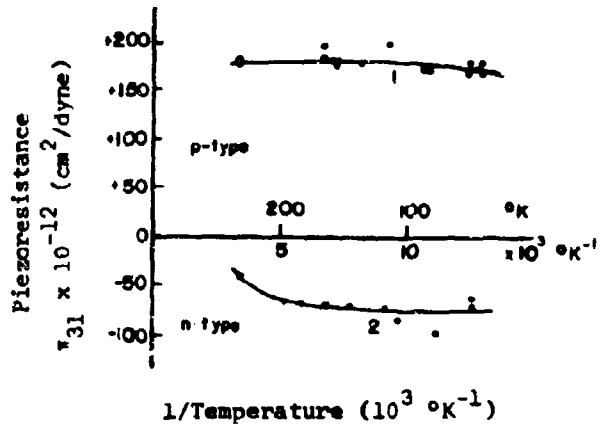
See page 38 for additional information on piezocoefficient of resistivity.



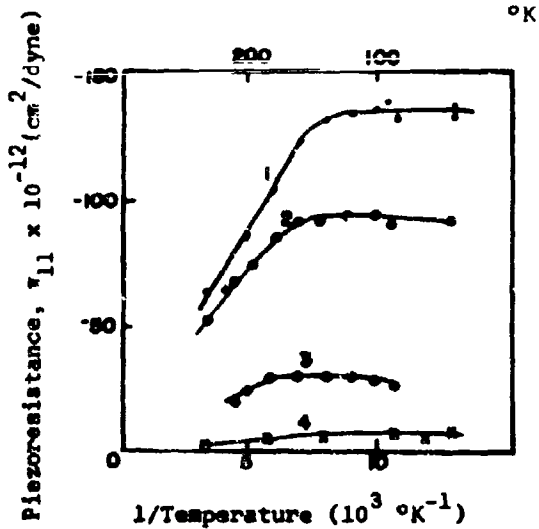
BISMUTH TELLURIDE and BISMUTH SELENIDE

PIEZOELECTRIC PROPERTIES

Temperature dependence of the piezoelectric constant  $\pi_{31}$  in single crystal, p-, and n-type  $\text{Bi}_2\text{Te}_3$ . Data is taken normal to (0001).



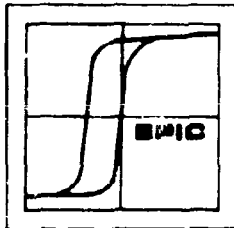
[Ref. 5842]



Temperature dependence of the piezoresistance coefficient  $\pi_{11}$  of single crystal, n-type  $\text{Bi}_2\text{Te}_3$ . The initial conductivity is given in  $(\text{ohm-cm})^{-1}$ . All measurements are parallel to (0001).

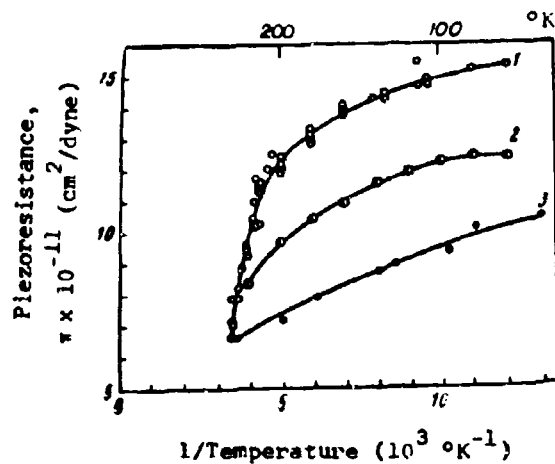
- 1) 340  $(\text{ohm-cm})^{-1}$
- 2) 720 "
- 3) 3500 "
- 4) is n-type, single crystal  $\text{Bi}_2\text{Se}_3$ ,  
 $\sigma = 3300 (\text{ohm-cm})^{-1}$

[Ref. 5842]



BISMUTH TELLURIDE

PIEZOELECTRIC PROPERTIES

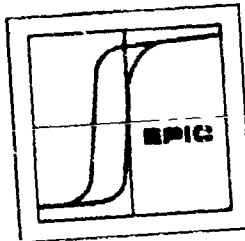


The piezoresistance coefficient  $\pi_{11}$ , in the glide plane, as a function of reciprocal temperature for three, single crystal, p-type  $\text{Bi}_2\text{Te}_3$  samples.

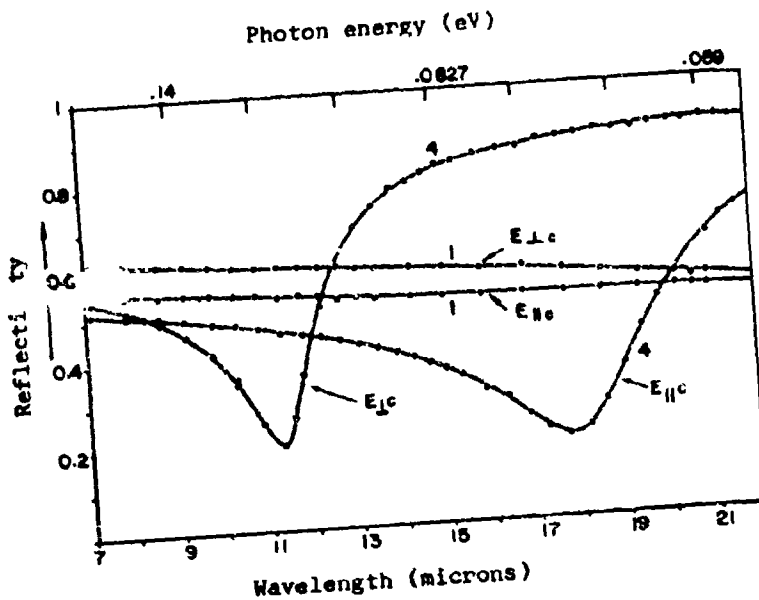
- 1)  $\sigma = 170 (\text{ohm-cm})^{-1}$
- 2) " 480 "
- 3) " 990 "

$$\pi = \frac{\Delta \rho}{\rho} \times \frac{1}{\chi}, \quad \rho = \text{resistivity in (001)}, \quad \chi = \text{mechanical stress}$$

[Ref. 3004]

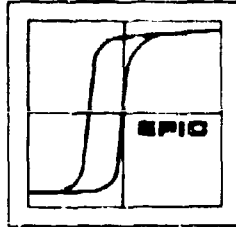


BISMUTH TELLURIDE  
REFLECTION COEFFICIENT (R)



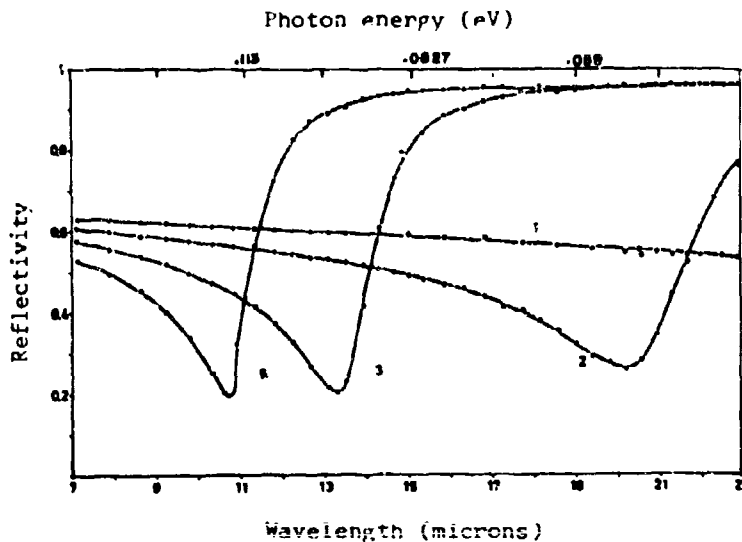
Reflectivity as a function of wavelength for single crystal, n-type  $\text{Bi}_2\text{Te}_3$  at 78°K. Polarized light normal and parallel to (0001) cleavage plane is indicated. Sample 1 is lightly doped,  $n = 9.5 \times 10^{18}/\text{cc}$ ; sample 4 is heavily doped,  $n = 10^{20}/\text{cc}$ .

[Ref. 18221]



BISMUTH TELLURIDE

REFLECTION COEFFICIENT



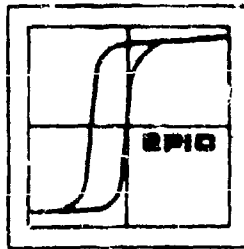
Reflectivity as a function of wavelength for variously doped single crystal, n-type  $\text{Bi}_2\text{Te}_3$ , at  $78^\circ\text{K}$  and parallel (0001) plane.

n at  $293^\circ\text{K}$

- 1)  $9.5 \times 10^{18}/\text{cc}$
- 2)  $2.8 \times 10^{19}$
- 3)  $6.8 \times 10^{19}$
- 5)  $1.4 \times 10^{20}$

Increase in carrier concentration displaces reflectivity minima towards shorter wavelength.

[Ref. 10221]



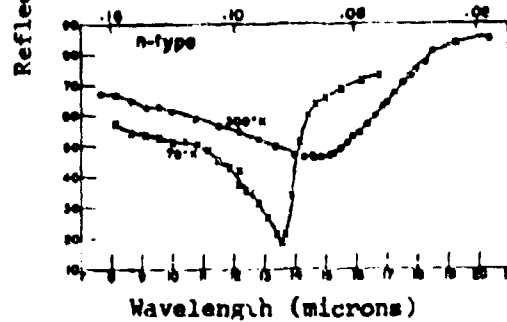
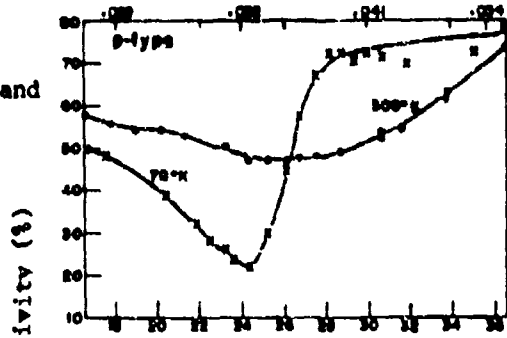
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BISMUTH TELLURIDE

REFLECTION COEFFICIENT

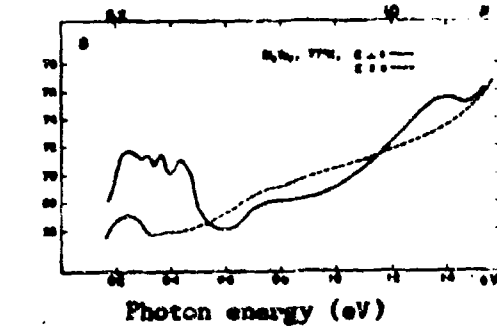
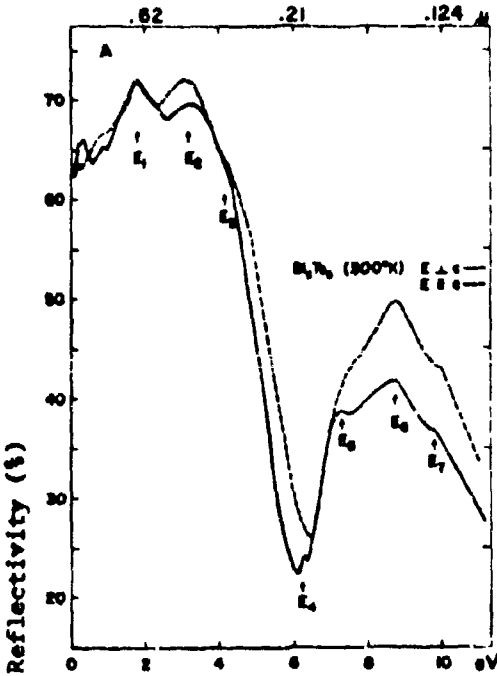
Reflectivity as a function of wavelength for n-, and p-type single crystal  $\text{Bi}_2\text{Te}_3$  at 78°K and 300°K.

Photon energy (eV)



[Ref. 21115]

Wavelength (microns)

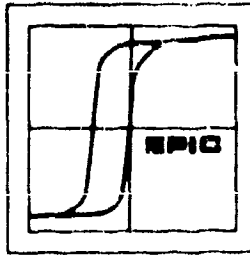


Reflectivity as a function of photon energy for single crystal, p-type  $\text{Bi}_2\text{Te}_3$

— radiation normal to (0001) cleavage plane  
--- radiation parallel to (0001) cleavage plane

- A)  $\lambda = .113$  to  $12.4\mu$ , 300°K
- B)  $\lambda = .827$  to  $6.89\mu$ , 77°K

[Ref. 22468]

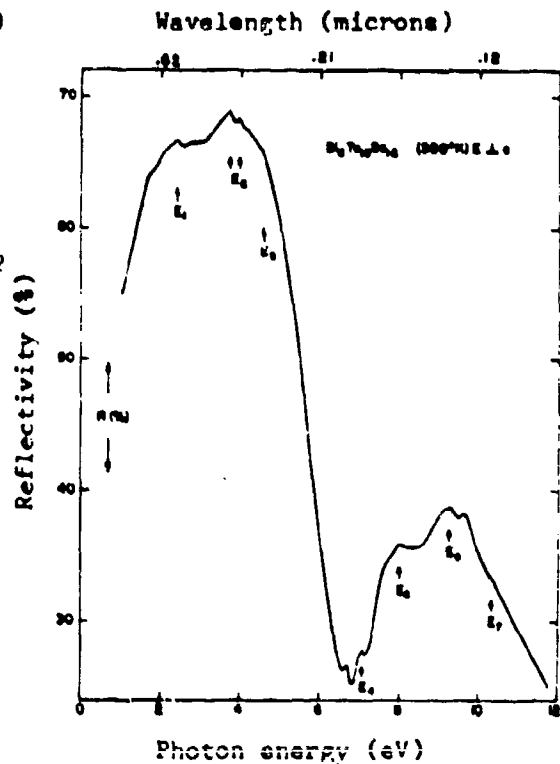


BISMUTH TELLURIDE-BISMUTH SELENIDE ( $\text{Bi}_2\text{Te}_{3-x}\text{Se}_x$ )

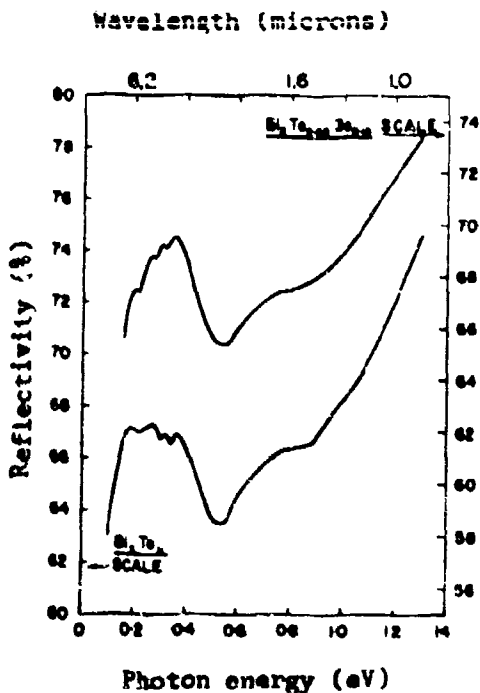
REFLECTION COEFFICIENT

Reflection coefficient as a function of photon energy for polycrystalline  $\text{Bi}_2\text{Te}_{1.8}\text{Se}_{1.2}$  at 300°K. Radiation normal to (0001) cleavage plane, ( $E_{1c}$ ).

(see table on next page for peak energies)

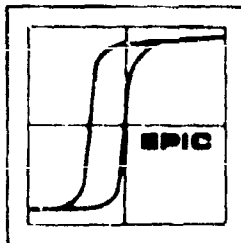


[Ref. 22468]



Reflection coefficient as a function of photon energy for single crystal, p-type  $\text{Bi}_2\text{Te}_3$  and polycrystalline, p-type  $\text{Bi}_2\text{Te}_{2.85}\text{Se}_{0.15}$  at 300°K. Radiation normal to (0001) cleavage plane ( $E_{1c}$ ).

[Ref. 22468]

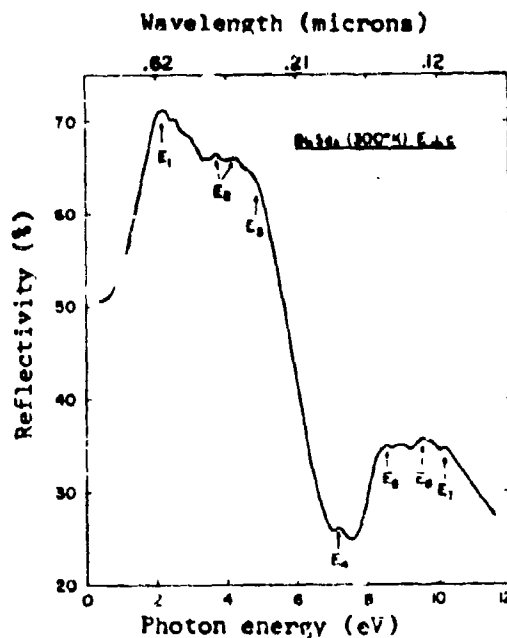


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BISMUTH TELLURIDE-BISMUTH SELENIDE ( $\text{Bi}_2\text{Te}_{3-x}\text{Se}_x$ )

REFLECTION COEFFICIENT

Reflection coefficient as a function of photon energy for single crystal, n-type  $\text{Bi}_2\text{Se}_3$  at 300°K. Radiation is normal to (0001) cleavage plane, ( $E_{1c}$ ).



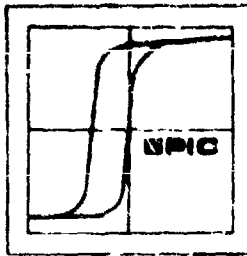
[Ref. 22468]

mol% Bi2Se3 in Bi2Te3	$E_1$	$E_2$	$E_3$	$E_4$	$E_5$	$E_6$	$E_7$
0	1.78	3.23	4.20	6.29	7.34	8.72	9.80
5	1.87	3.30		6.39	7.47	8.79	9.88
10	1.95		4.33	6.50	7.63	8.87	
20	2.14	3.80	4.41	6.66	7.67	9.10	
30	2.33	3.94	4.60	6.97	8.06	9.23	10.0
40	2.28	3.79	3.90	4.57	7.10	8.20	9.49
50	2.28	3.75	3.90	4.60	7.05	8.16	9.45
60	2.34	3.73	4.02	4.70	7.20	8.30	9.45
70	2.33	3.73	4.27	4.74	7.20	8.18	9.45
80	2.29	3.73	4.18	4.83	7.14	8.25	9.37
90	2.34	3.73	4.19	4.85	7.11	8.26	9.45
100	2.34	3.73	4.24	4.87	7.20	9.45	10.16

$\text{Bi}_2\text{Te}_3$  and  $\text{Bi}_2\text{Se}_3$  are single crystals. The alloys are polycrystalline. Peaks for 2 alloys are shown graphically on this page and the preceding one.

[Ref. 22468]



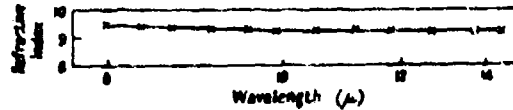


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**BISMUTH TELLURIDE**

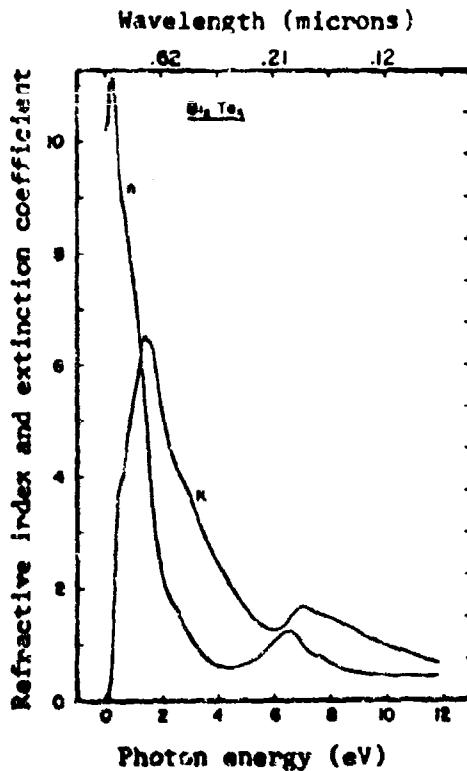
**REFRACTIVE INDEX (n)**

<u>Symbol</u>	<u>Value</u>	<u>Sample</u>	<u>Wavelength</u>	<u>Temperature</u>	<u>Ref.</u>
n	9.2	single crystal, n-type (0001)	8-14 $\mu$	300°K	3124



Refractive index as a function of wavelength for single crystal, n-type  $\text{Bi}_2\text{Te}_3$ , iodine-compensated intrinsic. Data taken on a (0001) cleavage plane at 118°K.

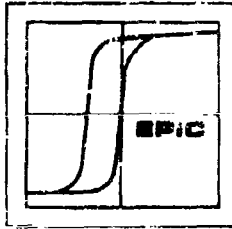
[Ref. 3124]



Refractive index, n, and extinction coefficient, k, as a function of photon energy in single crystal, p-type  $\text{Bi}_2\text{Te}_3$ . Radiation normal to cleavage plane, (0001),  $E_{1c}$ .

[Ref. 22468]

No refractive index data available for  $\text{Bi}_2\text{Se}_3$ .



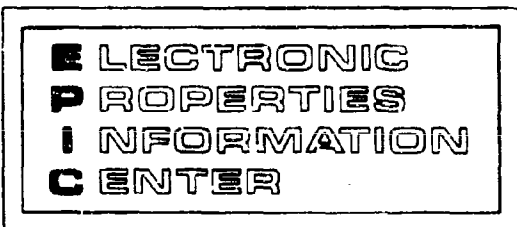
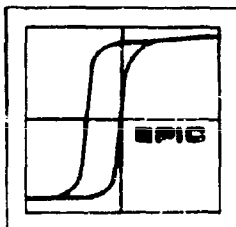
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**BISMUTH TELLURIDE**

**THERMAL CONDUCTIVITY (k)**

Symbol	Value (W/cm deg)	$\sigma$ (ohm-cm) <sup>-1</sup>	Sample (single crystal)	Temperature	Ref.
k	.0316	2700	n-type, impurity, parallel (0001)	150°K	2678
	.0187	730	" " "	300°K	
	.0278	370	n-type, near intrinsic, "	150°K	
	.0244	200	" " "	300°K	2678
k <sub>L</sub>	.0268		n-, and p-type, single crystals or aligned polycrystalline	150°K	2421
	.0157			300°K	2421
k	<u>p-type</u>	<u>n-type</u>	<u>parallel (0001),</u>	77°K	3215
	.072	.066	n-type, $\sigma = 6.3 \times 10^3$ (ohm-cm) <sup>-1</sup> for .09% iodine-doped		
k <sub>e</sub>	.01	.011			
k <sub>L</sub>	.06	.055	p-type, $\sigma \sim 6 \times 10^3$ (ohm-cm) <sup>-1</sup> for undoped material		
k	.0034		p-type, $\rho = .13 \times 10^{-2}$ ohm-cm	517°K	2401
	.004		$\rho = .2 \times 10^{-2}$ (hot-pressed)	428°K	2401

k = total thermal conductivity  
k<sub>e</sub> = electron thermal conductivity  
k<sub>L</sub> = lattice thermal conductivity



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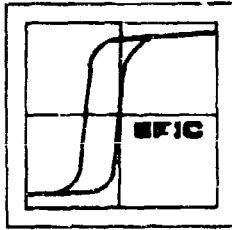
**BISMUTH SELENIDE**

**THERMAL CONDUCTIVITY**

Symbol	Value (W/cm deg)	Sample (single crystal)	Temperature	Ref.
k	.0077	p-type, $\rho = .58 \times 10^{-3}$ ohm-cm	324°K	2401
	.0052		413°K	
	.0039		511°K	
	.0047	.13x10 <sup>-2</sup>	428°K	
	.0060	.83x10 <sup>-3</sup> (hot-pressed)	445°K	2401

**BISMUTH TELLURIDE-BISMUTH SELENIDE**

k	(mW/cm °K)		% Composition		Conductivity (ohm-cm) <sup>-1</sup>		Temperature	Ref.
	k <sub>e</sub>	k <sub>L</sub>	Bi <sub>2</sub> Te <sub>3</sub>	Bi <sub>2</sub> Se <sub>3</sub>				
19.8	3.3	16.5	100	0	729	single crystal, undoped	300°K	19825
16.1	2.7	13.4	95	5	591			
13.1	1.3	11.8	90	10	290			
11.9	0.9	11.0	77.78	16.67	206			
12.0	0.8	11.2	80	20				
15.6	0.4	15.2	66.67	33.33	84	n- and p-type		
14.4	1.4	13.0	50	50	315	p-type		
13.0	2.3	10.7	40	60	513			
14.5	3.8	10.7	33.33	66.67	833			
17.5	5.3	12.2	16.67	77.78	1182			
27.0	8.8	18.2	0	100	1953			



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**BISMUTH TELLURIDE**

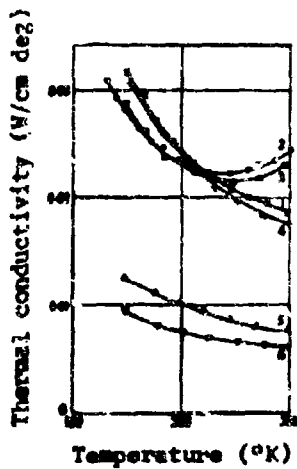
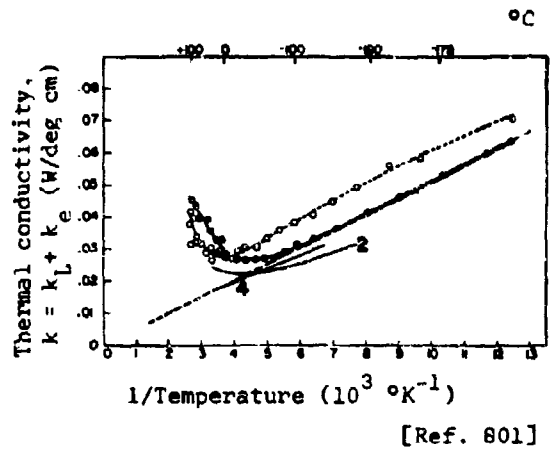
**THERMAL CONDUCTIVITY**

(Additional graphs will be found in Thermoelectric Properties)

Total thermal conductivity as a function of reciprocal temperature for two single crystal  $\text{Bi}_2\text{Te}_3$  samples, together with representative data of Goldsmid [Ref. 2678].

- o single crystal, p-type,  $n = 2 \times 10^{19}/\text{cc}$  (zone refined) (0001)
- e n-type,  $n = 3 \times 10^{17}/\text{cc}$  (0001)
- lattice thermal conductivity =  $k_L$
- $k_e$  = electron thermal conductivity

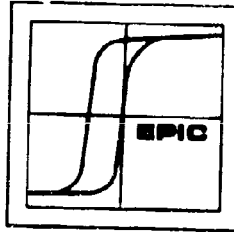
Type	Sample [Ref. 2678]
2	n near intrinsic, $\rho = .005$ ohm-cm
4	p parallel (0001), $\rho = .002$ ohm-cm



Thermal conductivity as a function of temperature for single crystal  $\text{Bi}_2\text{Te}_3$ .

Sample	Type	$\rho$ , ohm-cm	Orientation
1)	impure n	.001	parallel (0001)
2)	near intrinsic n	.005	"
3)	" n	.005	"
4)	impure p	.002	"
5)	" p	.002	normal (0001)
6)	" p	.002	"

[Ref. 2678]



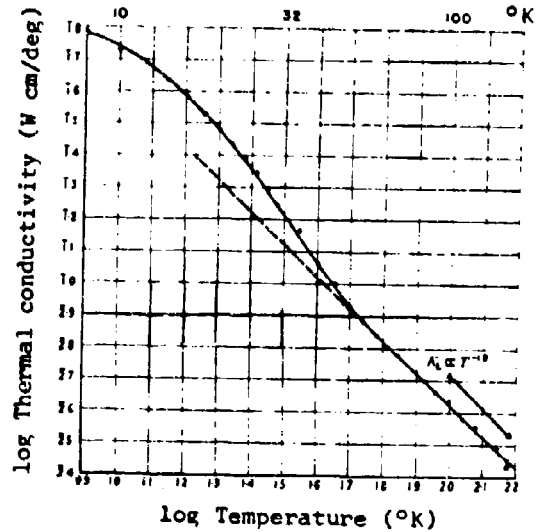
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**BISMUTH TELLURIDE**

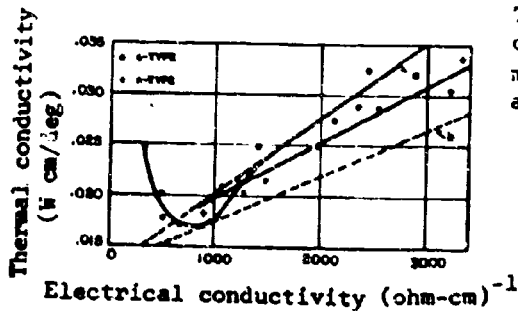
**THERMAL CONDUCTIVITY**

Lattice conductivity of stoichiometric single crystal, n- or p-type  $\text{Bi}_2\text{Te}_3$  compared with data from Goldsmid and Ure for tellurium-doped samples. Temperature coefficient of lattice conductivity is given for temperatures over 100°K.

- [Ref. 2421], 150-300°K
- ▲ [Ref. 801], 77-373°K



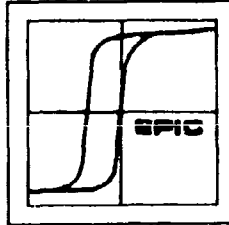
[Ref. 3466]



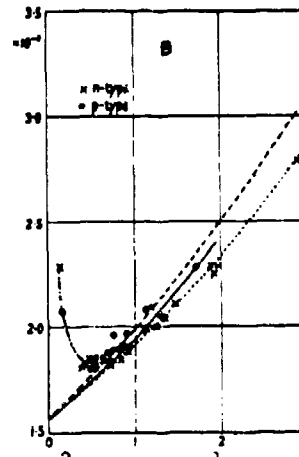
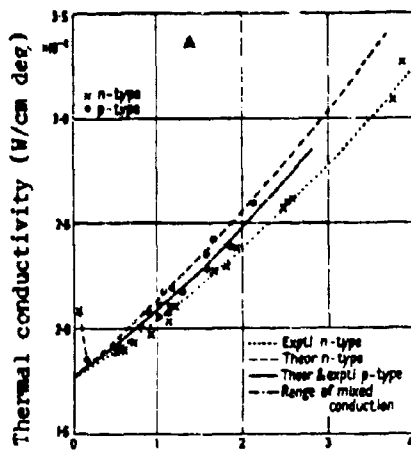
Thermal conductivity as a function of electrical conductivity in  $\text{Bi}_2\text{Te}_3$ , at 300°K. Samples are macrocrystalline, the p-type has excess bismuth and the n-type is CuI-doped.

- theoretical curves, calculated for thermal scattering (a) and degeneracy (b)

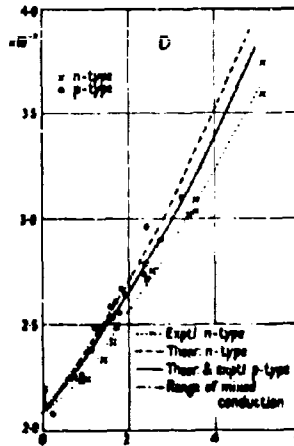
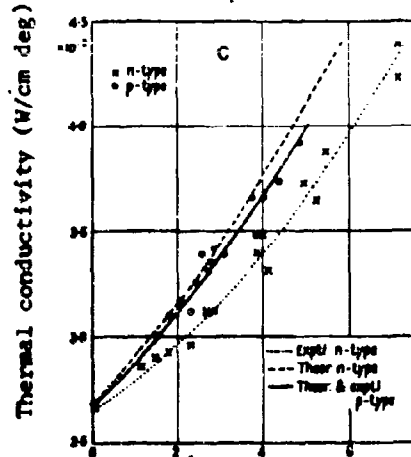
[Ref. 7768]



BISMUTH TELLURIDE  
THERMAL CONDUCTIVITY

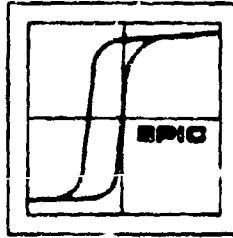


Thermal conductivity as related to electrical conductivity at 250°K (A) and 300°K (B). The single crystal, p-type samples were variously doped, the n-type are doped with iodine and chlorine only. The decrease in lattice thermal conductivity for the n-type material is due to additional phonon scattering by the halogen impurity.



Thermal conductivity as related to electrical conductivity at 150°K (C) and 200°K (D).

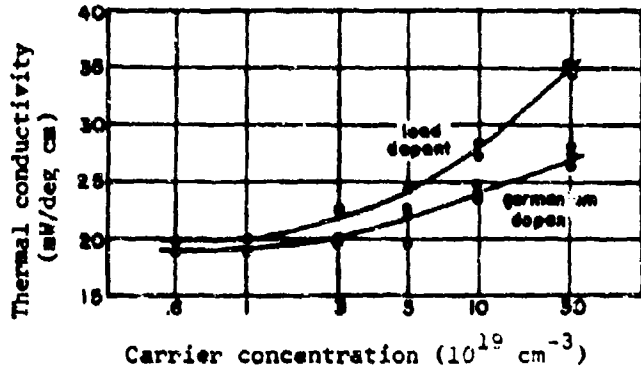
[Ref. 2421]



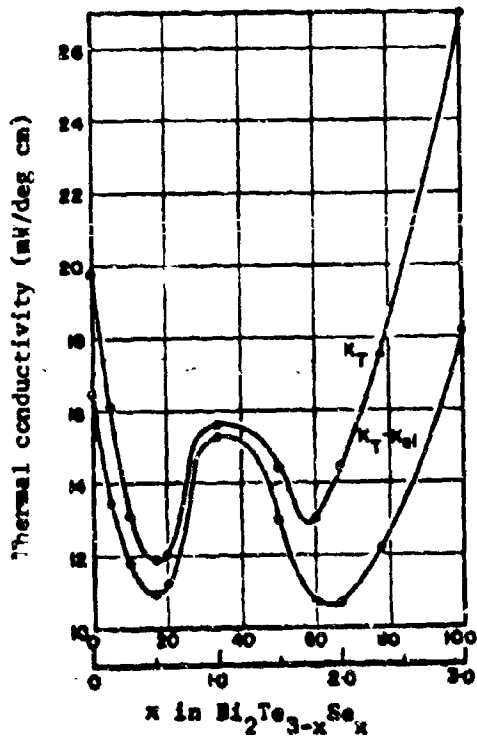
BISMUTH TELLURIDE-BISMUTH SELENIDE ( $\text{Bi}_2\text{Te}_{3-x}\text{Se}_x$ )

THERMAL CONDUCTIVITY

Thermal conductivity as a function of carrier concentration for single crystal  $\text{Bi}_2\text{Te}_3$  at 300°K. The samples are lead- and germanium-doped, lead yields p-type, germanium gives n-type.

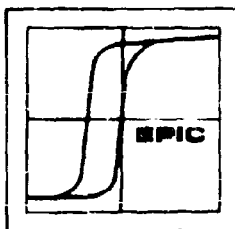


[Ref. 16182]



Thermal conductivity as a function of composition in the  $\text{Bi}_2\text{Te}_3$ - $\text{Bi}_2\text{Se}_3$  system at 300°K.  $k_T$  is thermal conductivity.  $k_e$  is electron thermal conductivity. All samples are polycrystalline, at  $x = 1$  type changes from p to n.

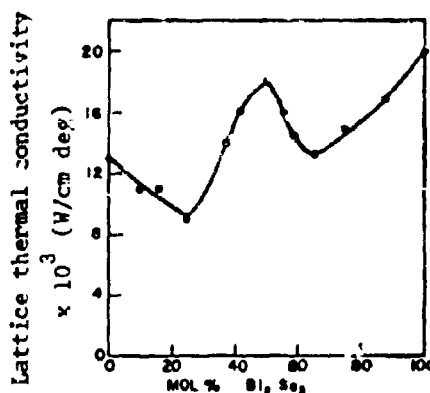
[Ref. 19875]



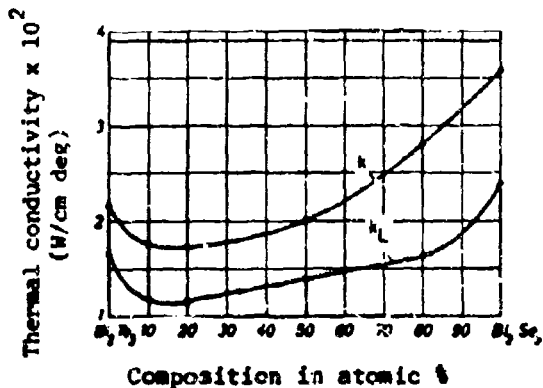
BISMUTH TELLURIDE-BISMUTH SELENIDE ( $\text{Bi}_2\text{Te}_{3-x}\text{Se}_x$ )

THERMAL CONDUCTIVITY

Lattice thermal conductivity as a function of composition in the  $\text{Bi}_2\text{Te}_3$ - $\text{Bi}_2\text{Se}_3$  system. Samples are macrocrystalline, n-type, copper bromide-doped.



[Ref. 7768]



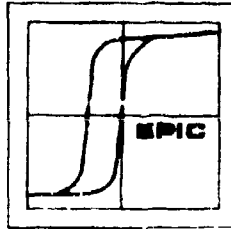
Thermal conductivity as a function of composition in the  $\text{Bi}_2\text{Te}_3$ - $\text{Bi}_2\text{Se}_3$  system at 300°K. Single crystal samples are 0.1% silver iodide-doped.

$k$  = thermal conductivity  
 $k_L$  = lattice thermal conductivity

Lack of data between 33 and 50%  $\text{Bi}_2\text{Se}_3$  masks the anomalous behaviour seen in [Ref. 7768] and [Ref. 19825].

[Ref. 3857]

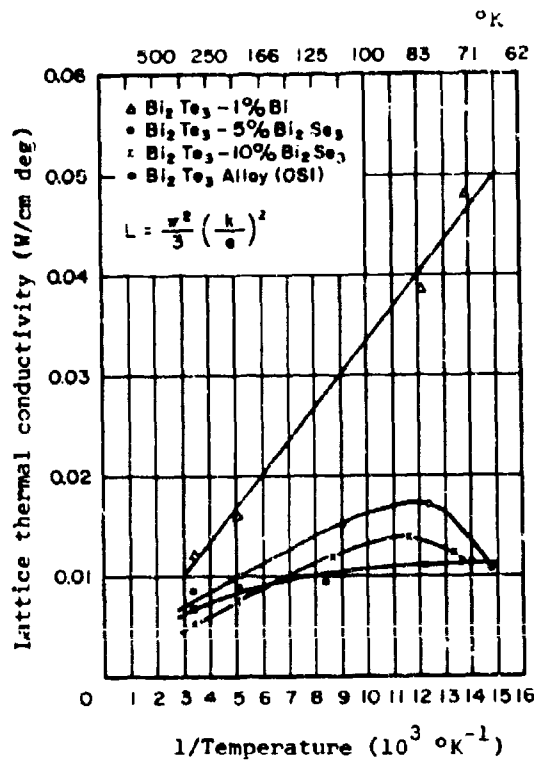




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BISMUTH TELLURIDE-BISMUTH SELENIDE ( $\text{Bi}_2\text{Te}_{3-x}\text{Se}_x$ )

THERMAL CONDUCTIVITY

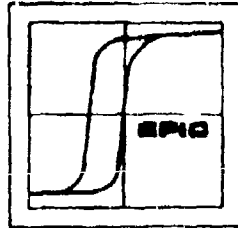


Thermal conductivity as a function of reciprocal temperature for several  $\text{Bi}_2\text{Te}_3$ - $\text{Bi}_2\text{Se}_3$  polycrystalline alloys.

- commercial, n-type  $\text{Bi}_2\text{Te}_3$
- ▲ p-type  $\text{Bi}_2\text{Te}_3$  + 1%  $\text{Bi}_2\text{Se}_3$
- n-type  $\text{Bi}_2\text{Te}_3$  + 5%  $\text{Bi}_2\text{Se}_3$  + .26% CuBr
- × n-type  $\text{Bi}_2\text{Te}_3$  + 10%  $\text{Bi}_2\text{Se}_3$  + .26% CuBr

The electronic component of the thermal conductivity has been subtracted by assuming degenerate statistics and using the Wiedmann-Franz ratio.

[Ref. 15503]



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**BISMUTH TELLURIDE**

**THERMOELECTRIC PROPERTIES**

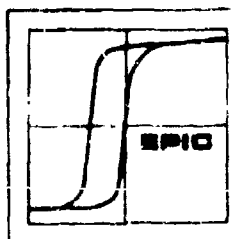
Q ( $\mu\text{V}/^\circ\text{K}$ )	$\sigma$ ( $\text{ohm-cm}^{-1}$ )	k (W/cm deg)	Z ( $\text{deg}^{-1}$ )	Sample	Temperature Ref.
61	$6.9 \times 10^3$	.072		single crystal, p-type, undoped, parallel (0001)	77°K 3215
68	5.85	.072			
-139	1.71	.058		single crystal, n-type with increasing I-doping	3215
-73	6.3	.066			
-22	15.2	.076			

				macrocrystalline			
				Doping			
				wgt. %	$n$ ( $10^{19} \text{ cm}^{-3}$ )		
+240	$5.25 \times 10^2$	.0200	$1.51 \times 10^{-3}$	undoped	(1.23)	300°K	3867
+242	3.05	.0215	0.83	AgI 0.01	-		
+ 13	3.50	-	-	AgI 0.03	-		
-202	11.50	.0216	2.18	AgI 0.10	2.05		
-177	15.40	.0230	2.10	AgI 0.15	2.8		
-148	21.00	.0248	1.86	AgI 0.20	3.83		
-73	53.20	-	-	AgI 1.00	19.2		
+184	7.74	.0207	1.26	Sn 0.1	3.25		
+100	8.85	.0210	0.47	Sn 0.3	10.35		
+ 55	10.00	-	-	Sn 0.5	33.4		3867

				impure			
				single crystal, p-type,			
				n-type			
+200	500	.0175	$1.14 \times 10^{-3}$	single crystal, p-type, n-type		300°K	2678
-215	750	.019	2.81				
-200	200	.024	2.50	pure, n-type			2678

All measurements parallel (0001)

Q (thermal e.s.f.);  $\sigma$  (electrical conductivity); Z (figure of merit); k (thermal conductivity); n (carrier concentration)



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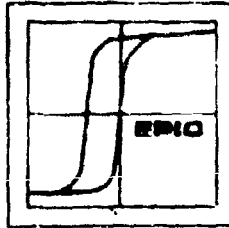
BISMUTH TELLURIDE

THERMOELECTRIC PROPERTIES

Q (max)	$\sigma$ (ohm-cm) <sup>-1</sup>	k (W/cm deg)	Z <sub>T</sub> (300K)	n <sub>i</sub> cm <sup>-3</sup>	Sample	Temperature	Ref.
					single crystal		
180	500	.021	>0.048	5x10 <sup>18</sup>	n-type, excess Te	333°K	2624
170	400		>0.041	8x10 <sup>18</sup>	p-type, excess Bi or Pb	333°K	
210	300					300°K	2624

BISMUTH SELENIDE

-100	2000	~ .03	.66x10 <sup>-3</sup>	2x10 <sup>19</sup>	n-type	300°K	2866
-51	2000			23x10 <sup>18</sup>	single crystal	300°K	21836
-41	650			23x10 <sup>18</sup>	Bi <sub>1.95</sub> In <sub>0.14</sub> Se <sub>3</sub> macrocrystalline	300°K	21836



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BISMUTH TELLURIDE-BISMUTH SELENIDE

THERMOELECTRIC PROPERTIES

$\text{Bi}_2\text{Te}_3$	$\text{Bi}_2\text{Se}_3$	Q ( $\mu\text{V}/^\circ\text{C}$ )	$\sigma$ ( $\text{ohm-cm}^{-1}$ )	k (W/cm $^\circ\text{C}$ )	Z ( $\text{deg}^{-1}$ )	Ref.
100%	0	+ 212	729	.0198	$1.66 \times 10^{-3}$	19875
95	5	+ 231	591	.0161	1.96	
90	10	+ 273	290	.0131	1.65	
83.33	16.67	+ 290	206	.0119	1.46	
80	20	+ 284	180	.0120	1.20	
66.67	33.33	~ 0	84	.0156	0	
50	50	- 228	315	.0144	1.14	
40	60	- 180	513	.0130	1.28	
33.33	66.67	- 135	833	.0145	1.05	
22.32	77.78	- 109	1182	.0175	0.80	
0	100	- 70	1953	.0270	0.95	19825

The above values are for macrocrystalline samples at 300°K.

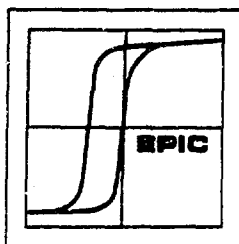
100	0	+ 240	525	.02	$1.51 \times 10^{-3}$	3867
80	20	+ 90	263	-	-	
66.67	33.33	- 213	262	.0142	.14	
50	50	- 163	486	.0158	.82	
25	75	- 87	1814	.0199	.84	
0	100	- 60	2330	.0304	.28	

The above values are for macrocrystalline samples at 300°K.

100	0	- 202	1148	.0216	$2.76 \times 10^{-3}$	3867
90	10	- 179	1335	.0175	1.08	
80	20	- 177	975	.0174	1.07	
66.67	33.33	- 188	1560	-	1.9	
50	50	- 105	1440	.0203	0.5	
20	80	- 53	2730	.0209	0.27	
0	100	- 44	3530	.0307	0.16	

The above values are for silver iodide doped macrocrystalline at 300°K.

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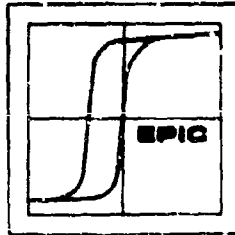
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**BISMUTH TELLURIDE-BISMUTH SELENIDE**

**THERMOELECTRIC PROPERTIES**

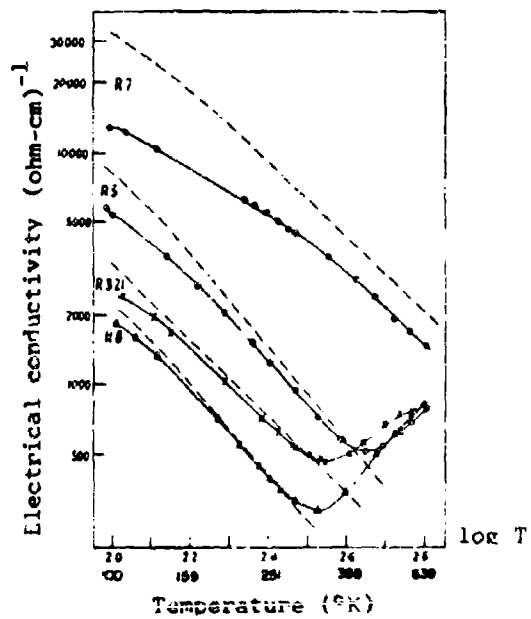
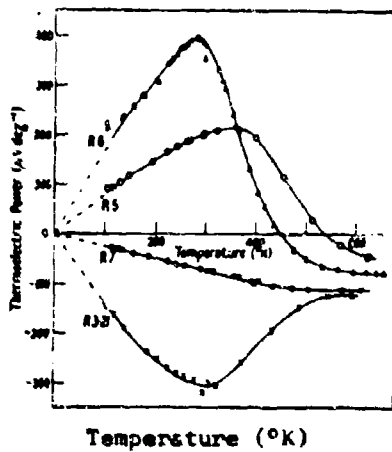
$\text{Bi}_2\text{Te}_3$	$\text{Bi}_2\text{Se}_3$	$Q$ ( $\mu\text{V}/^\circ\text{C}$ )	$\sigma$ ( $\text{ohm-cm}^{-1}$ )	$k$ ( $\text{W/cm } ^\circ\text{C}$ )	$Z$ ( $\text{deg}^{-1}$ )	Temperature	Ref.
90	10	- 200.1	1245	.0168		293.3°K	19515
		- 173.6	1838	.0228		271 °K	
		- 125.6	3495	.0398		115.9°K	19515

The above values are for a single crystal, n-type sample.



**BISMUTH TELLURIDE**

**THERMOELECTRIC PROPERTIES**

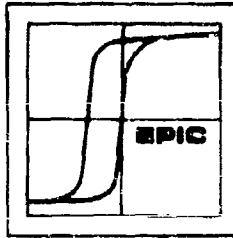


Electrical conductivity and thermoelectric emf as a function of temperature for  $Bi_2Te_3$ . Current flow parallel to cleavage plane (0001).

----- calculated curve  
————— experimental

Sample	Type	Crystal
R 8	p	single crystal
R 5	p	macrocrystalline, zone refined
R 7	n	macrocrystalline, zone refined
R-3-21	n	macrocrystalline, zone refined

[Ref. 3223]

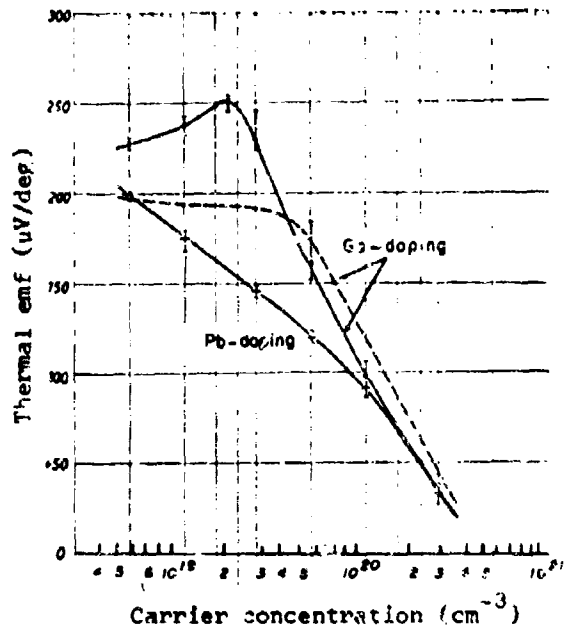


BISMUTH TELLURIDE

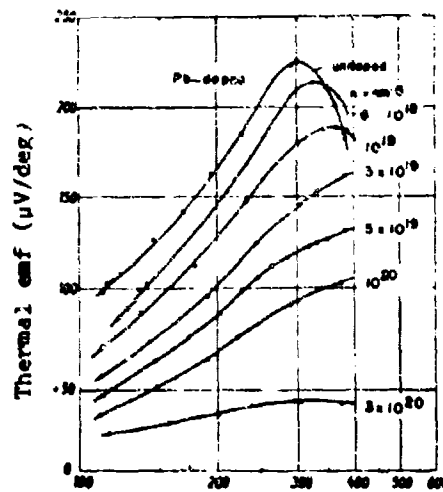
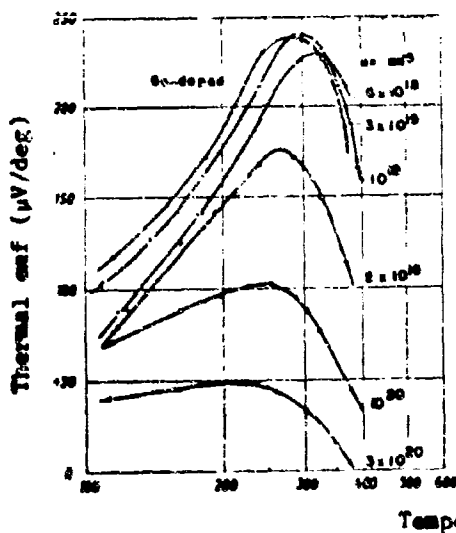
THERMOELECTRIC PROPERTIES

Thermal emf as a function of lead and germanium concentration in macro-crystalline  $\text{Bi}_2\text{Te}_3$  at  $300^\circ\text{K}$ .

- measurement taken immediately after sample preparation (Ge-doped)
- measured about three months after sample preparation

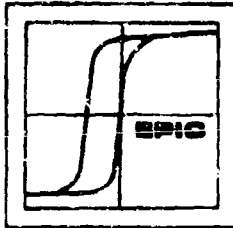


[Ref. 15813]



Thermal emf as a function of temperature for Pb-, and Ge-doped, p-type, macro-crystalline  $\text{Bi}_2\text{Te}_3$ , normal to (0001) cleavage plane.

[Ref. 15813]



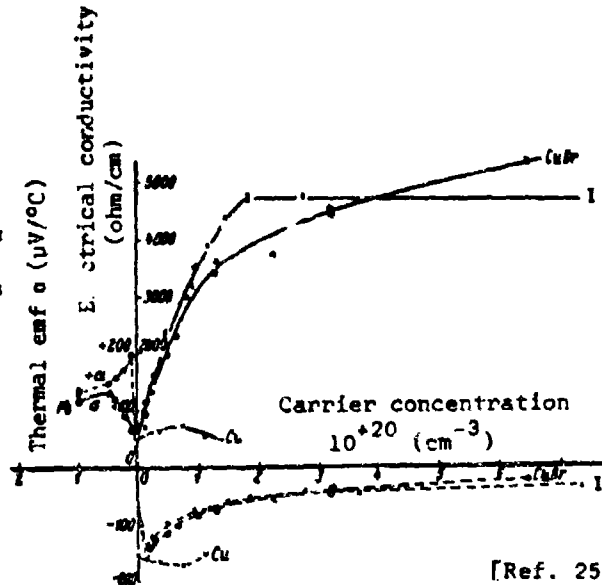
BISMUTH TELLURIDE

THERMOELECTRIC PROPERTIES

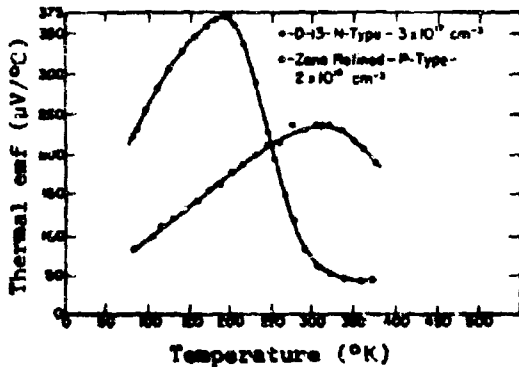
(---) Thermal emf and (—) electrical conductivity in polycrystalline  $\text{Bi}_2\text{Te}_3$  as a function of carrier concentration at a range of 300-700°K. Lead additives yield p-type material; halides yield n-type samples. Copper must be added as a halide rather than the metal.

Maximum Values for Lead-doped Samples

$\sigma = 1300 \text{ (ohm-cm)}^{-1}$   
 $Q = 20 \text{ } \mu\text{V}/^\circ\text{K}$



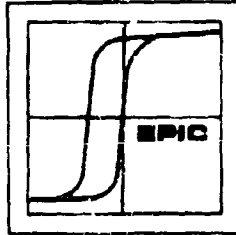
[Ref. 2526]



Seebeck coefficient as a function of temperature for n-type, Te-doped, and p-type zone refined, single crystal bismuth telluride.

[Ref. 14854]



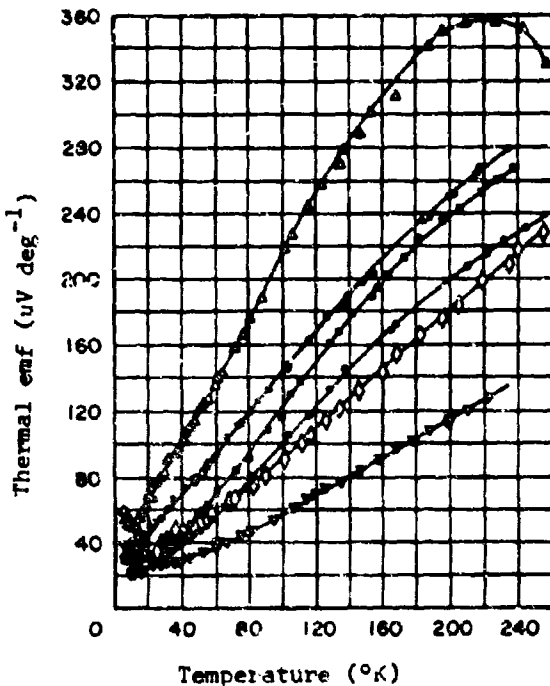


BISMUTH TELLURIDE

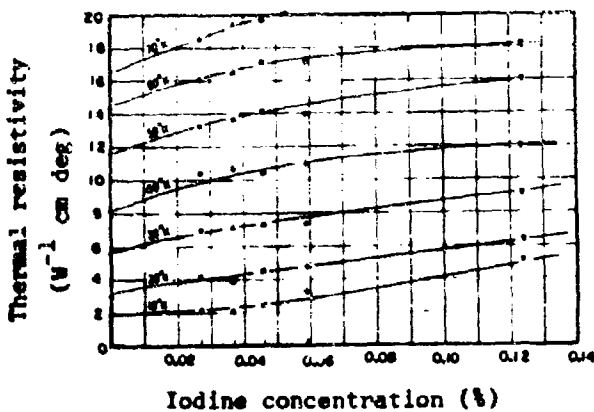
THERMOELECTRIC PROPERTIES

Thermoelectric emf as a function of temperature for single crystal, n-type, iodine-doped  $\text{Bi}_2\text{Te}_3$ , cut parallel to (0001) cleavage plane.

Symbol	Type	% Iodine
△	n	.037
□	n	.046
○	n	.059
▽	n	.124
●	p	.027
▲	p	undoped

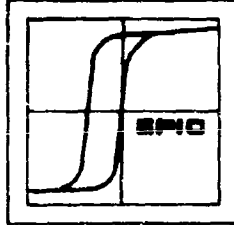


[Ref. 3466]



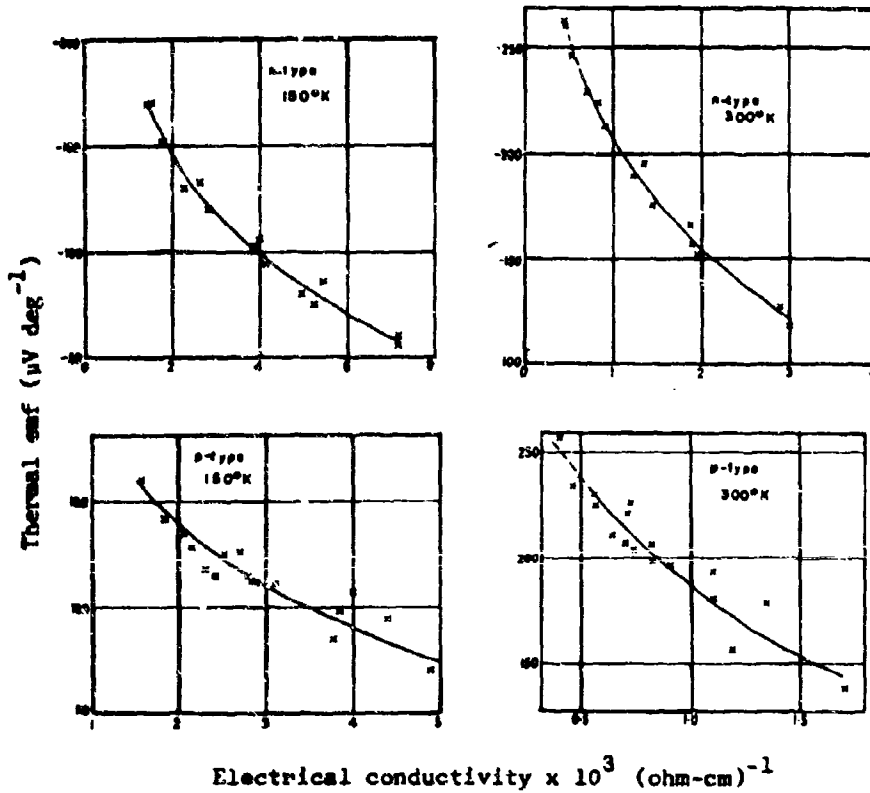
Thermal resistivity as a function of iodine doping at several temperatures for single crystal, n- or p-type  $\text{Bi}_2\text{Te}_3$ ; iodine-doped sample cut parallel to (0001) cleavage plane.

[Ref. 3466]



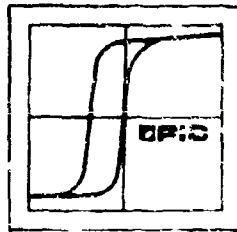
BISMUTH TELLURIDE

THERMOELECTRIC PROPERTIES



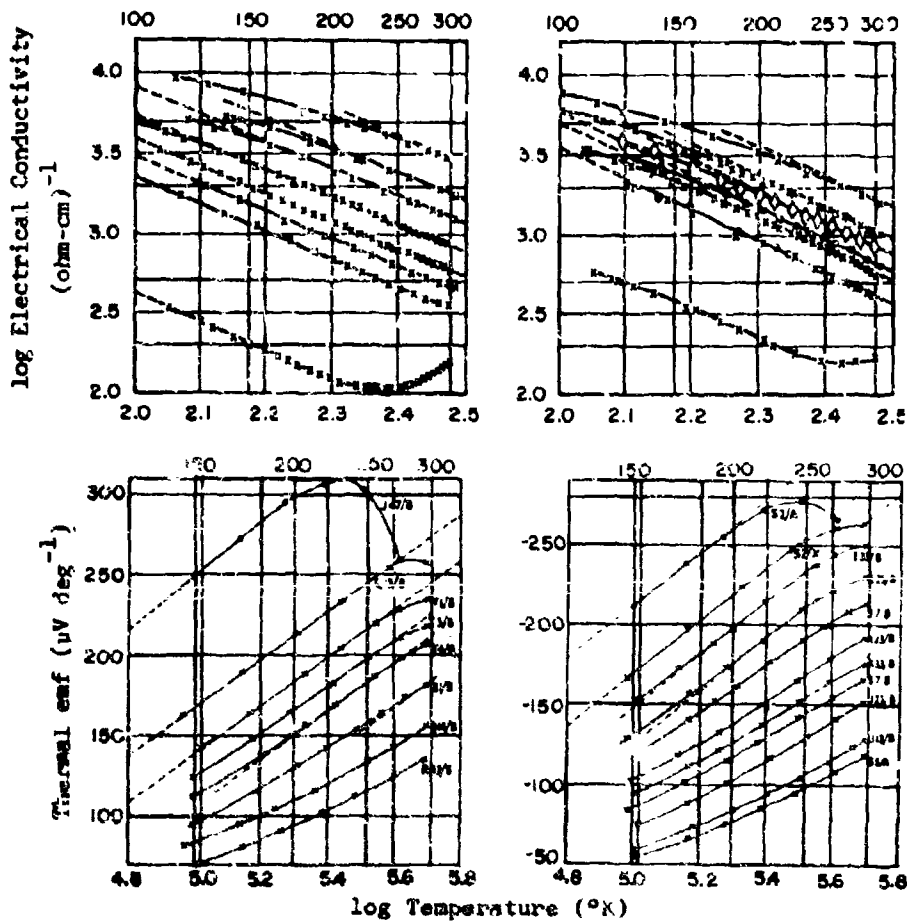
Thermal emf as related to conductivity for zone refined polycrystalline Bi<sub>2</sub>Te<sub>3</sub>. Type and temperature are shown on individual graphs. The p-type material is undoped, or with excess bismuth:  $\rho \sim .002$  ohm-cm. The n-type is iodine-doped.

[Ref. 2595]



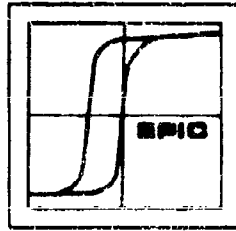
BISMUTH TELLURIDE

THERMOELECTRIC PROPERTIES



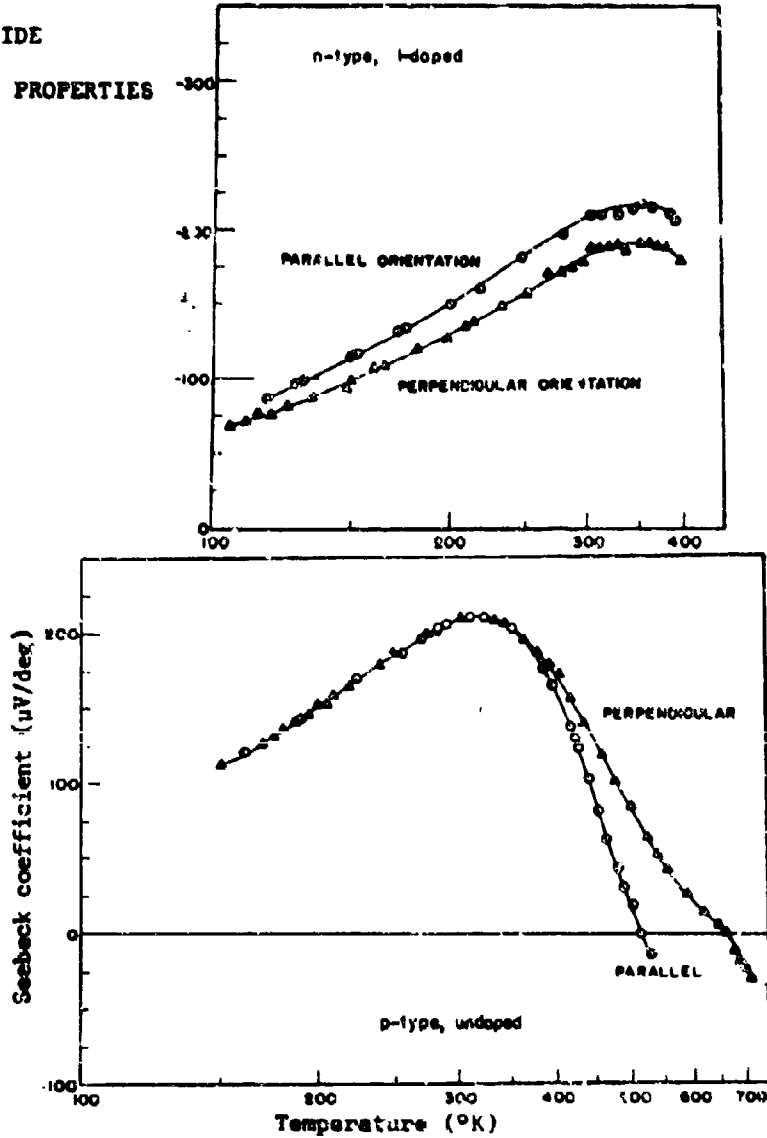
Log electrical conductivity and thermal emf as a function of log temperature for n-, and p-type  $\text{Bi}_2\text{Te}_3$  samples. Specifications are not given, but may be either single or polycrystalline. Change in slope at higher temperatures is due to mixed conduction.

[Ref. 2595]



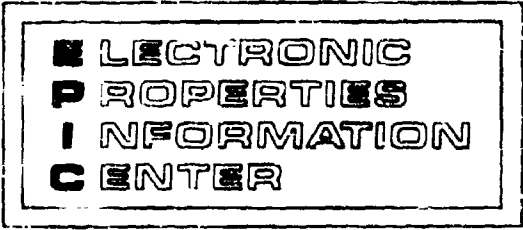
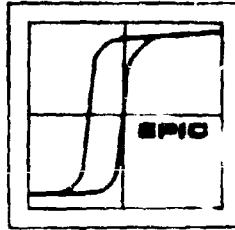
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BISMUTH TELLURIDE  
 THERMOELECTRIC PROPERTIES



Seebeck coefficient as a function of temperature for two samples of single crystal  $\text{Bi}_2\text{Te}_3$  taken parallel and normal to (0001) cleavage planes. The undoped material is seen to be isotropic at temperatures below the point at which mixed conduction begins.

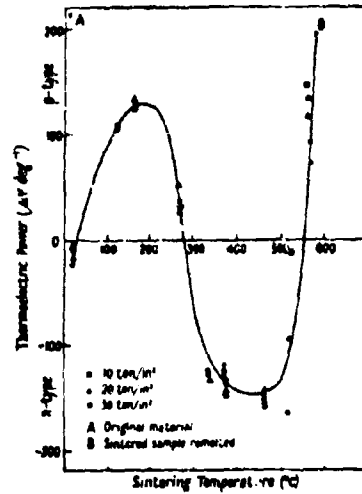
[Ref. 19827]



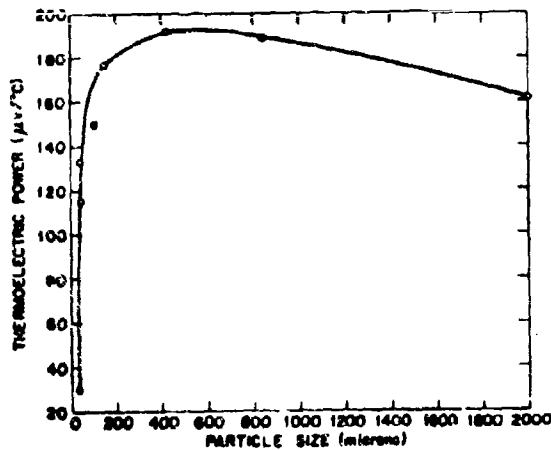
BISMUTH TELLURIDE

THERMOELECTRIC PROPERTIES

Thermal emf as a function of sintering temperature for p-type, zone refined  $\text{Bi}_2\text{Te}_3$ , iodine-doped. The material was crushed and compacted at various pressures, then sintered at temperatures up to melting point. Change in type is noted and reproducible; (10 ton/in<sup>2</sup> = 1406.14 kg/cm<sup>2</sup>). Compacting pressure has only slight effect on thermal emf.

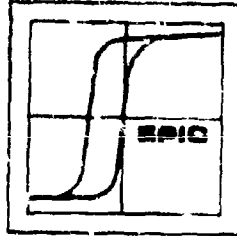


[Ref. 3585]



Thermal emf as a function of particle size in p-type  $\text{Bi}_2\text{Te}_3$  powders at 300°K,  $n \sim 2 \times 10^{19}/\text{cc}$ .

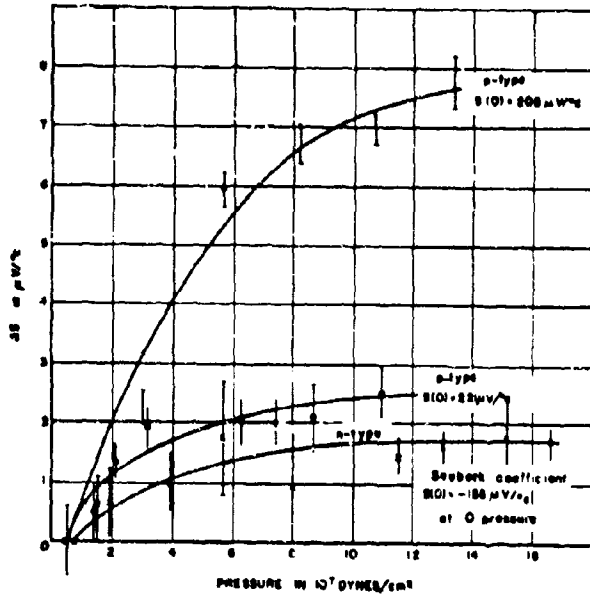
[Ref. 8758]



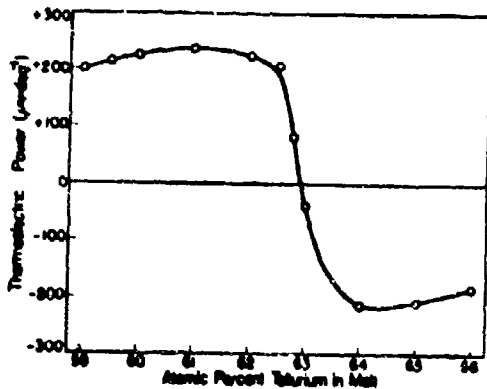
BISMUTH TELLURIDE

THERMOELECTRIC PROPERTIES

Changes in the Seebeck coefficient as a function of pressure at 300°K, in single crystal  $\text{Bi}_2\text{Te}_3$ .

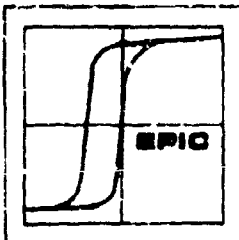


[Ref. 19826]



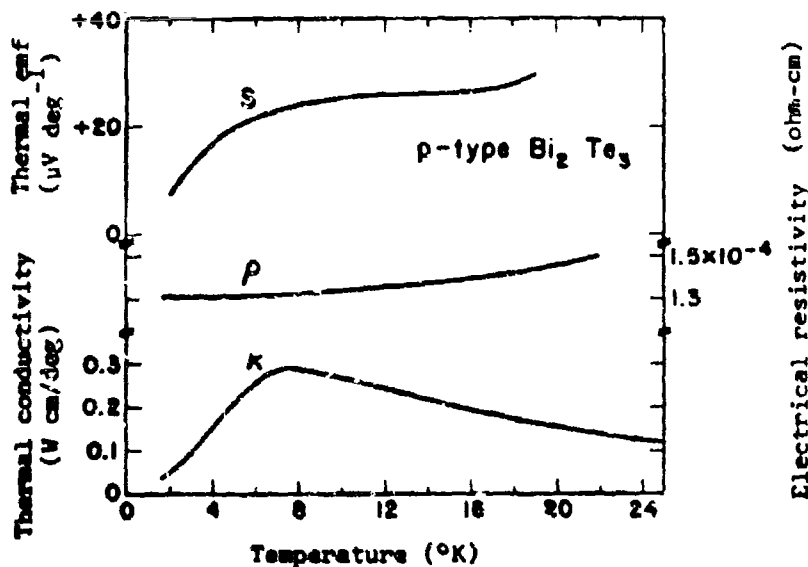
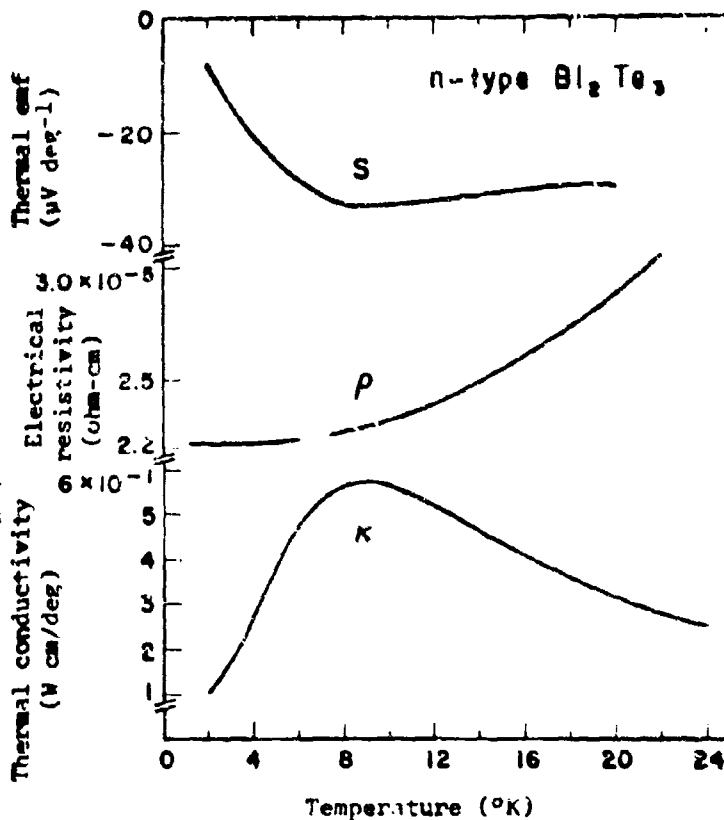
Thermal emf for  $\text{Bi}_2\text{Te}_3$  single crystal at 300°K as a function of crystal mother liquid composition. Data taken parallel (0001) cleavage plane.

[Ref. 801]

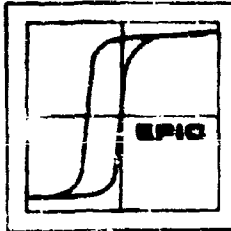


**BISMUTH TELLURIDE**  
**THERMOELECTRIC PROPERTIES**

Thermal emf, electrical resistivity and thermal conductivity for n- and p-type  $\text{Bi}_2\text{Te}_3$  as a function of temperature between 2 and 20°K. Carrier concentration for both types was  $\sim 10^{19}/\text{cc}$ .



[Ref. 12946]

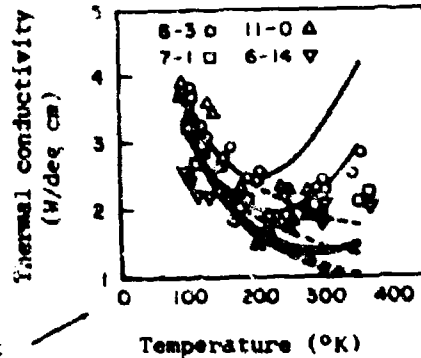
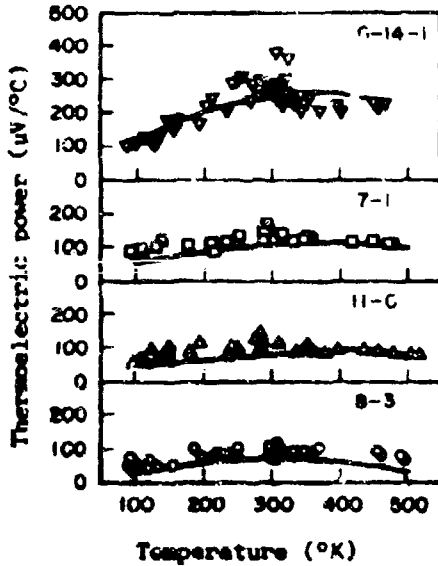
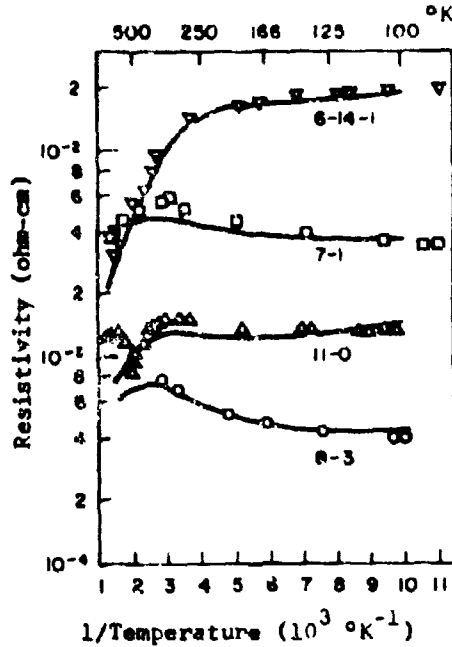


**BISMUTH SELENIDE**

**THERMOELECTRIC PROPERTIES**

Thermoelectric parameters for polycrystalline, n-type  $\text{Bi}_2\text{Se}_3$ .

Sample	$n, \text{cm}^{-3}$
8-3	$5.43 \times 10^{18}$
11-0	$4.16 \times 10^{18}$
7-1	$2.97 \times 10^{18}$
6-14-1	$.67 \times 10^{18}$

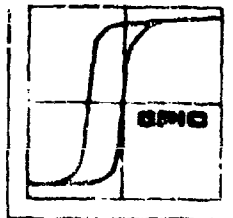


- lattice conductivity + normal electronic component
- lattice conductivity + electronic component - normal electronic component

The normal electronic component is a function of conductivity, lattice scattering and sample degeneracy.

[Ref. 21372]





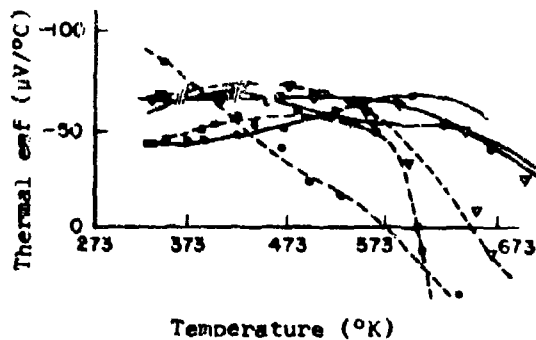
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BISMUTH SELENIDE

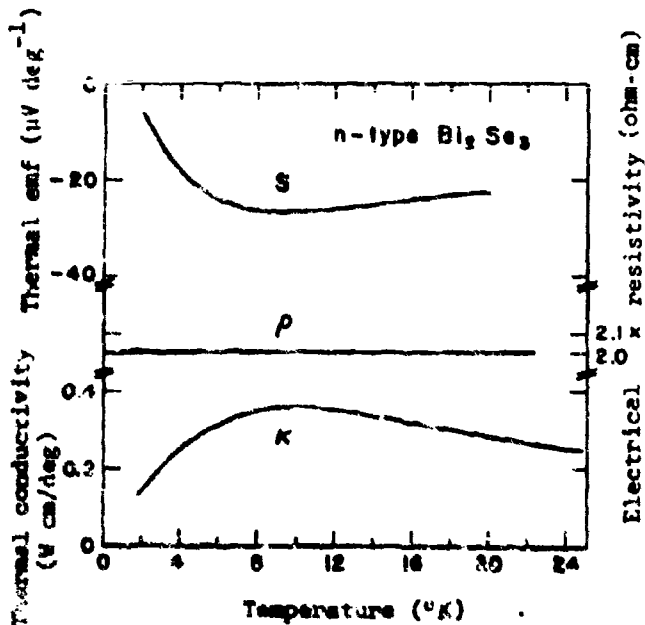
THERMOELECTRIC PROPERTIES

Thermal emf as a function of temperature for single crystal, n-type  $\text{Bi}_2\text{Se}_3$ . Although carrier concentration is the same, the decrease in conductivity of 95-98% from parallel to normal direction, above 500°K, affects the thermal emf. Measurements based on three samples.

Sample cleavage	$n, \text{cm}^{-3}$	$\sigma_{300\text{K}}$
(0001) —	$2-4 \times 10^{19}$	1000-3000 (ohm-cm) <sup>-1</sup>
⊥ (0001) ---	"	50-60 "

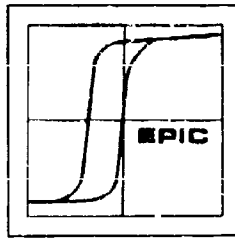


[Ref. 630]



Thermal emf, electrical resistivity and thermal conductivity in n-type  $\text{Bi}_2\text{Se}_3$  as a function of temperature from 2 to 24°K. The carrier concentration is  $\sim 10^{19}/\text{cc}$ .

[Ref. 12946]

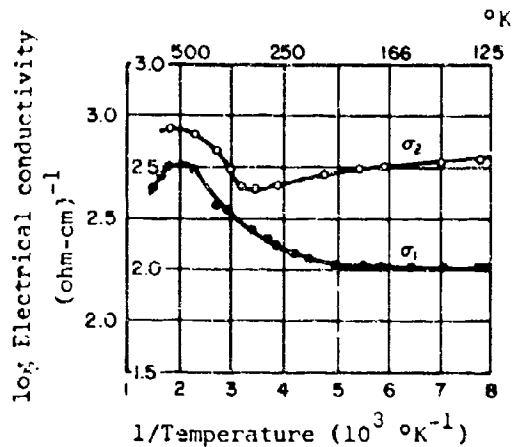


BISMUTH SELENIDE

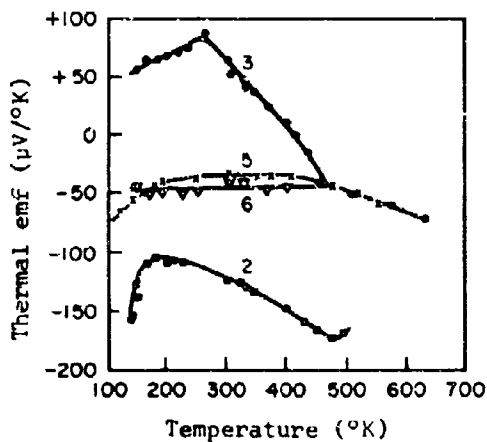
THERMOELECTRIC PROPERTIES

Log electrical conductivity as a function of reciprocal temperature for polycrystalline  $\text{Bi}_2\text{Se}_3$ .

$\sigma_1$  is p-type  
 $\sigma_2$  is n-type



[Ref. 2473]

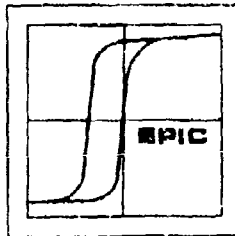


Thermal emf as a function of temperature for polycrystalline  $\text{Bi}_2\text{Se}_3$ , either hot-pressed or from slowly cooled melts.

Sample	$n, \text{cm}^{-3}$
3) p-type	$1.9 \times 10^{19}$
2) n-type	$1.6 \times 10^{18}$
5)	$1.5 \times 10^{19}$
6)	$1.7 \times 10^{19}$

[Ref. 2473]

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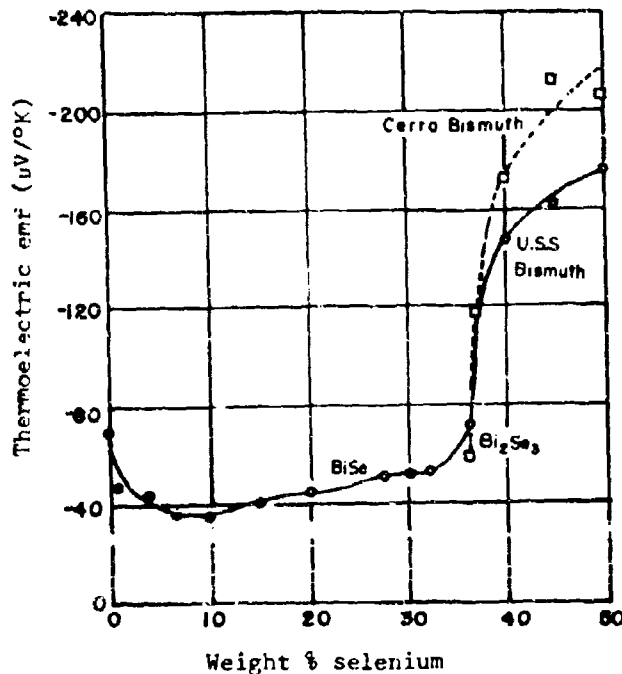


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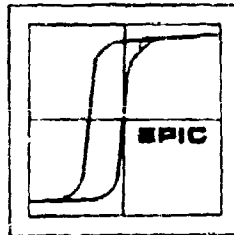
BISMUTH SELENIDE

THERMOELECTRIC PROPERTIES



Thermoelectric emf (relative to copper) of  $\text{Bi}_2\text{Se}_3$  alloys as a function of Se content at  $300^\circ\text{K}$ . The alloys were macrocrystalline. A high purity grade of selenium was used with two commercial grades of bismuth. The Cerro bismuth purity was higher than that of the USS brand, although the latter was purified before use.

[Ref. 12851]

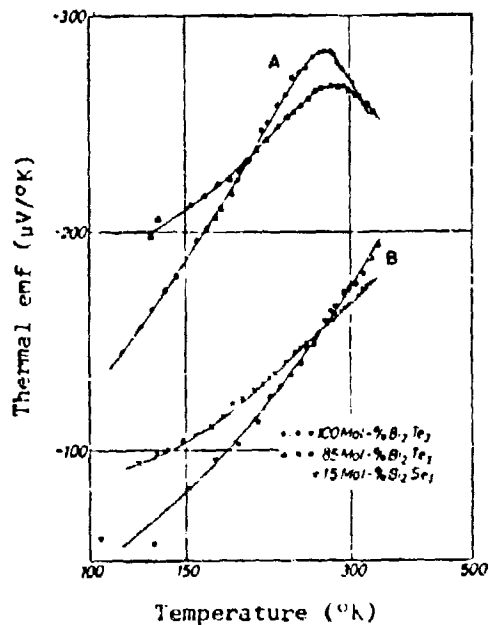


BISMUTH TELLURIDE-BISMUTH SELENIDE ( $\text{Bi}_2\text{Te}_{3-x}\text{Se}_x$ )

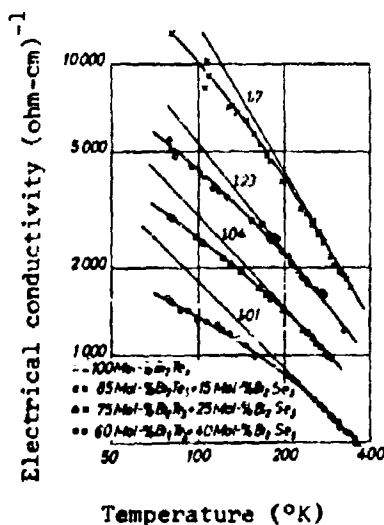
THERMOELECTRIC PROPERTIES

Thermal emf as a function of temperature for single crystal  $\text{Bi}_2\text{Te}_3$  and single crystal 85%  $\text{Bi}_2\text{Te}_3$ -15%  $\text{Bi}_2\text{Se}_3$ . The normally p-type  $\text{Bi}_2\text{Te}_3$  is altered to n-type by the presence of the selenide as well as the chlorine.

- A) weak doping
- B) strong chlorine-doped

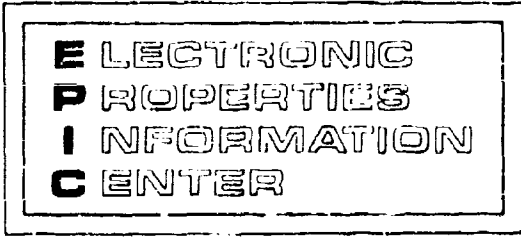
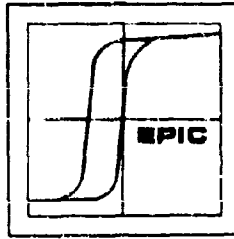


[Ref. 5810]



Electrical conductivity as a function of temperature for single crystal samples in the  $\text{Bi}_2\text{Te}_3$ - $\text{Bi}_2\text{Se}_3$  system. Chlorine doping is designed to give the maximum figure of merit. The slope of the calculated curves (indicated by integers) gives the temperature coefficient of the electron mobility.

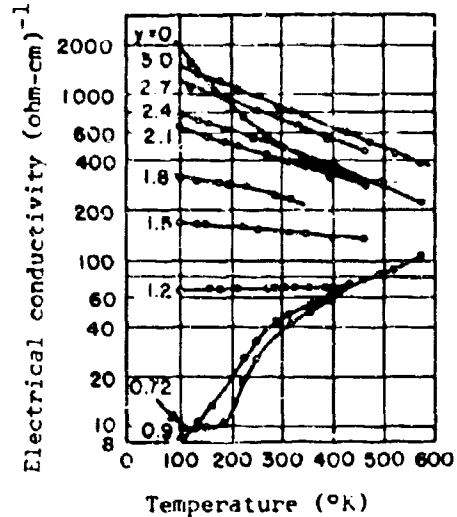
Ref. 5810]



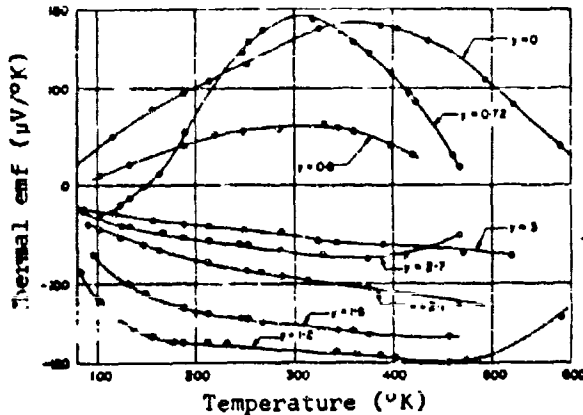
BISMUTH TELLURIDE-BISMUTH SELENIDE ( $\text{Bi}_2\text{Te}_{3-x}\text{Se}_x$ )

THERMOELECTRIC PROPERTIES

Electrical conductivity as a function of temperature for the  $\text{BiTe}_{3-y}\text{Se}_y$  system.



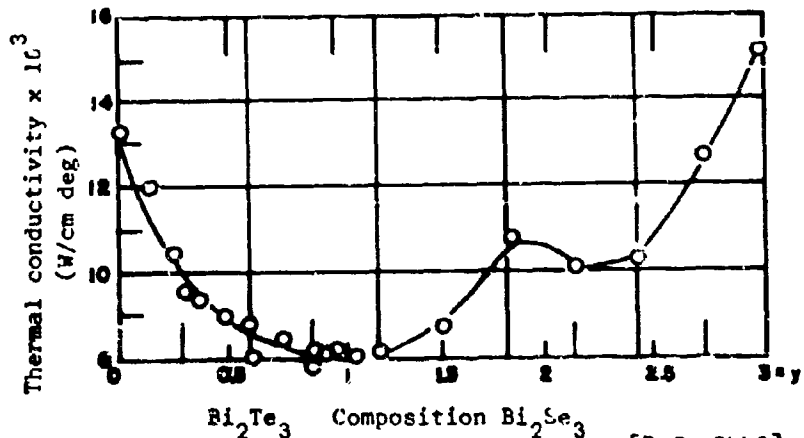
[Ref. 3449]



Seebeck coefficient as a function of temperature for polycrystalline  $\text{BiTe}_{3-y}\text{Se}_y$  mixed crystals. The crystals are columnar and the measurements are made along the (0001) longitudinal axis.

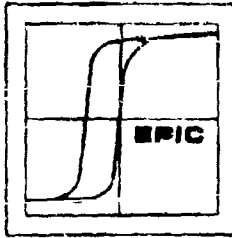
[Ref. 3449]

The total thermal conductivity of the  $\text{BiTe}_{3-y}\text{Se}_y$  system at  $300^{\circ}\text{K}$ .



[Ref. 3449]

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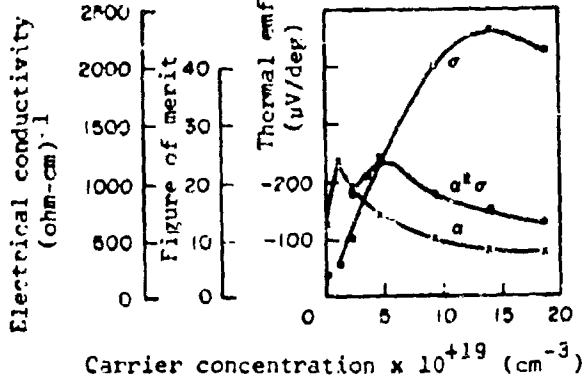
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BISMUTH TELLURIDE-BISMUTH SELENIDE ( $\text{Bi}_2\text{Te}_3\text{-xSe}_x$ )

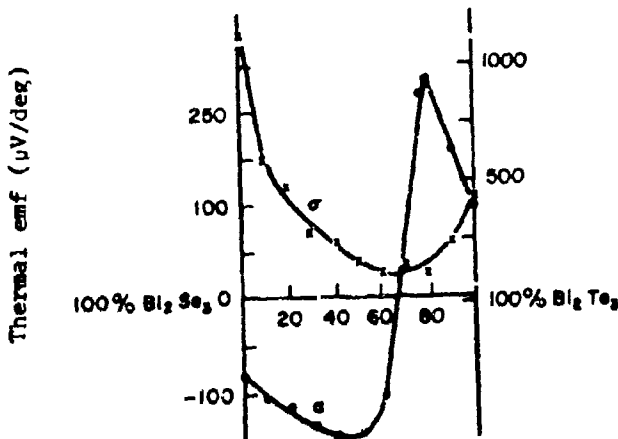
THERMOELECTRIC PROPERTIES

Thermal emf and electrical conductivity as a function of carrier concentration for iodine-doped 80%  $\text{Bi}_2\text{Te}_3$ -20%  $\text{Bi}_2\text{Se}_3$  at 300°K.

- $\sigma$  = Electrical conductivity
- $\alpha^2\sigma$  = Figure of merit
- x  $\alpha$  = Thermal emf



[Ref. 2538]

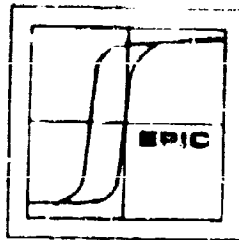


Thermal emf and electrical conductivity as a function of composition in  $\text{Bi}_2\text{Te}_3\text{-Bi}_2\text{Se}_3$  macrocrystalline samples.

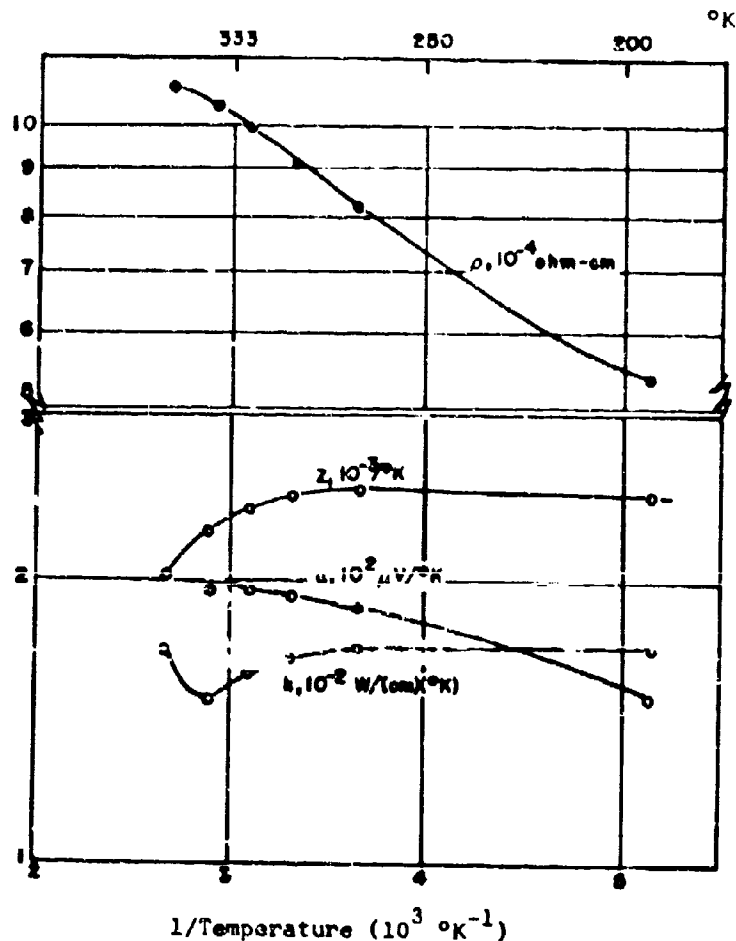
- x = Electrical conductivity
- o = Thermal emf

[Ref. 2538]





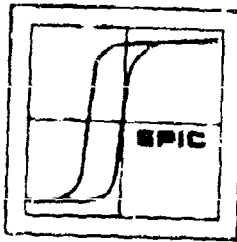
BISMUTH TELLURIDE-BISMUTH SELENIDE  
THERMOELECTRIC PROPERTIES



Thermoelectric properties as a function of reciprocal temperature for 90%  $\text{Bi}_2\text{Te}_3$ -10%  $\text{Bi}_2\text{Se}_3$ , polycrystalline samples.

- $\rho$  - resistivity
- $Q$  - thermal emf
- $k$  - thermal conductivity
- $Z$  - figure of merit





BISMUTH TELLURIDE-BISMUTH SELENIDE  
THERMOELECTRIC PROPERTIES

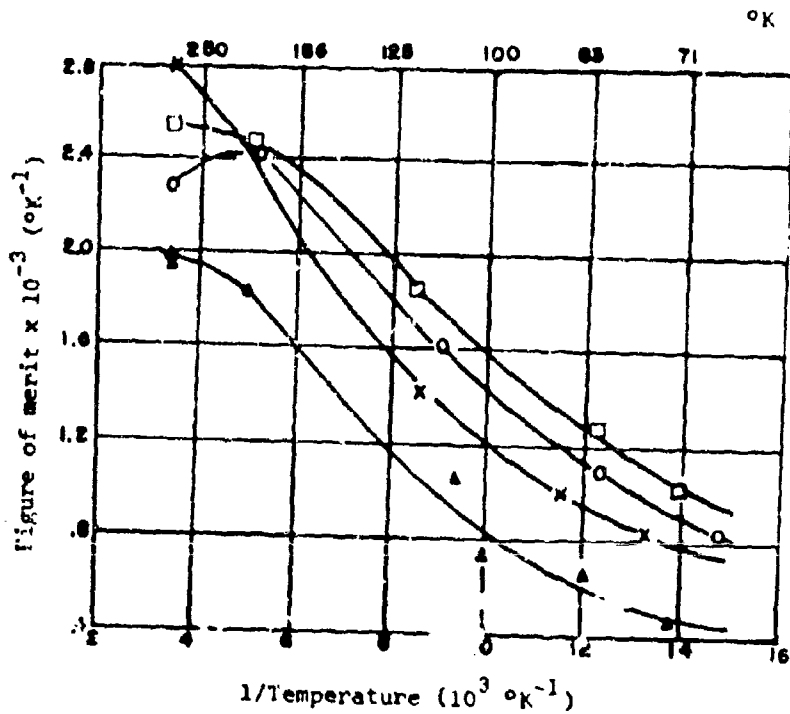
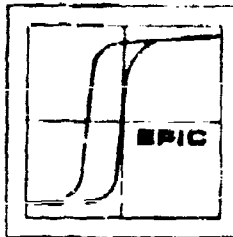


Figure of merit as a function of reciprocal temperature for several Bi<sub>2</sub>Te<sub>3</sub>-Bi<sub>2</sub>Se<sub>3</sub> commercial polycrystalline samples.

- commercial n-type Bi<sub>2</sub>Te<sub>3</sub>
- Δ p-type, Bi<sub>2</sub>Te<sub>3</sub> + 1% Bi
- n-type, Bi<sub>2</sub>Te<sub>3</sub> + 5% Bi<sub>2</sub>Se<sub>3</sub> + .26% CuBr
- x n-type, Bi<sub>2</sub>Te<sub>3</sub> + 10% Bi<sub>2</sub>Se<sub>3</sub> + .26% CuBr

[Ref. 15503]



BISMUTH TELLURIDE-BISMUTH SELENIDE ( $\text{Bi}_2\text{Te}_{3-x}\text{Se}_x$ )

THERMOELECTRIC PROPERTIES

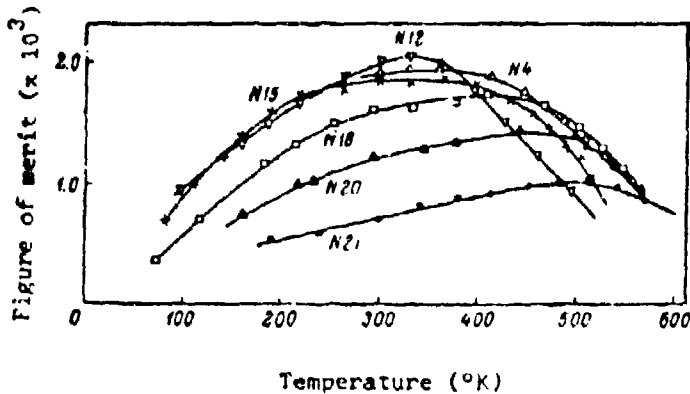
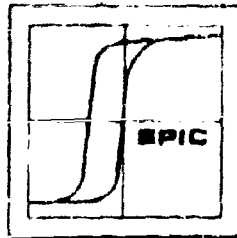


Figure of merit as a function of temperature for polycrystalline samples of  $\text{Bi}_2\text{Te}_3(80\%)\text{-Bi}_2\text{Se}_3(20\%)$ .  $n$  varies from  $3 \times 10^{19}$  to  $1.7 \times 10^{20}/\text{cc}$ . Carrier concentrations for samples 15 and 21 are given as:

	$n, \text{cm}^{-3}$
# 15)	$4.4 \times 10^{19}$
# 21)	$3.7 \times 10^{20}$

[Ref. 14600]

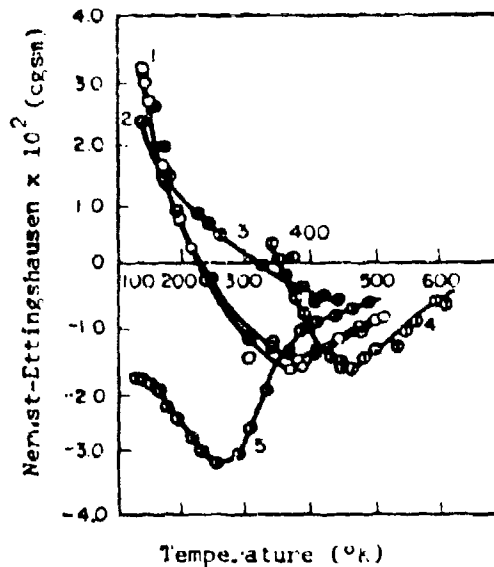


BISMUTH TELLURIDE and BISMUTH SELLENIDE

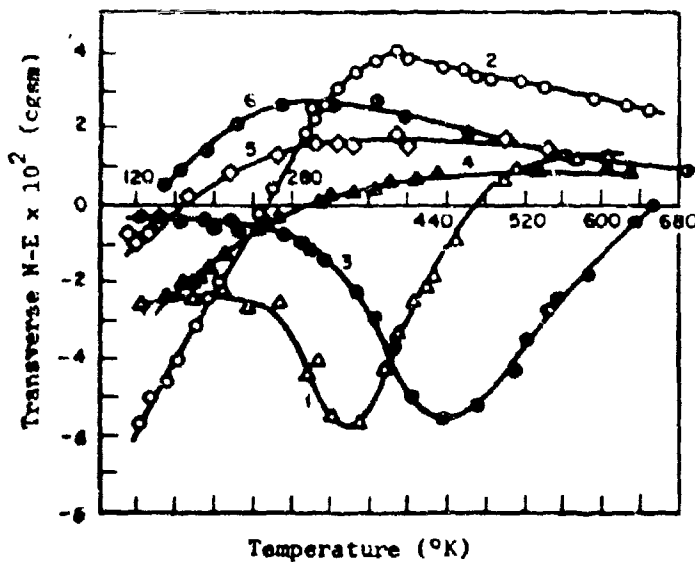
THERMOMAGNETIC PROPERTIES

Nernst-Ettingshausen coefficient as a function of temperature for polycrystalline, cast and pressed  $\text{Bi}_2\text{Te}_3$ , in a 7400 Oe field. Field is applied parallel to (0001) cleavage plane.

Sample	Type	$n, \text{cm}^{-3}$
1	n	$1.5 \times 10^{19}$
2	n	$2.2 \times 10^{19}$
3	n	$5.5 \times 10^{19}$
4	p	$6 \times 10^{19}$ $4 \times 10^{18}$



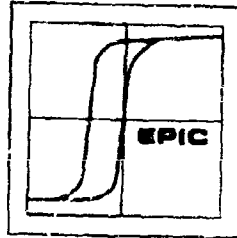
[Ref. 2537]



Transverse Nernst-Ettingshausen coefficient as a function of temperature for polycrystalline  $\text{Bi}_2\text{Se}_3$ . Material was either hot-pressed or slowly cooled. Carrier concentration at 200°K:

#	Type	$n, \text{cm}^{-3}$
1	p	$1.2 \times 10^{19}$
3	p	$1.9 \times 10^{19}$
2	n	$1.6 \times 10^{18}$
4	n	$1.2 \times 10^{18}$
5	n	$1.5 \times 10^{19}$
6	n	$1.7 \times 10^{19}$

[Ref. 2473]

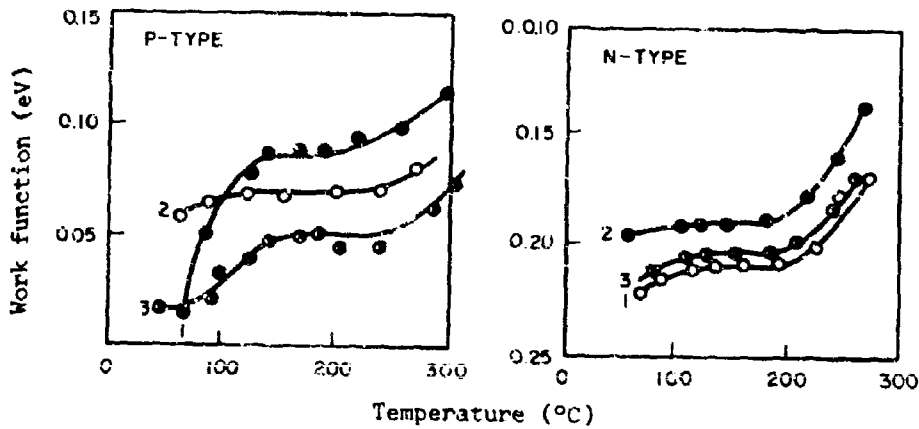


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BISMUTH TELLURIDE

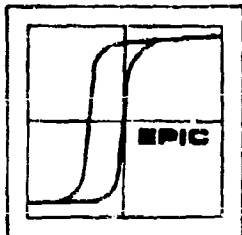
WORK FUNCTION ( $\phi$ )

Value (eV)	Sample	Test Method	Temperature	Ref.
5.30	single crystal, p-type, (0001)	electron photo-emission	300°K	493



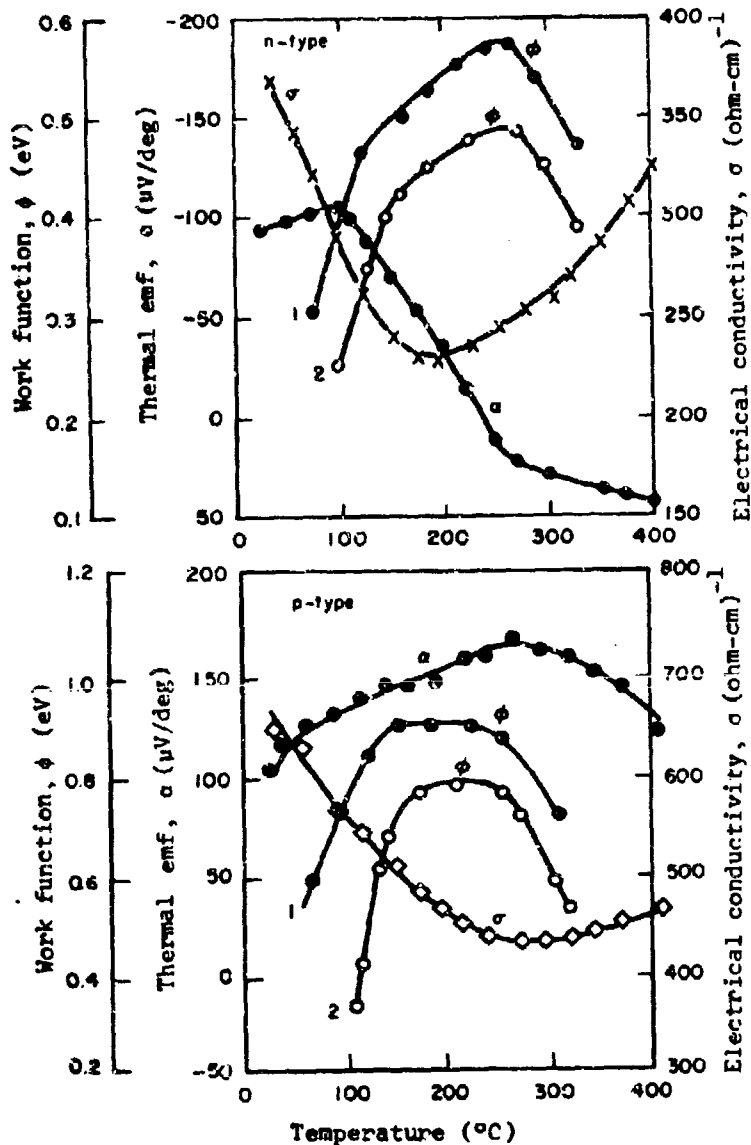
Work function behaviour with temperature for three samples of polycrystalline, n-, and p-type  $\text{Bi}_2\text{Te}_3$ . Measurements made by means of contact potential difference experiments.

[Ref. 19098]



BISMUTH TELLURIDE-BISMUTH SELENIDE

WORK FUNCTION



Work function behaviour with temperature for two samples of polycrystalline, n- and p-type, 80%  $\text{Bi}_2\text{Te}_3$  + 20%  $\text{Bi}_2\text{Se}_3$ . Conductivity and thermal emf are also shown.

[Ref. 19098]

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### ADDITIONAL PUBLICATIONS

EPIC BULLETIN. Vol. 1, no. 1, January 1965. . A monthly two-page news sheet containing items of interest to many of our users.

ELECTRICAL AND ELECTRONIC PROPERTIES OF MATERIALS. INFORMATION RETRIEVAL PROGRAM, Technical Documentary Report No. ASD-TDR-62-539, June 1962, Final Report (Covers work from July 5, 1961 - June 15, 1962), H. T. Johnson, E. Schafer, and E. M. Wallace, pp. 219. (AD-289 546) \$15.00.

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THE ELECTRONIC PROPERTIES INFORMATION CENTER, Technical Report AFML-TR-65-68. March 1965, H. Thayne Johnson and Donald L. Grigsby (Covers work from 1 February 1964 - 31 January 1965), pp. 80. (AD-466 104). Not available from Clearinghouse.

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### SPECIAL REPORTS

- S-1 INSULATION MATERIALS DESCRIPTORS USED IN THE ELECTRICAL AND ELECTRONIC PROPERTIES OF MATERIALS INFORMATION RETRIEVAL PROGRAM: Emil Schafer. July 1962. (Superseded by other publications.)
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